



HIGH TEMPERATURE

In Situ and Operando  
Electrochemical Techniques



novel measurement solutions

T. M. Huber

Join at [menti.com](https://menti.com) | use code 1414 1463

# Outline:

- Experiments:
  - In situ PLD
  - In situ XPS
  - In situ Auger SEM
  - In situ LASIS
  - In situ NAP XPS
  - In situ XPS
- How to do/start an in situ experiment
- Potential problems on the way
- Tips & tricks on how to set things up
- Electrical measurements, electrode arrangements & designs

iPLD  
EXACT-XPS  
EXACT-AEM





Join at [menti.com](https://menti.com) | use code 1414 1463

# In situ definition

***In situ*** (/ɪn 'sɪtjuː; - 'sartjuː; - 'si:-/; often not italicized in English)<sup>[1][2][3]</sup> is a Latin phrase that translates literally to "on site"<sup>[4]</sup> or "in position."<sup>[5]</sup> It can mean "locally", "on site", "on the premises", or "in place" to describe where an event takes place and is used in many different

## Experimental physics [edit]

In [experimental physics](#) *in situ* typically refers to a method of data collection or manipulation of a sample without exposure to an external environment. For example, the Si(111) 7x7 surface reconstruction is visible using a [scanning tunneling microscope](#) when it is prepared and analyzed *in situ*

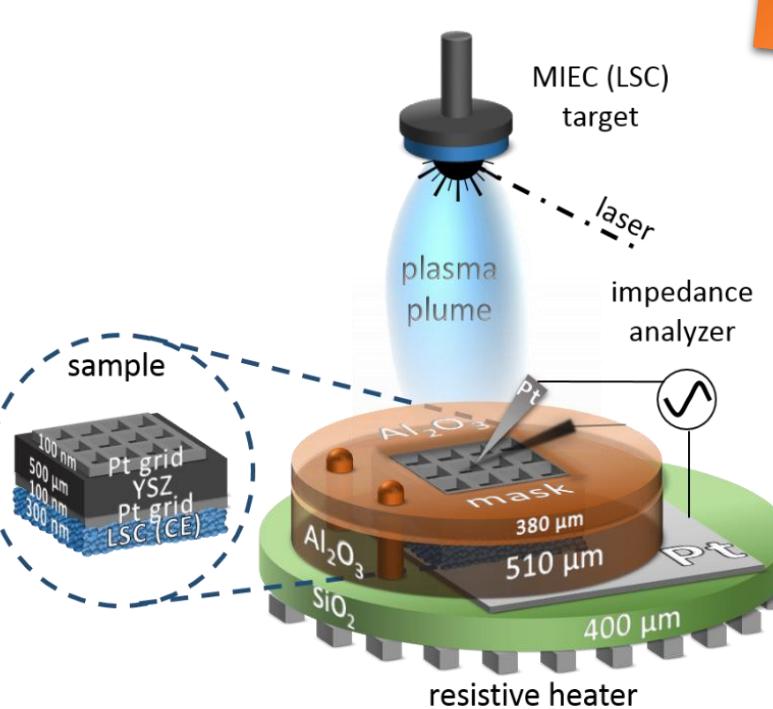
## Electrochemistry [edit]

In [electrochemistry](#), the phrase *in situ* refers to performing electrochemical experiments under operating conditions of the electrochemical cell, i.e., under potential control. This is opposed to doing *ex situ* experiments that are performed under the absence of potential control. Potential control preserves the electrochemical environment essential to maintain the double layer

The term “*in situ*” changed to “*operando*” in the research field of catalyst spectroscopy!



## Production/ deposition



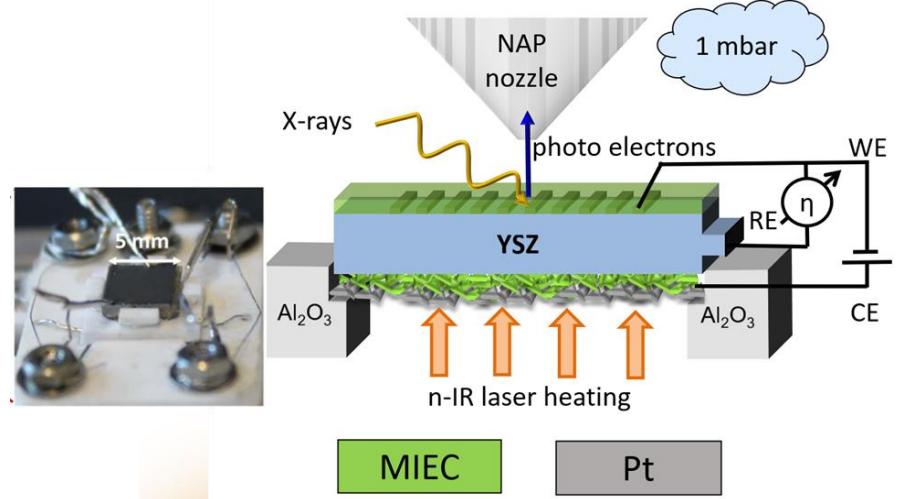
Temperature



Gasses

Electrical  
Measurements

Analytical



# Experiments

# Real-time impedance monitoring in the PLD

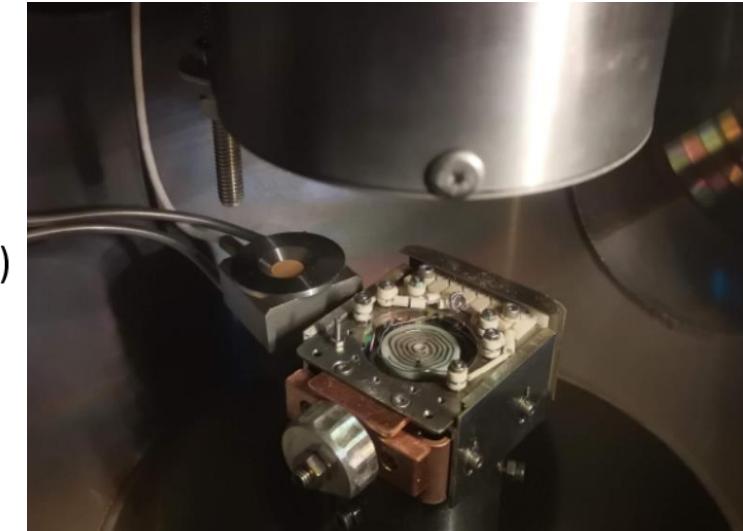
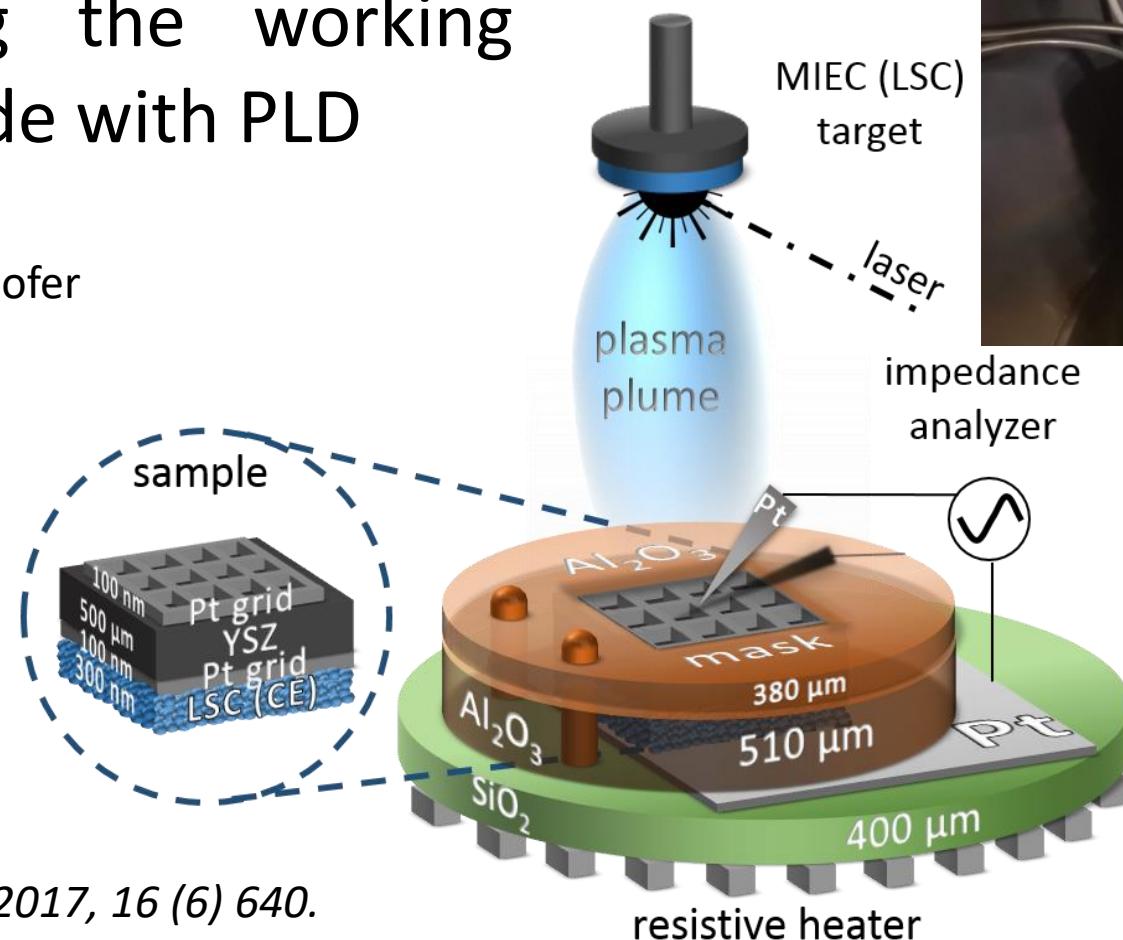
Measuring a cell while  
growing the working  
electrode with PLD



Matthäus Siebenhofer  
Poster on Tuesday



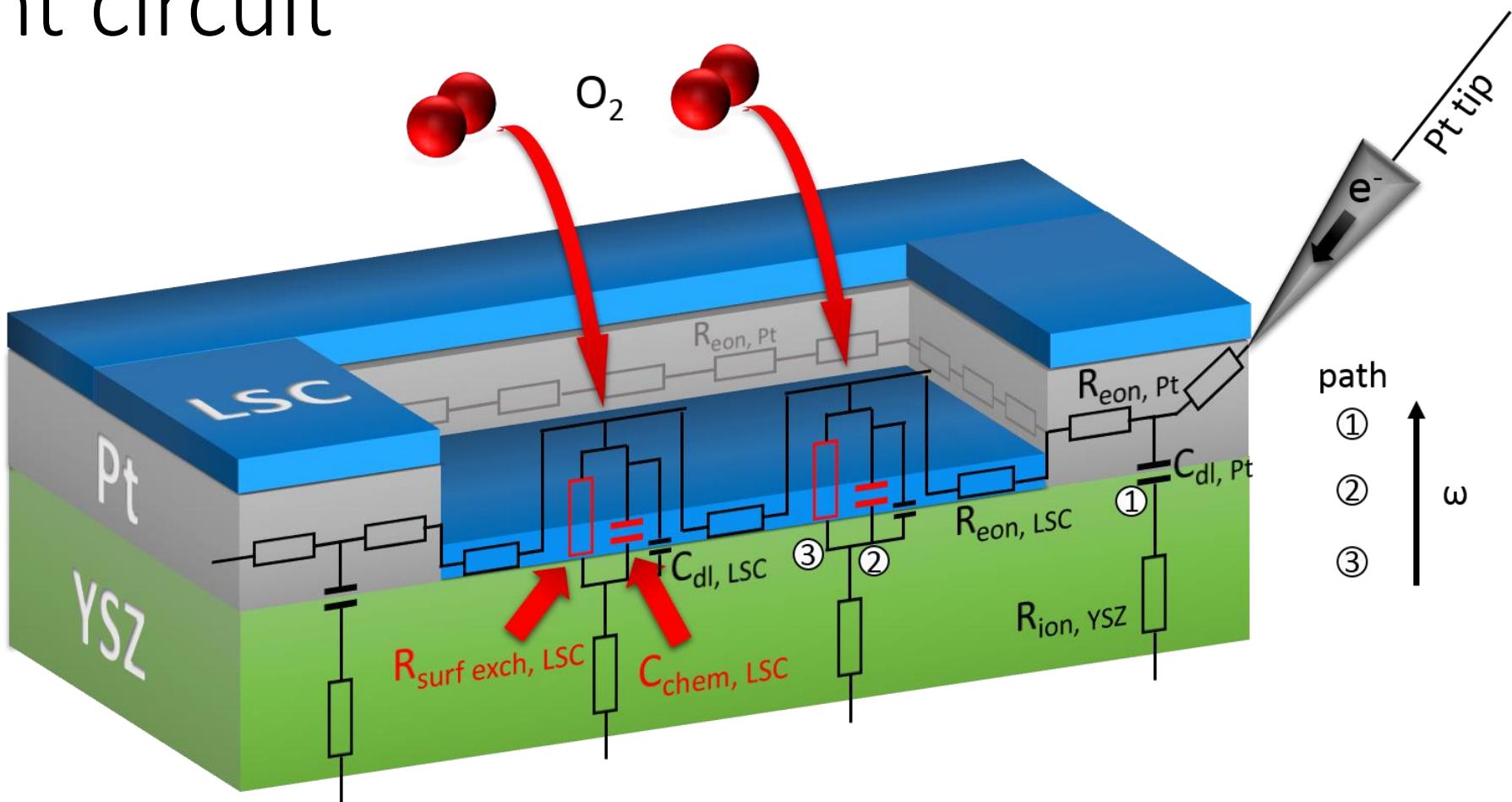
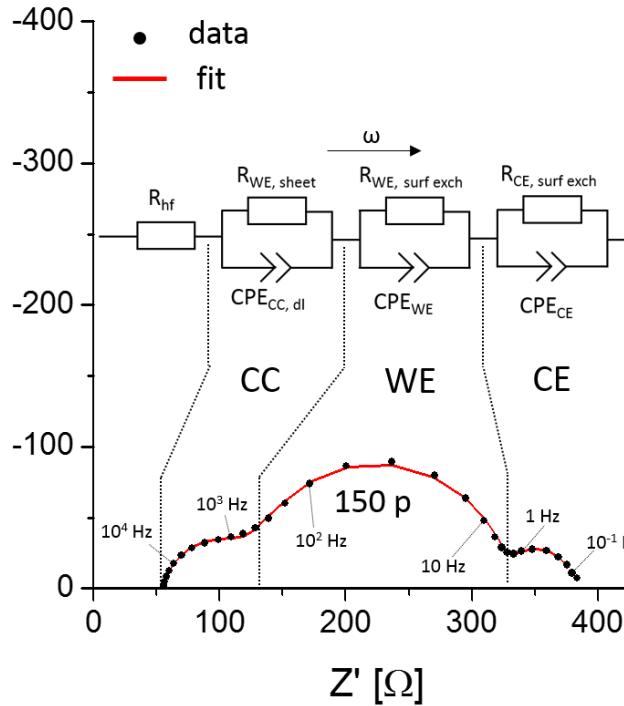
Markus Kubicek  
Talk on Friday



Rupp G.M. et al. *Nature Materials*, 2017, 16 (6) 640.

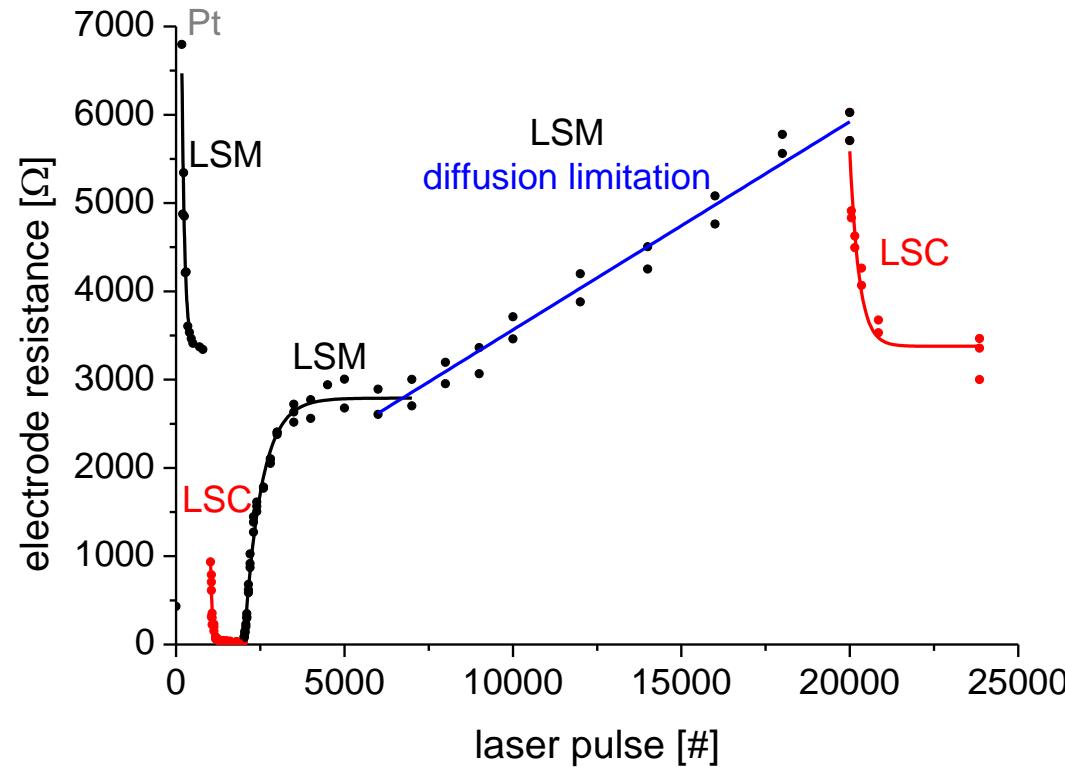
Rupp G.M. et al. *ACS Appl. Energy Mater.* 2018 1, 9, 4522-4535

# The equivalent circuit



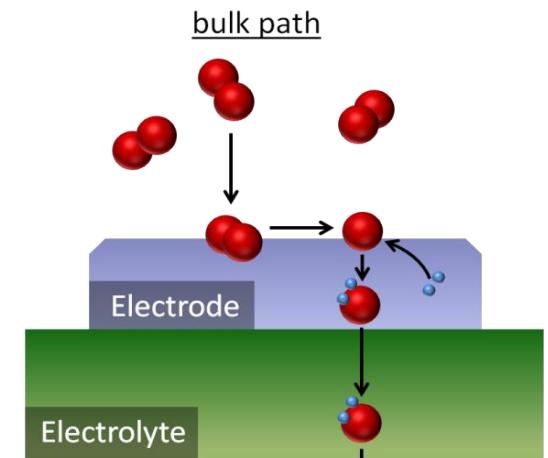
- Equivalent circuit based on Jamnik-Maier model
- Could not be used for NLLS fitting (3D, differential)
- Simplified equivalent circuit for fitting

# Multilayers of $\text{La}_{0.6}\text{Sr}_{0.4}\text{CoO}_{3-\delta}$ and $\text{La}_{0.8}\text{Sr}_{0.2}\text{MnO}_{3-\delta}$



Impedance of growing  
MIEC thin films

600°C,  $4 \cdot 10^{-2}$  mbar  $\text{pO}_2$

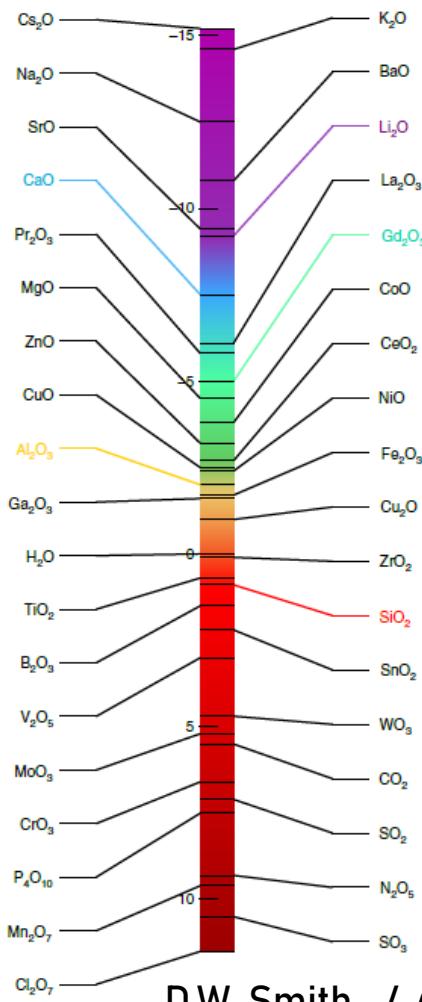


- Determine critical thickness
- Investigate co-limitations
- Customize model thin films ( $R_{\text{surf}}$  vs.  $R_{\text{diff}}$ )

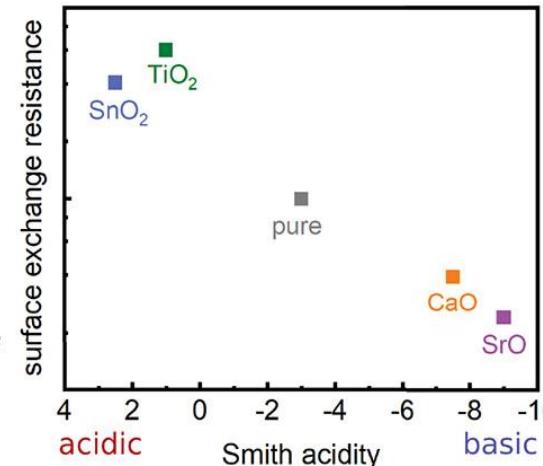
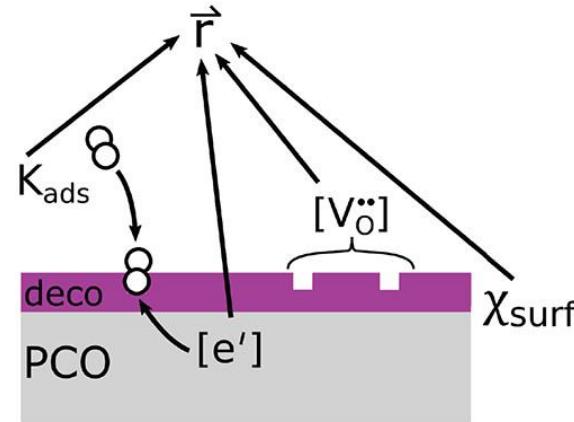
# Surface manipulation

Acidity scale for oxides:

Transfer of  $O^{2-}$



D.W. Smith, *J. Chem. Educ.*, (1987), 64, 6, 480.



surface charge – work function – catalytic activity

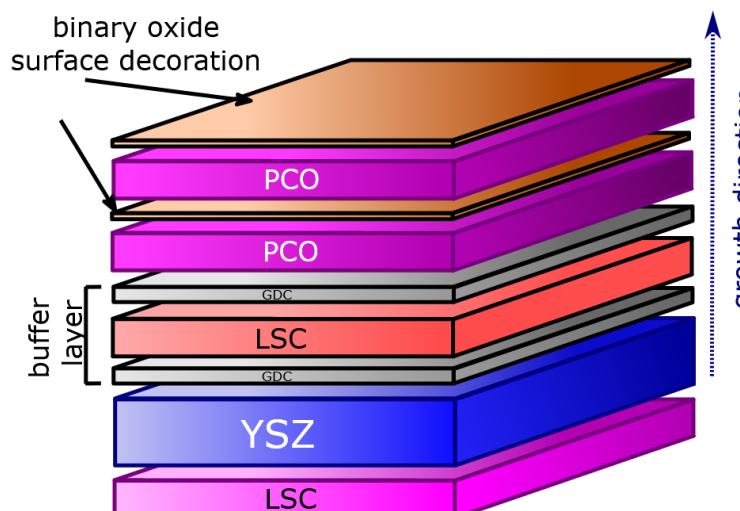
C. Riedl, ... M Kubicek et al.  
*J. Mater. Chem. A*, (2022) ,10, 2973–2986

M Siebenhofer, ..., M Kubicek  
*J. Electrochem. Soc.* (2023) 170 014501

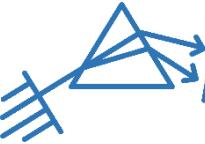
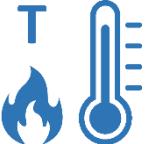
F Fahrnberger, ... M Kubicek  
*Appl. Surf. Sci.*, (2023), 640, 158312

M Siebenhofer, ... M Kubicek  
*J. of Mater. Chem. A*, (2023), 11(24), pp. 12827–12836

M Siebenhofer, ..., M Kubicek  
*Nature Comm.*, (2024), 15, 1, 1730



# Methods

In situ thin film growth in atmosphere		Optical (UV/VIS/IR) Characterization	X-Ray Based Spectroscopy	X-Ray and Neutron Diffraction	Electron & Ion Beam Methods	Electrical AC & DC Measurements
Challenges						
Temperature Incompatibility 		 IR background	 desorption of surface species		 limited resolution	
Pressure Gap 				 Neutrons dependence on atmosphere		
Set up/Mechanical Incompatibility 				 Needs custom made solution		

# Laser induced breakdown spectroscopy

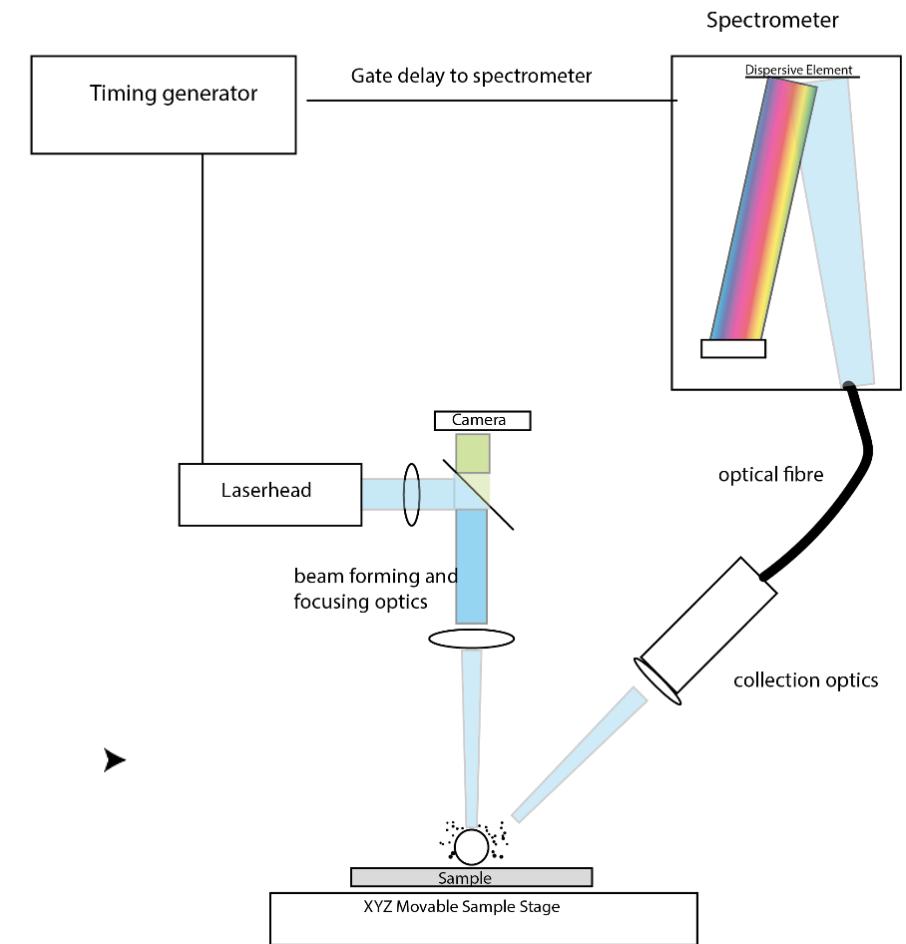
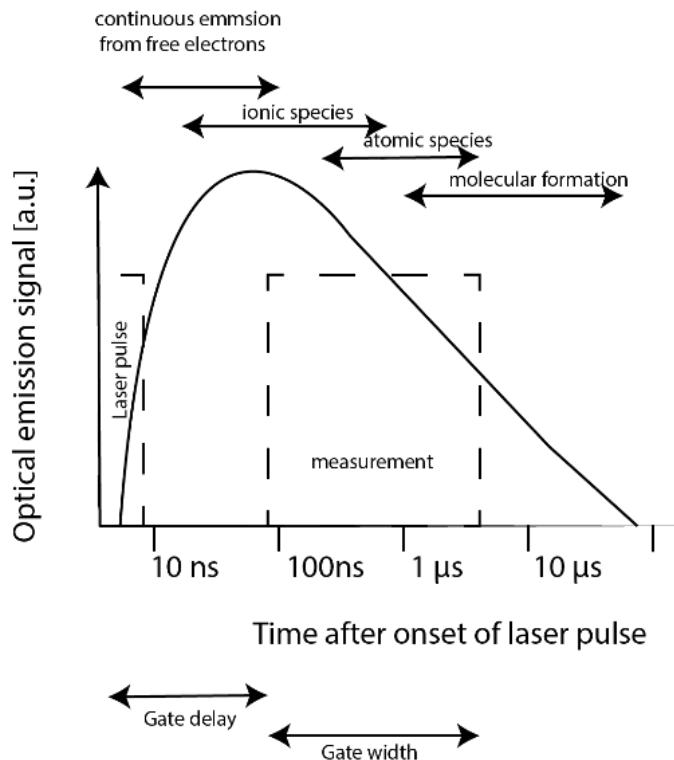
- **Laser pulse evaporates sample**
  - (same mechanism as PLD)
- **Plasma emits characteristic elemental emission → detected and quantified**



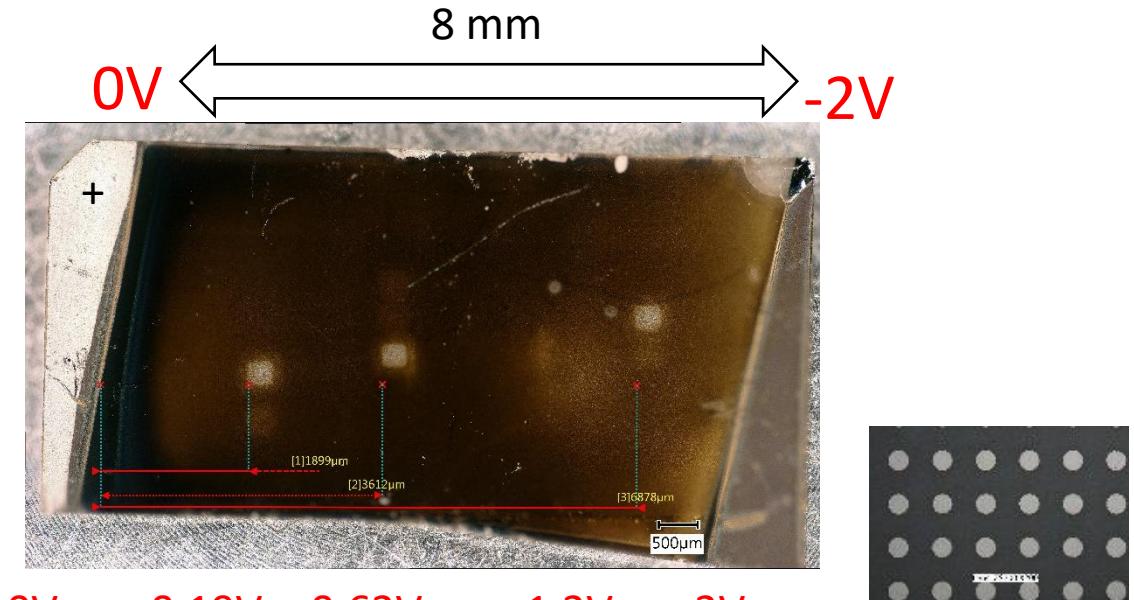
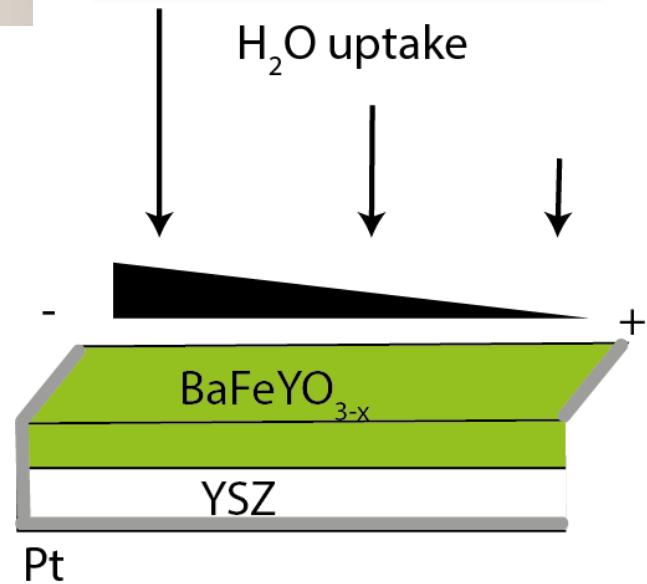
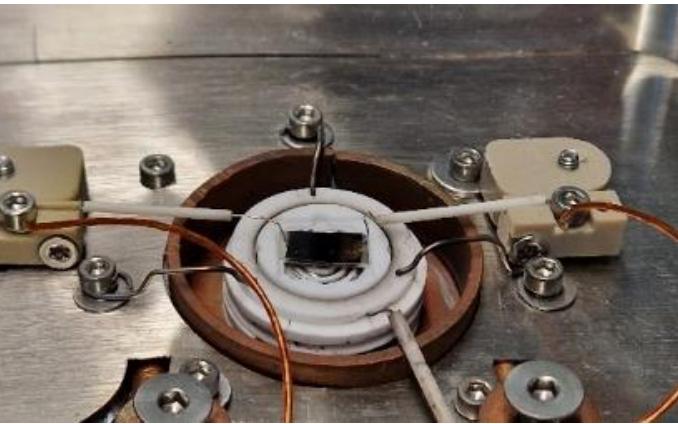
Melanie Anstiss  
Tuesday 2A3 St. James  
10.30  
& Poster on Tuesday



Maximilian Weiss  
Poster on Tuesday



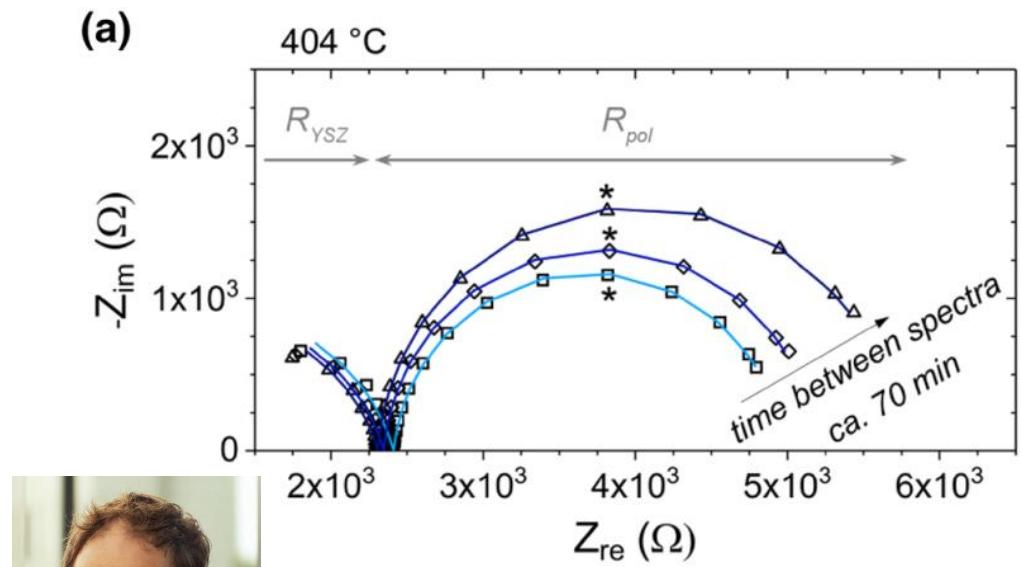
# In situ LIBS measurements



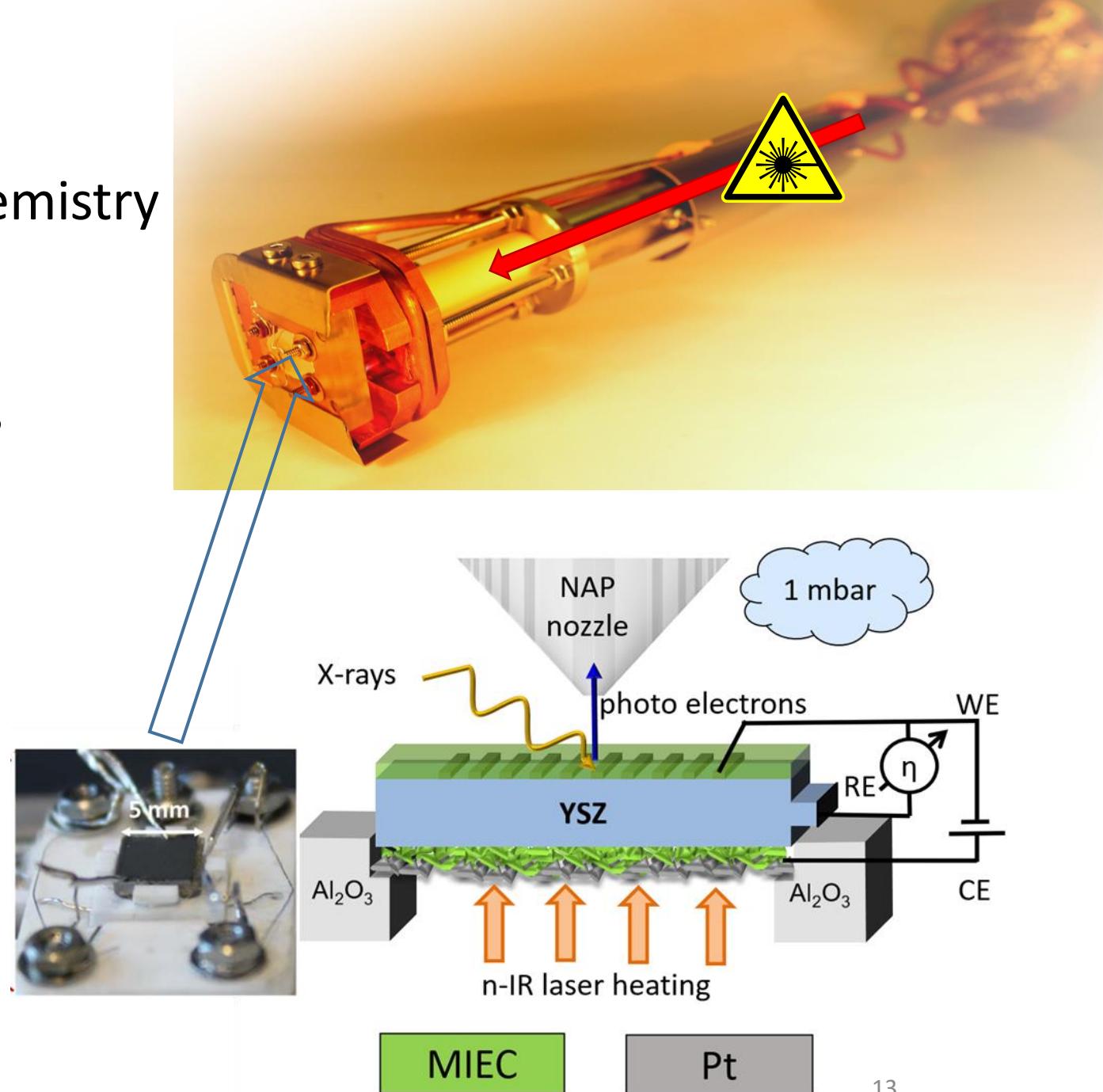
- Voltage /  $p(O_2)$  drop across sample
- Large  $p(O_2)$  range on just one sample
- Measure OH uptake laterally

# NAP-XPS + EIS measurements

- Direct correlation of surface chemistry and activity
- Example: Sr segregation on  $\text{La}_{0.6}\text{Sr}_{0.4}\text{CoO}_{3-\delta}$  (LSC) electrodes



Andreas Nenning  
Talk and poster on  
Tuesday



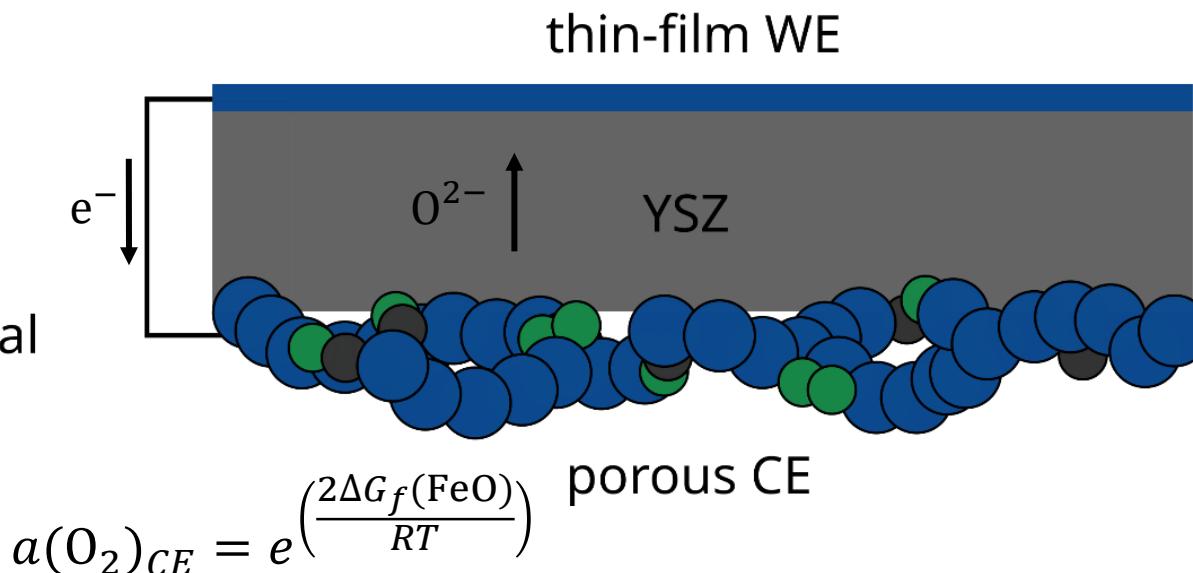
# ELECTROCHEMICAL OXYGEN ACTIVITY CONTROL (EXACT) AEM IN UHV

CE conditioning

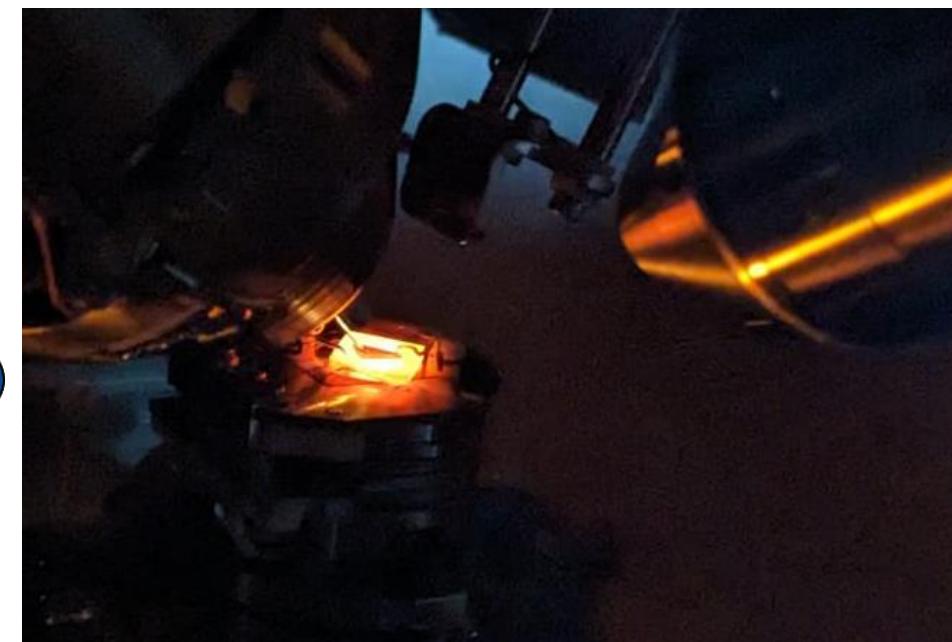
goal: constant  $\mu(O)$  in CE  
high CE capacity

$Fe_2O_3 \rightleftharpoons Fe_3O_4$	1/3 e <sup>-</sup> per Fe atom	-500 mV vs. air
$Fe_3O_4 \rightleftharpoons FeO$	2/3 e <sup>-</sup> per Fe atom	-890 mV vs. air
$FeO \rightleftharpoons Fe$	2 e <sup>-</sup> per Fe atom	-1050 mV vs. air

- GDC10
- Fe<sub>2</sub>O<sub>3</sub>
- Fe<sub>3</sub>O<sub>4</sub>
- FeO
- Fe metal



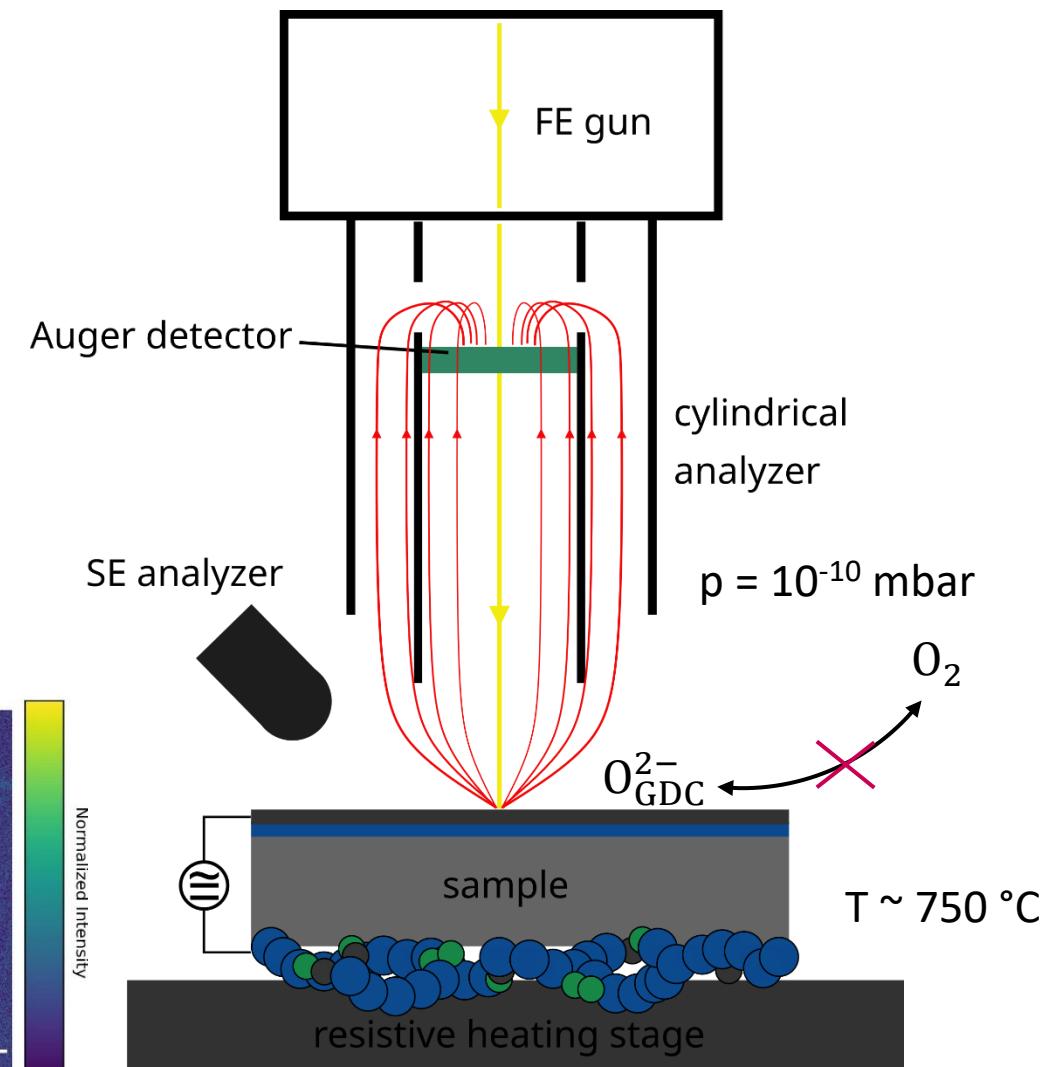
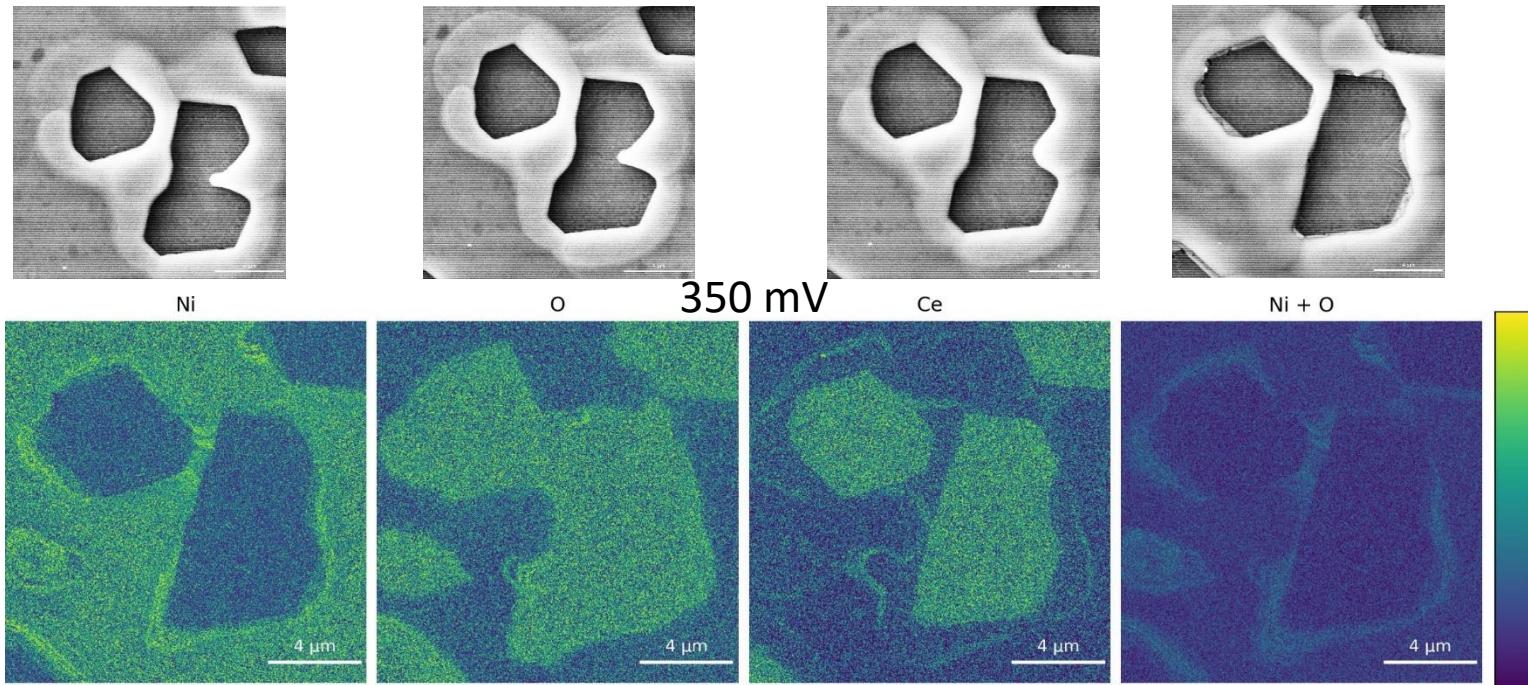
Christian Melcher  
Monday 16:35, 5A4 Room: Moore

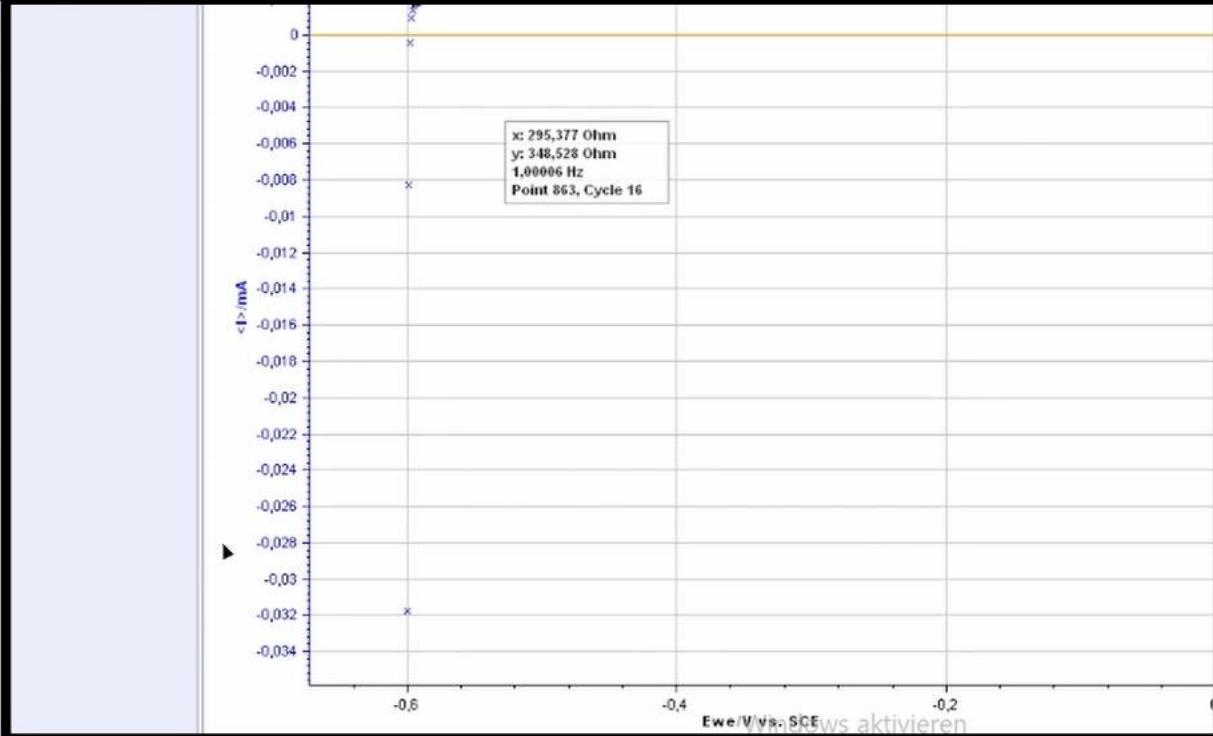
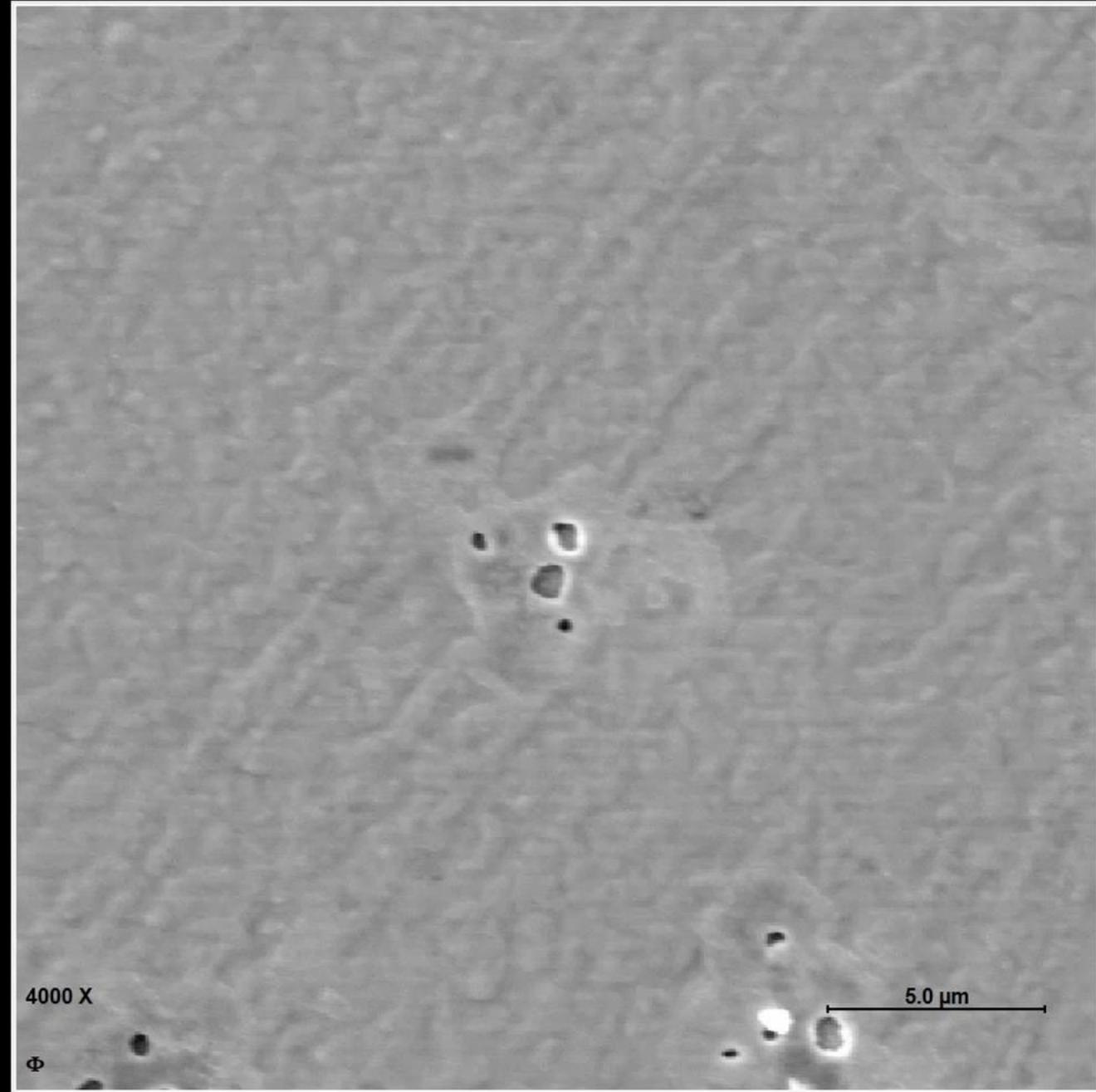


T = 750 °C

# In situ Auger electron microscopy (AEM) Ni thin film on GDC

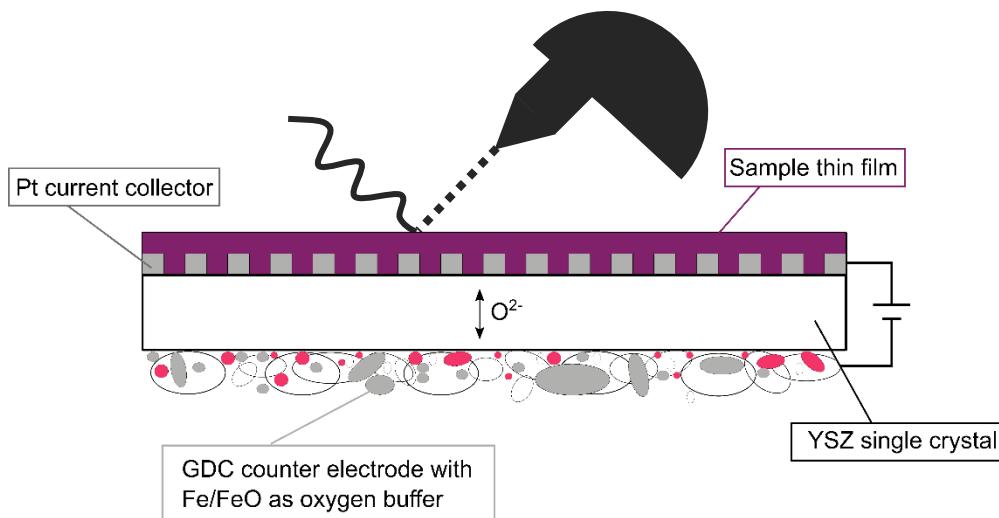
- SEM imaging
- spatially resolved surface spectroscopy
- elemental mapping
- UHV conditions required





00:00:00:00

# ELECTROCHEMICAL oXYGEN ACTIVITY CONTROL (EXACT) XPS



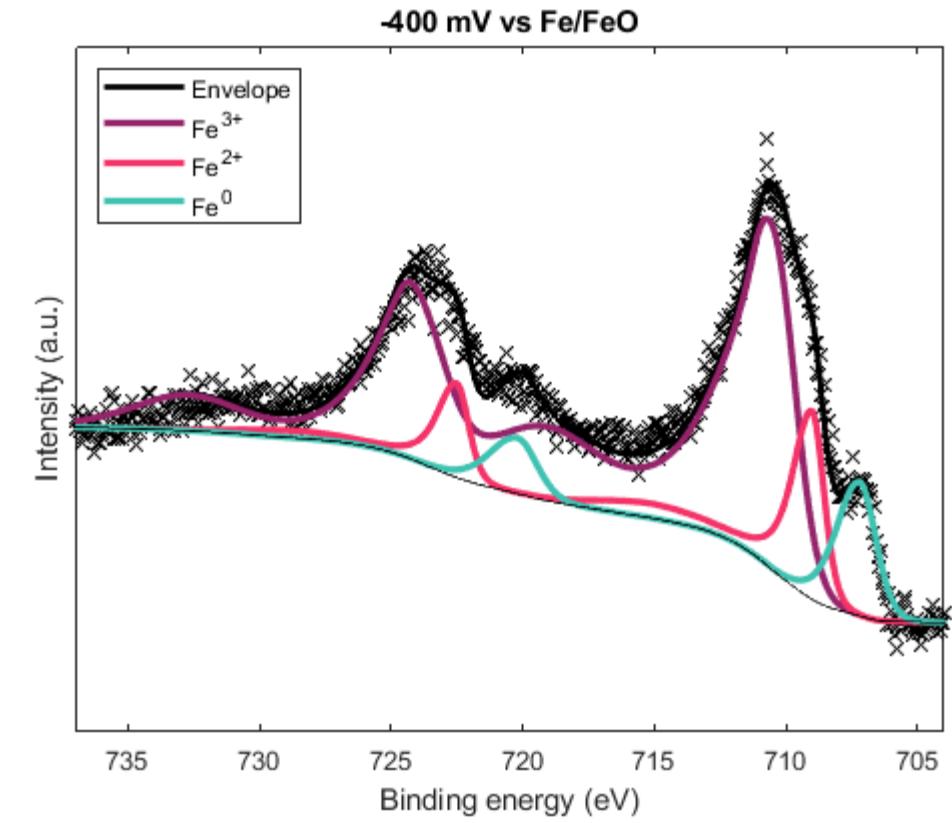
$$a(O_2)_{WE} = e^{\left(\frac{4F \cdot U + 2\Delta_f G^0(FeO)}{RT}\right)}$$



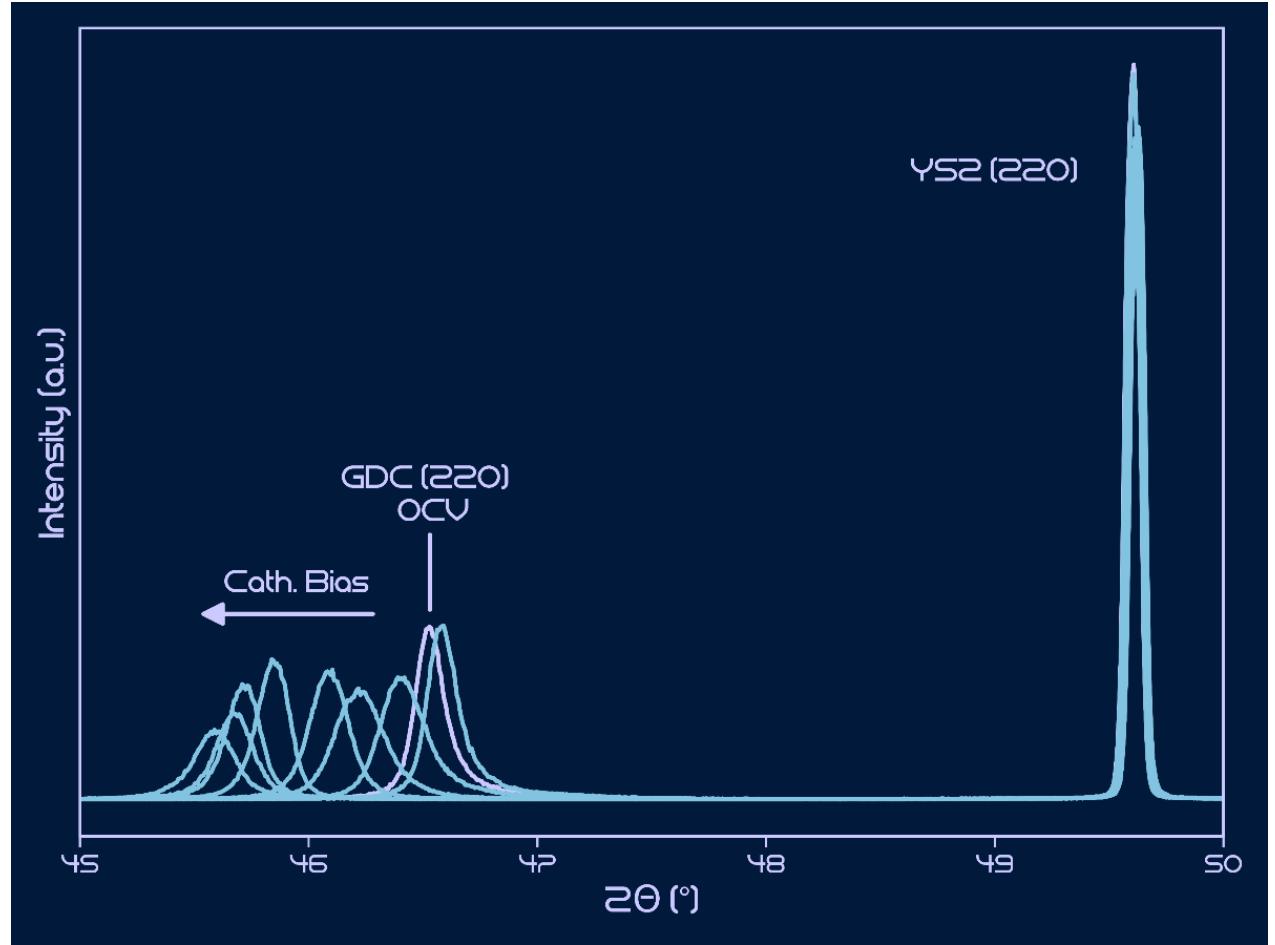
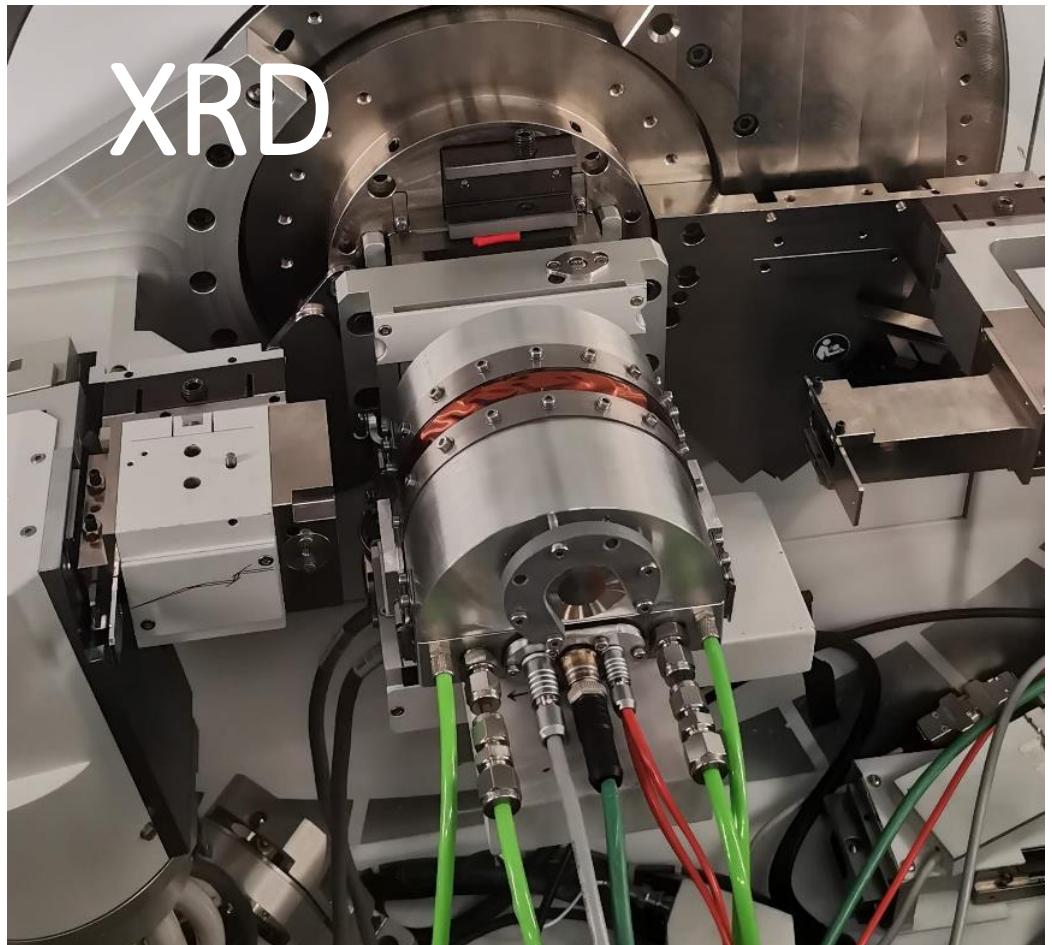
Stanislaus Breitwieser  
Talk on Monday



Andreas Nenning  
Talk and poster on  
Tuesday



600 °C, UHV

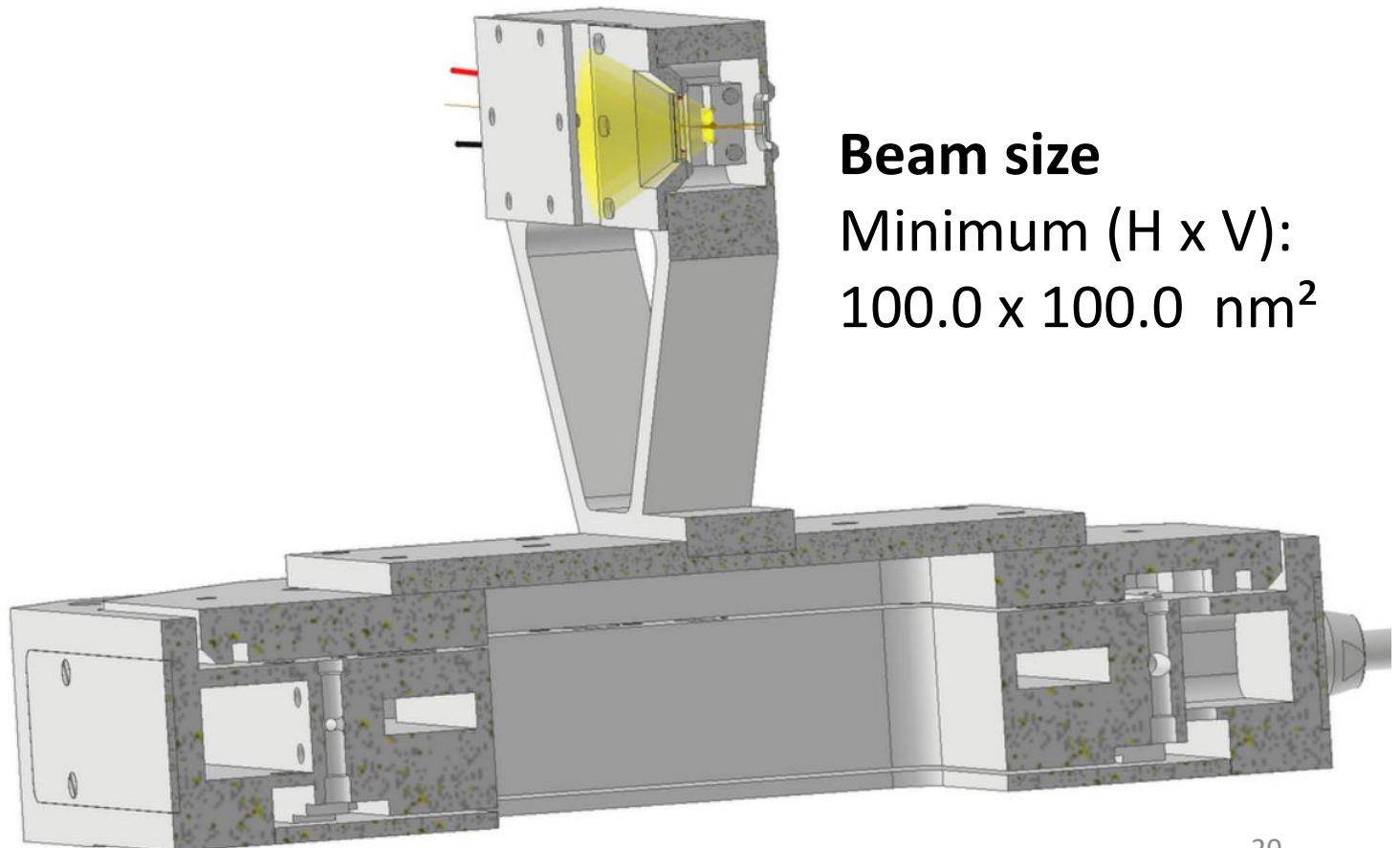
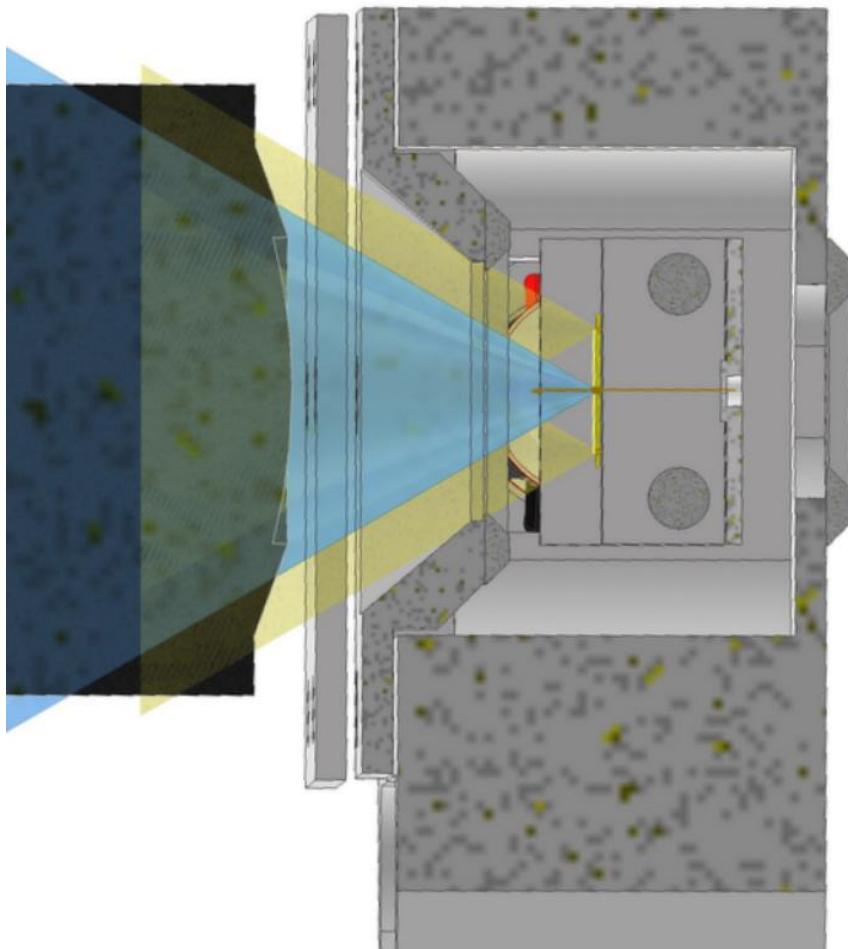


## GDC thin film on YSZ

Kirsten Rath  
Talk on Monday 3A4 Moore 12:05

- Compression with anodic bias
  - Expansion with cathodic bias
- YSZ reflex does not shift!

# Solid-State Lithium-Ion battery ESRF ID13 Microfocus BL



## Beam size

Minimum (H x V):  
 $100.0 \times 100.0 \text{ nm}^2$

# How to start an in situ project





a) heating

f) sample transfer

b) electrical measurements

e) gasses

g) sensor at the sample

d) polarization

c) cooling





# Material incomparability

UHV chambers → in situ chambers  
UHV heaters contain molybdenum

Formula	Melting point [°C]
Mo	2623 <sup>(1)</sup>
MoO <sub>2</sub>	1100 (decomposition) <sup>(1)</sup>
MoO <sub>3</sub>	801 <sup>(1)</sup>



high vapor pressure!  
sublimates noticeably at 700 °C

(1) [www.webelements.com/compounds/molybdenum/molybdenum\\_dioxide.html](http://www.webelements.com/compounds/molybdenum/molybdenum_dioxide.html)

From: Michael Schmid,  
[www.tuwien.at/en/phy/iap/tools/vapor-pressure-calculator](http://www.tuwien.at/en/phy/iap/tools/vapor-pressure-calculator)

IAP / Tools / Vapor Pressure Calculator

Substance: Mo

Temperature: 1173.2 K  
900 °C

Vapor Pressure: 3.48e-22 bar

**MORE...**

Gas Density: 2.15e+3 per m<sup>3</sup> \*

Evaporation/Subl. Rate: 2.7e5 per (m<sup>2</sup>s) \*\*

Erosion: 4.3e-24 m/s \*\*

Melting Temperature: 2890 K

Vapor pressure at Melting P.: 4.32e-5 bar



# Structural materials for in situ heater

- Preferable: high temperature oxides
  - e.g. Alumina, Zirconia, Sapphire, Quartz glass,...
- Metals, Ni-based alloys



- Water cooled parts
  - Non high temperature materials possible
  - **BUT anticipate a cooling failure!**



# Nickel tetracarbonyl & Iron pentacarbonyl

- CO & Ni

- CO & Fe

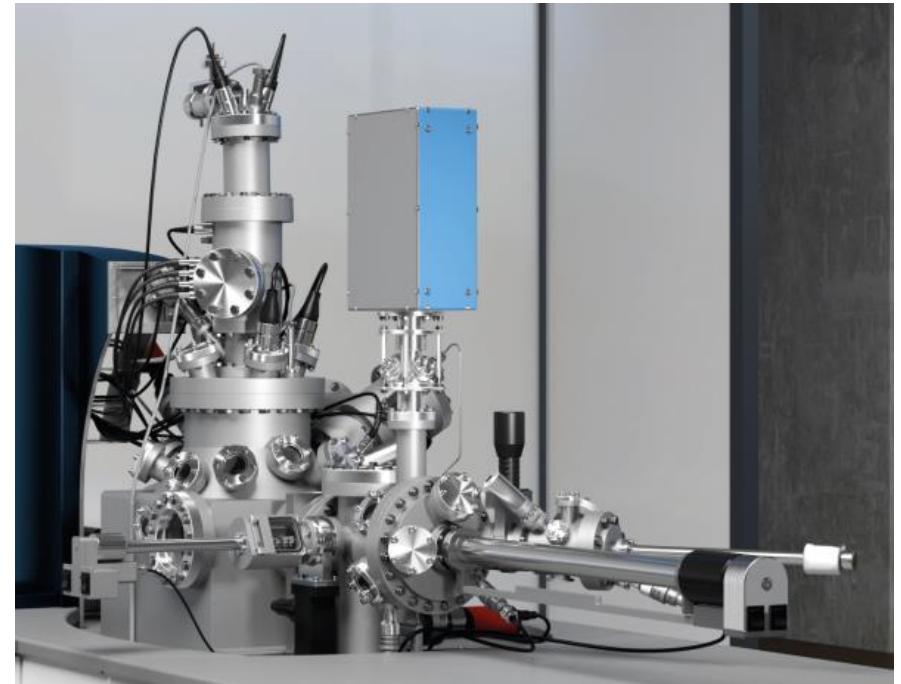
(e.g. stainless steel)

GHS labelling:	
Pictograms	
Hazard statements	H225, H300, H301, H304, H310, H330, H351, H360D, H410
Precautionary statements	P201, P202, P210, P233, P240, P241, P242, P243, P260, P271, P273, P280, P281, P284, P303+P361+P353, P304+P340, P308+P313, P310, P320, P370+P378, P391, P403+P233, P403+P235, P405, P501
NFPA 704 (fire diamond)	

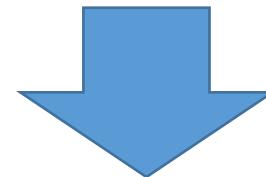
Flash point	4 °C (39 °F; 277 K)
Autoignition temperature	60 °C (140 °F; 333 K)
Explosive limits	2–34%
Lethal dose or concentration (LD, LC):	
LC <sub>50</sub> (median concentration)	266 ppm (cat, 30 min) 35 ppm (rabbit, 30 min) 94 ppm (mouse, 30 min) 10 ppm (mouse, 10 min) <sup>[3]</sup>
LC <sub>Lo</sub> (lowest published)	360 ppm (dog, 90 min) 30 ppm (human, 30 min) 42 ppm (rabbit, 30 min) 7 ppm (mouse, 30 min) <sup>[3]</sup>

# Plastic components

- Not hydroscopic:
  - PEEK
  - Polyethylene
  - Polypropylene
  - PTFE (Teflon) **Max temperature 170°C !**
  - PVC
  - Polyimide (Kapton)



Using scroll vacuum pump  
with Teflon tip seal



Fluorine poisoned surface

# Contacts and electrodes

- Platinum
  - Platinum Iridium alloys (better mechanical properties & harder)
  - Platinum Rhodium alloys (higher temperature stability)
- Tungsten, Tungsten Carbide
- Gold (very soft/ for sealing)
- Silver

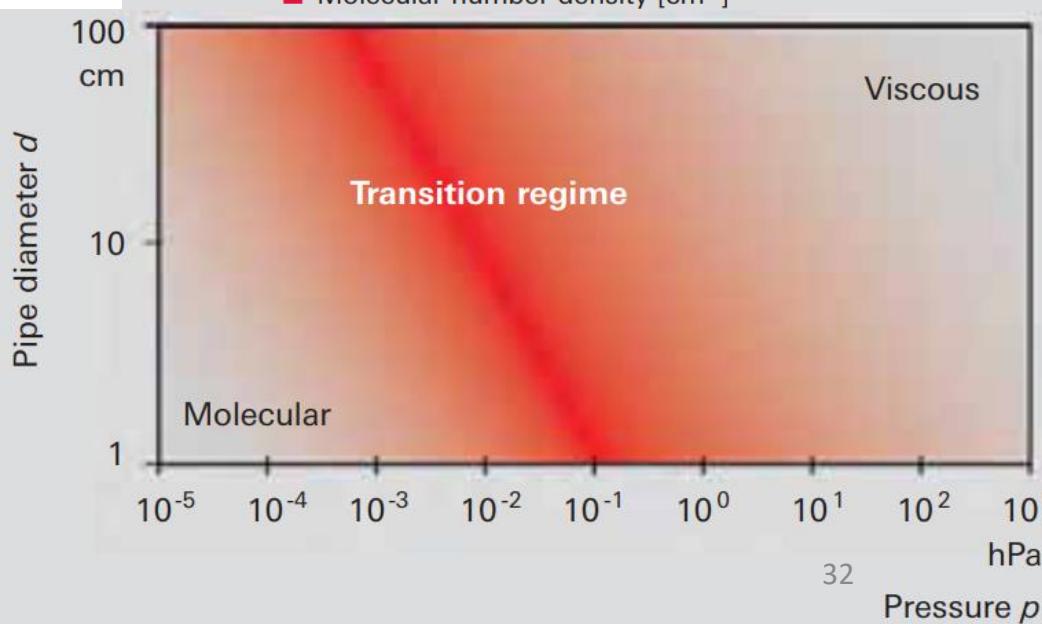
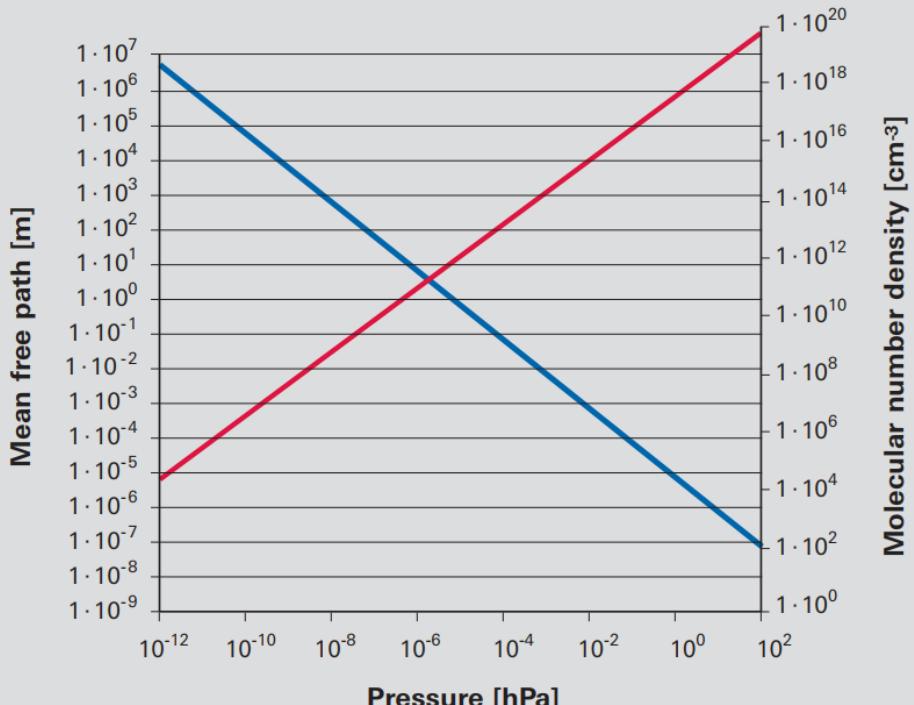


Substance	Ag	▼
Temperature	973.15	K
	700	°C
Vapor Pressure	2.37e-9	bar ▼

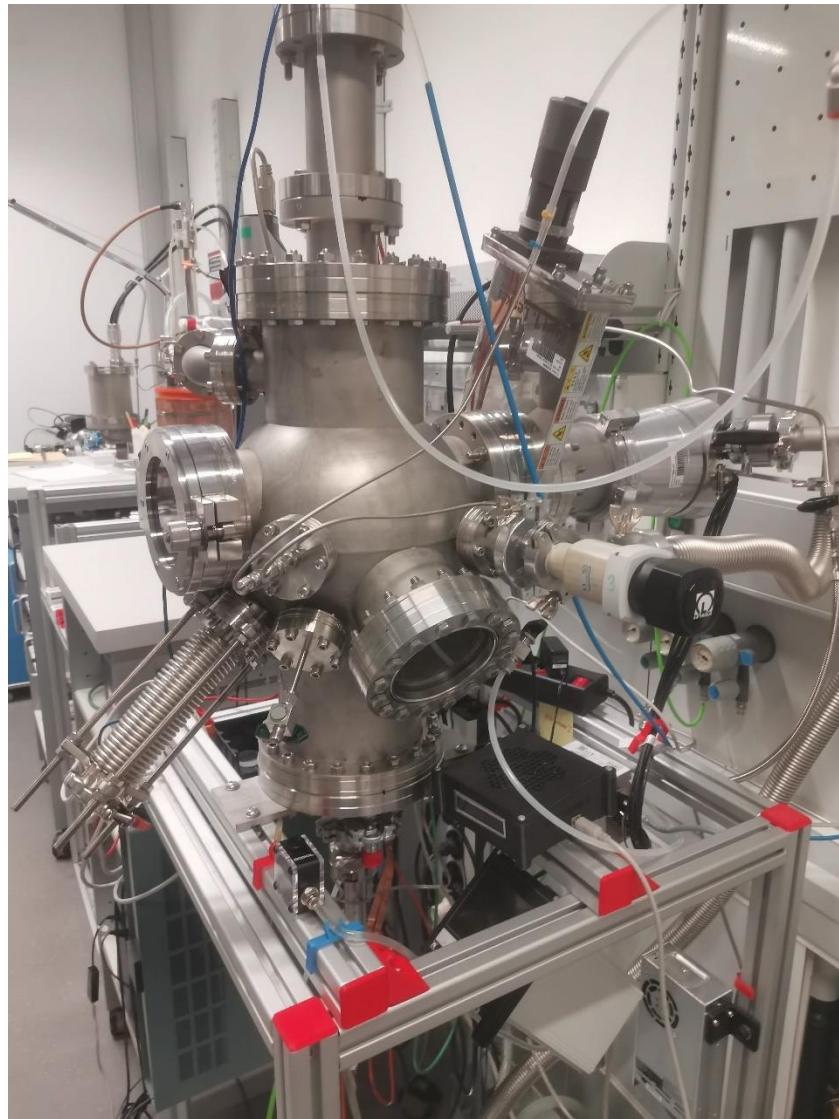
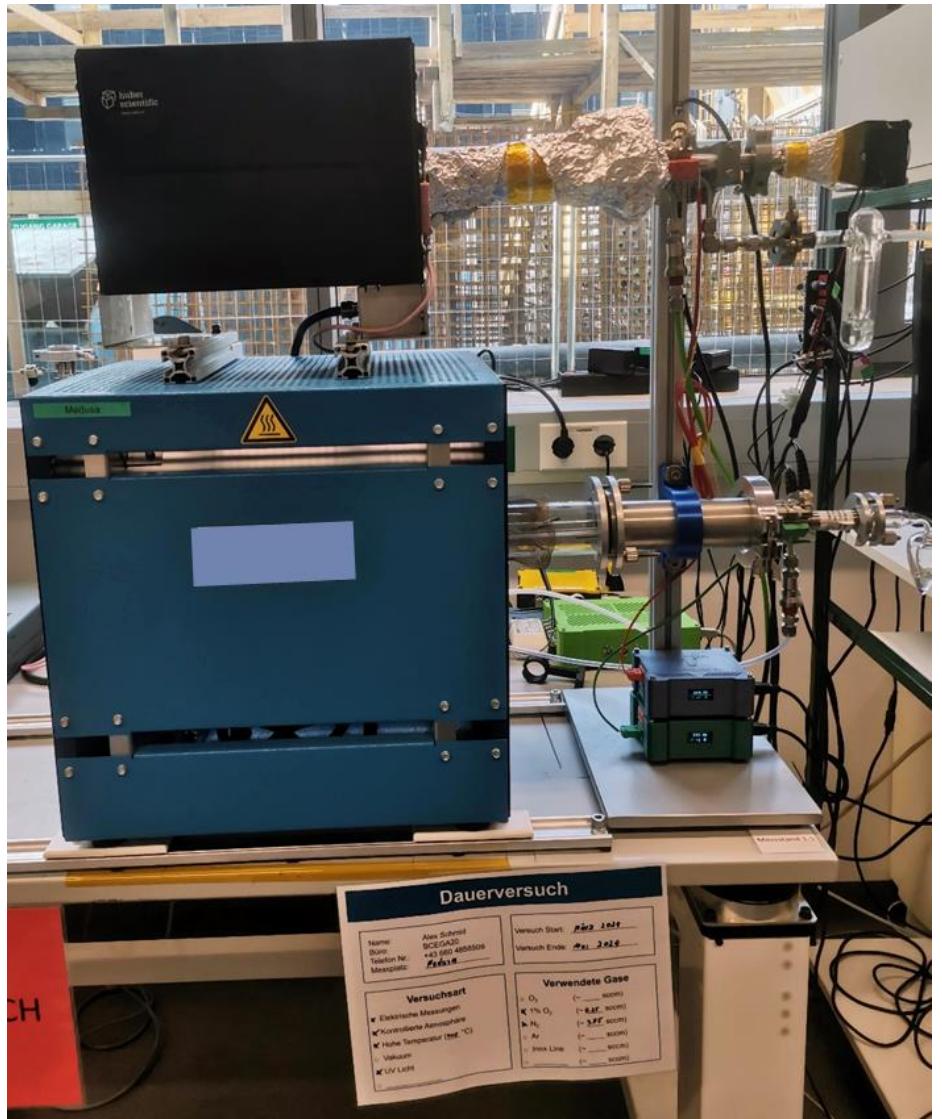
From: Michael Schmid, [www.tuwien.at/  
en/phy/iap/tools/vapor-pressure-calculator](http://www.tuwien.at/en/phy/iap/tools/vapor-pressure-calculator)

# In situ / ex situ Clean surface necessary?

- In situ in same chamber/ transport?
- Mean free path at pressure regime?
- Temperature of components
  - **Radiation**
    - Parts in line of sight?
  - **Convection**
    - Mean free path at pressure regime?
    - Cooling effects!
  - **Conduction**
    - Cooling effects!
    - Sensitive parts connected?
- Simple leak test
  - Linear → leak
  - Asymptotical → outgassing

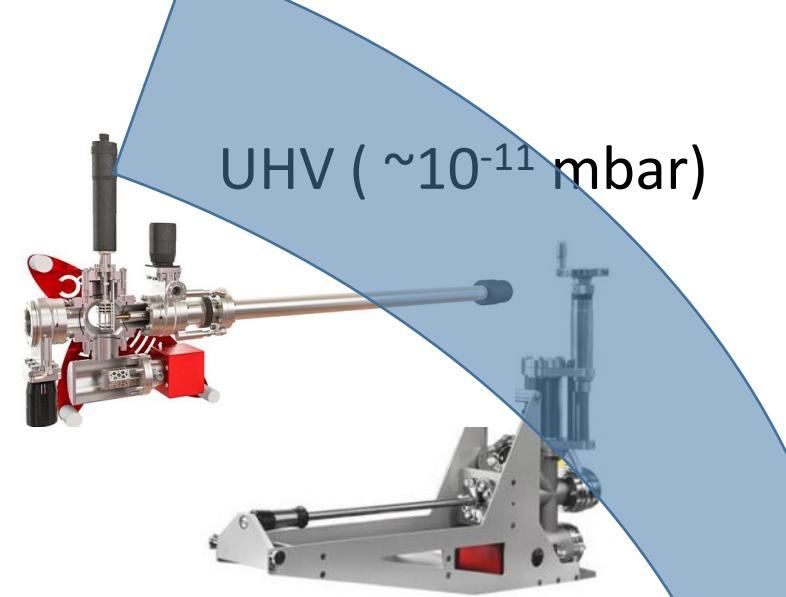
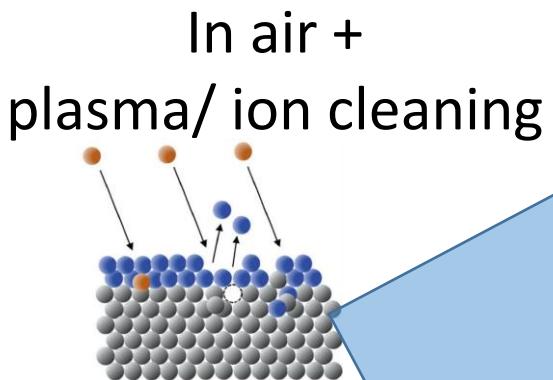




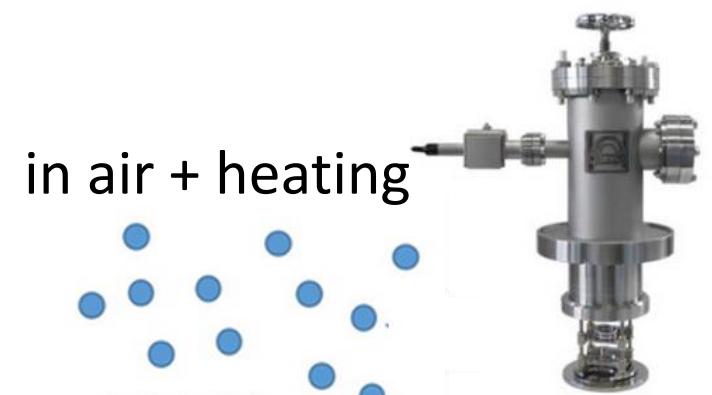


# Transport

- Which contaminants are a problem?
- **Not from transport:** chromium, fluorine, silicon, heavy metals, ...
- **From transport:** carbon, sulphur, water, CO<sub>2</sub>, acidic gases, ...
- **Cooling/heating:** cation diffusion, phase segregation, ...
- **Surface cleaning:** changing the surface

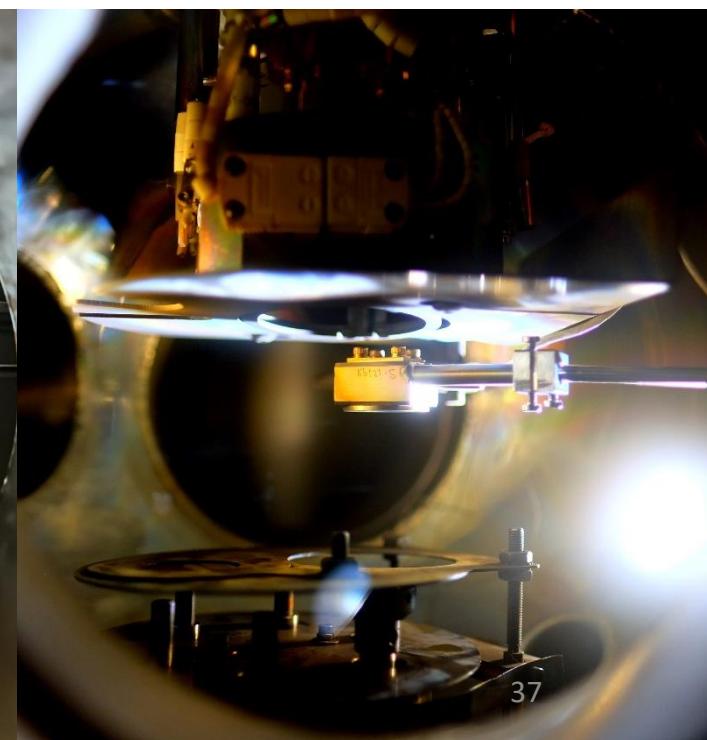
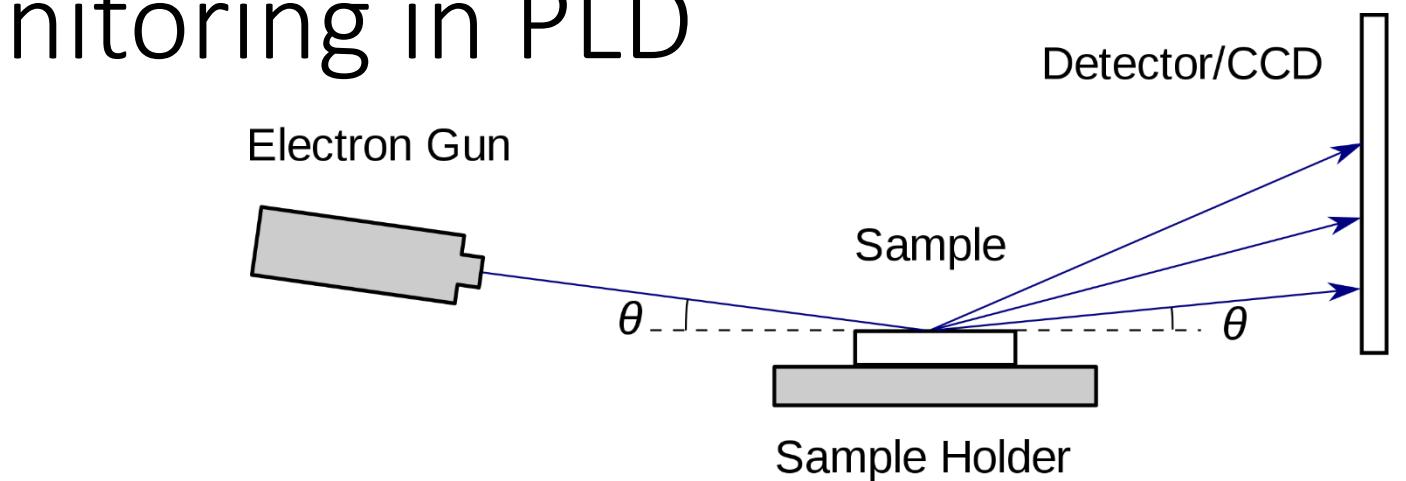
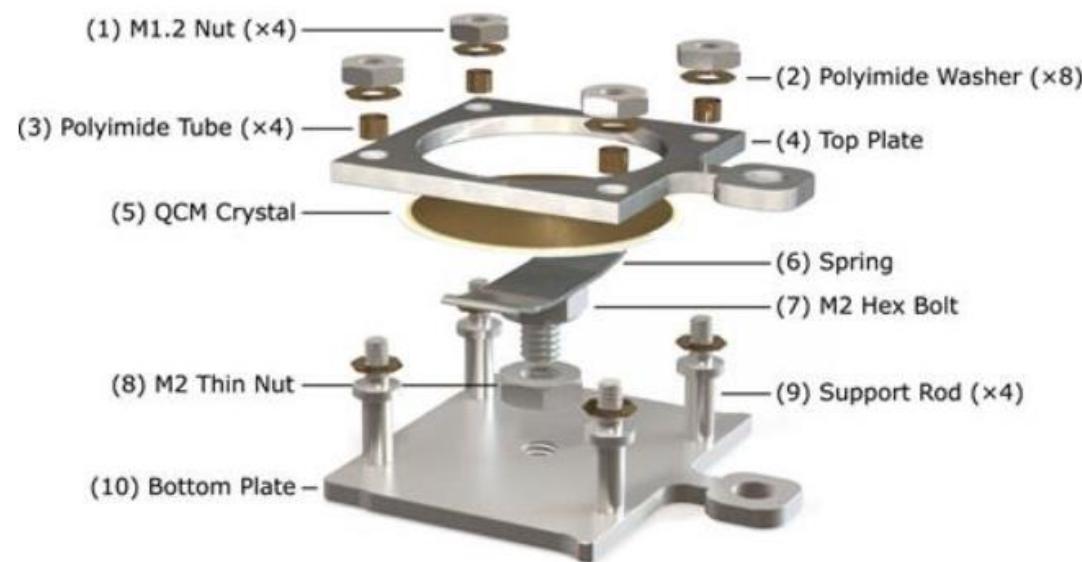


Inert gas/ low vacuum



# In situ thickness monitoring in PLD

- Rheed
- Quartz micro balance

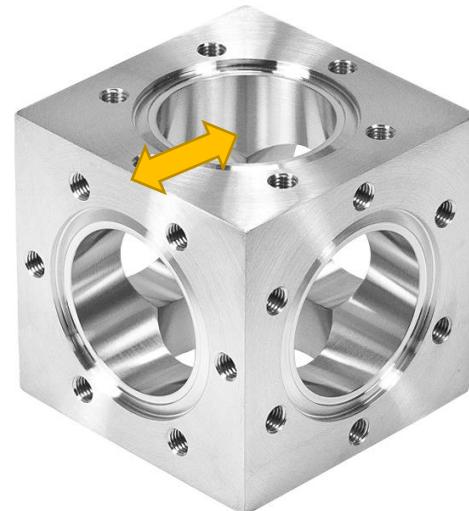


Important (small) points/problems

# Transfer, chamber shape etc.



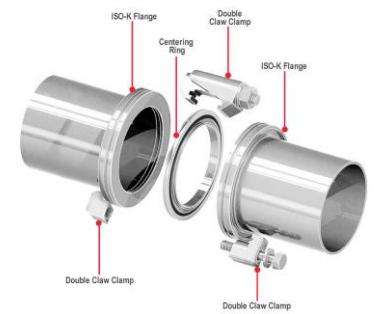
+



$< 1 \cdot 10^{-7}$  mbar?

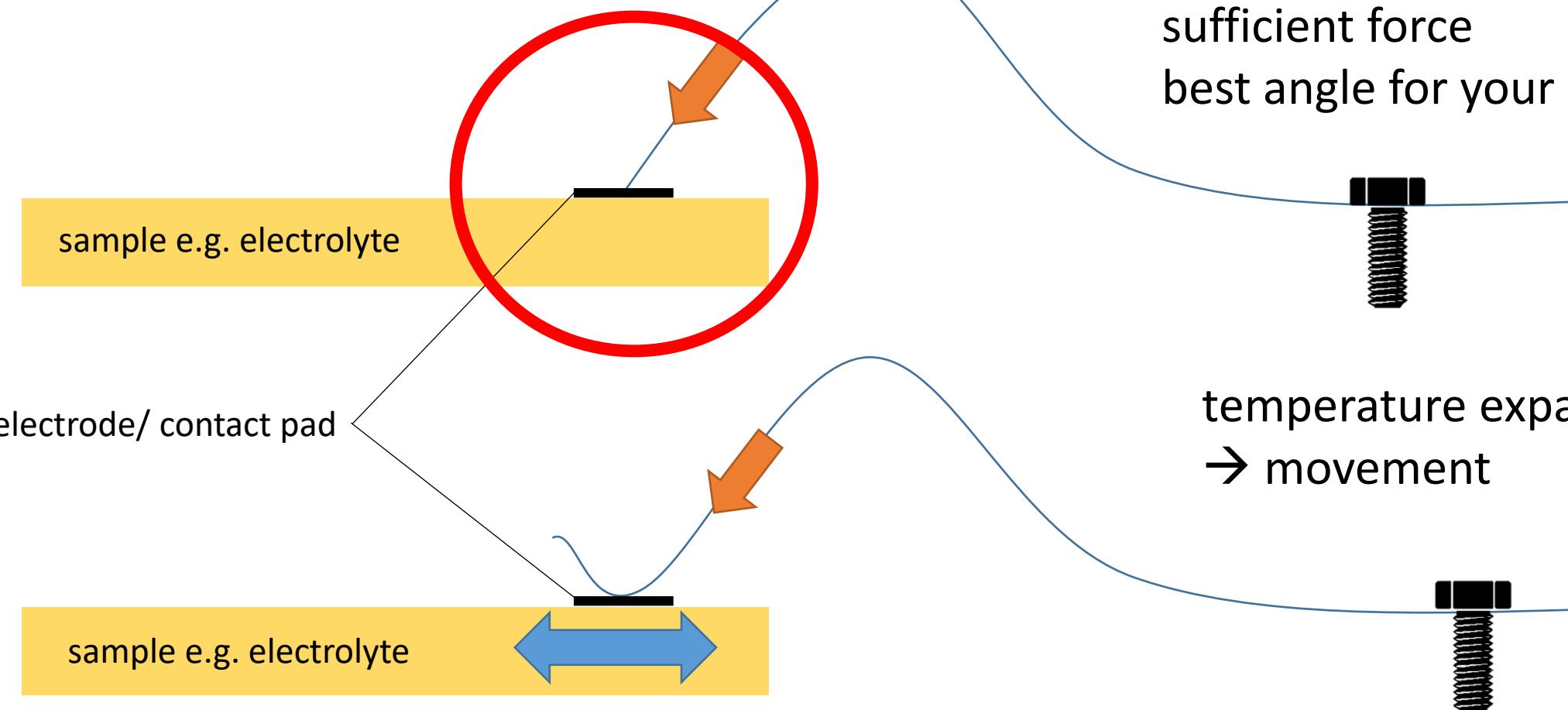


Pressure range?



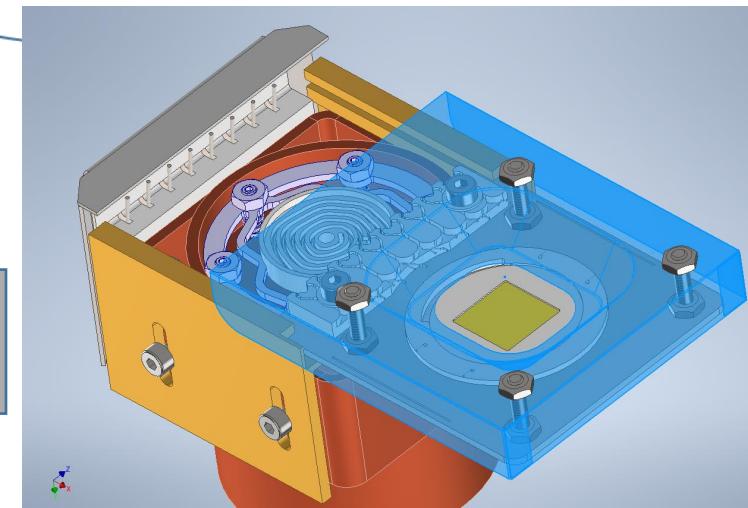
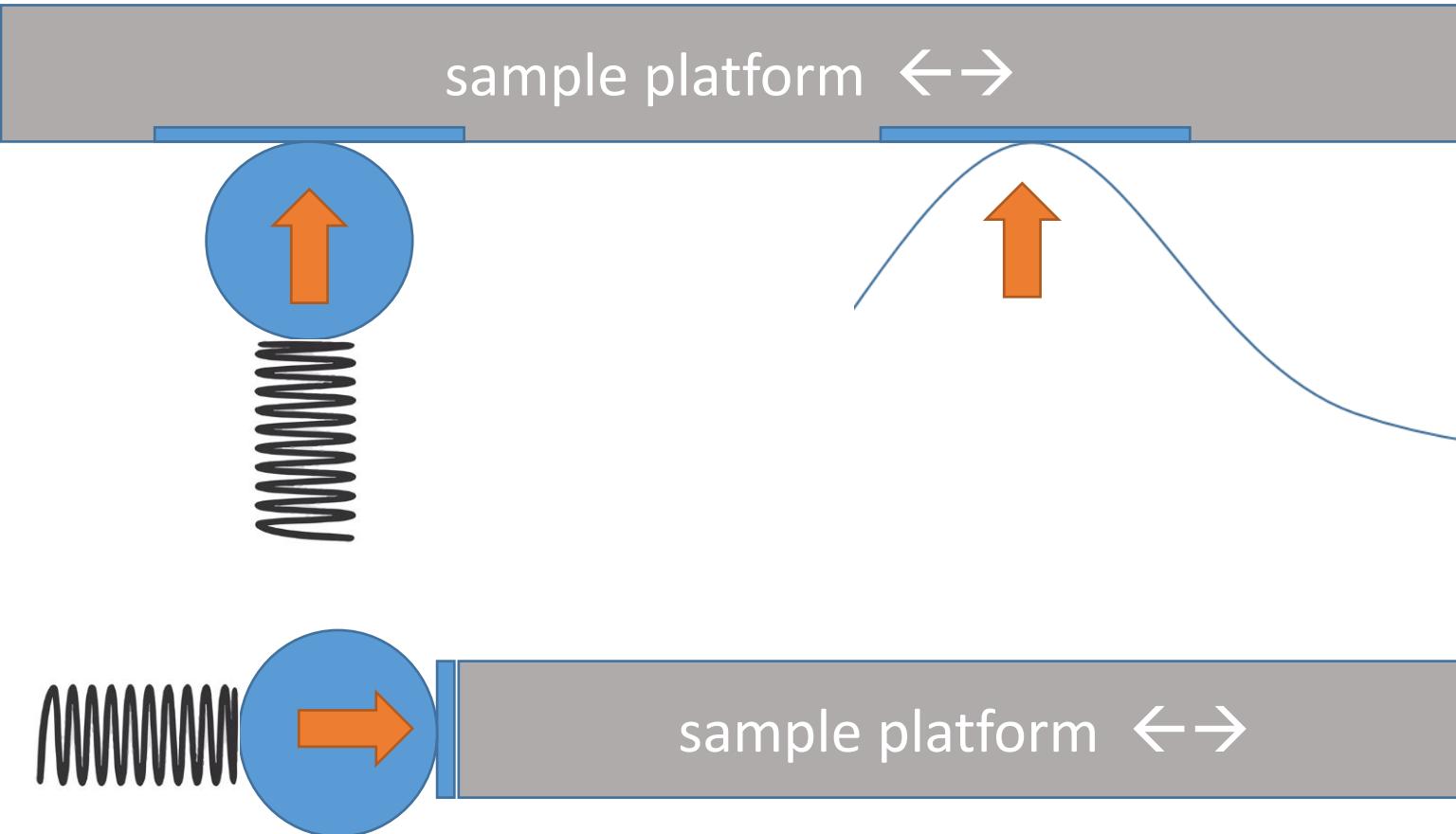
Don't shoot  
sparrows with  
cannons!

# Electrical contact tips



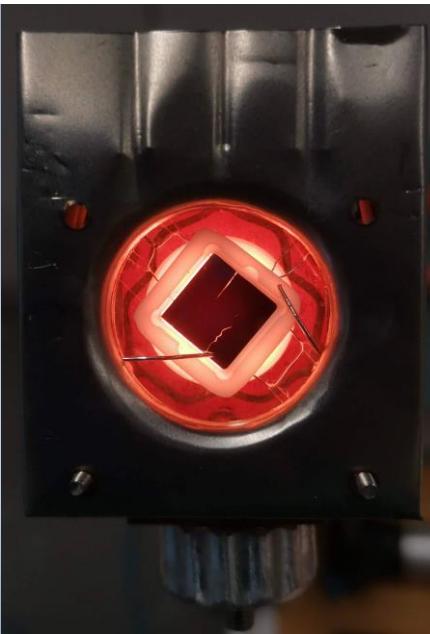
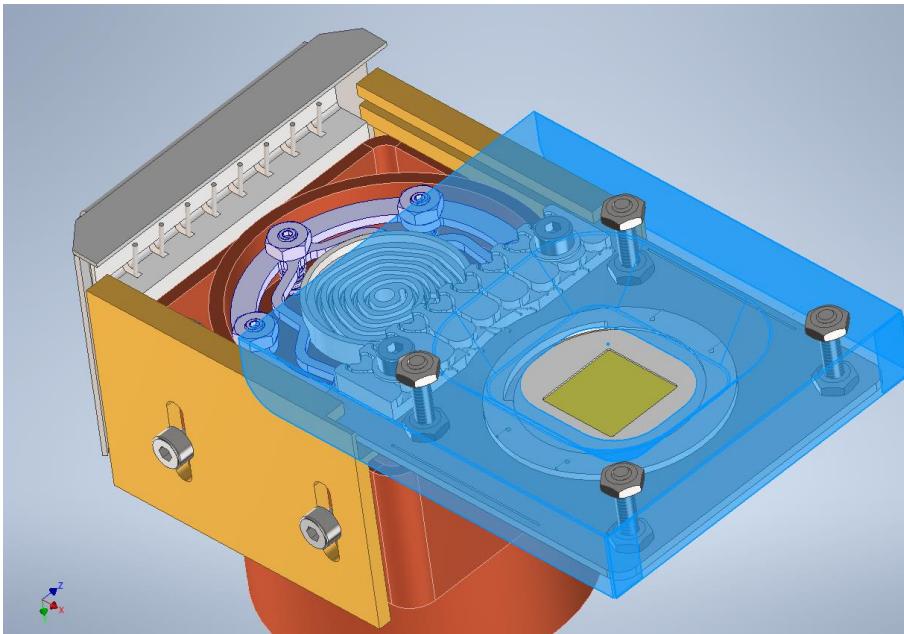
# Spring loaded sliding contacts

Corrosion issues!  
Use TC type S

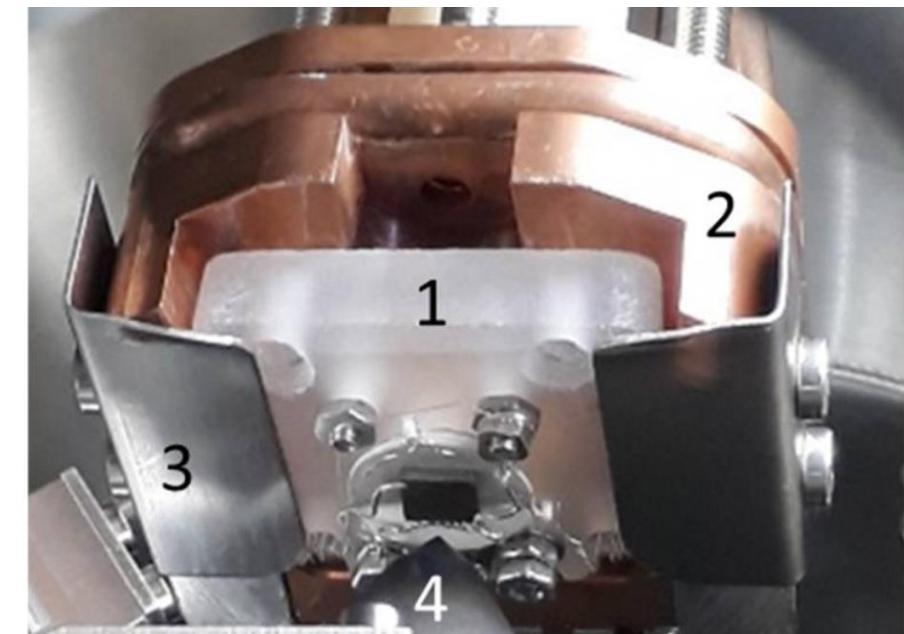


# Sample platforms

PVD systems (HV)



NAP-XPS (UHV)



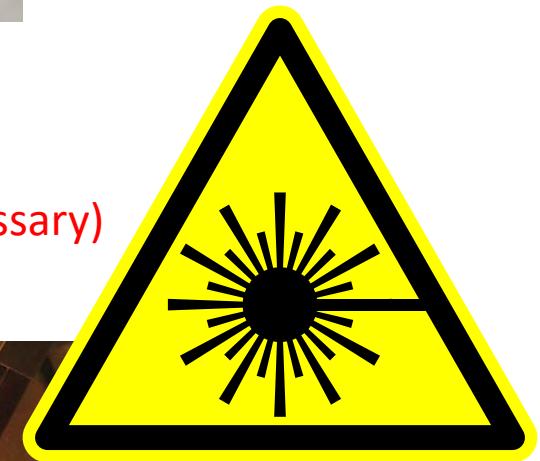
# Heating

- **conduction, convection and radiation**
- **1000 → 10 mbar (laminar flow)**
- **10e<sup>-4</sup> mbar thermal conductivity of the gas low**
  - Radiation → line of sight, distance
  - Convection → gas pressure & gravity
  - Heat conduction → material properties



resistive

Small is beautiful  
(only heat what's necessary)



laser

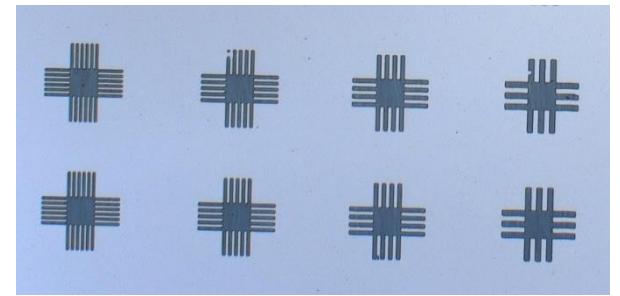
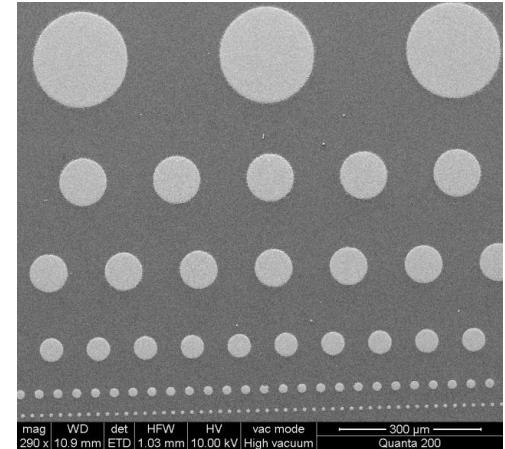
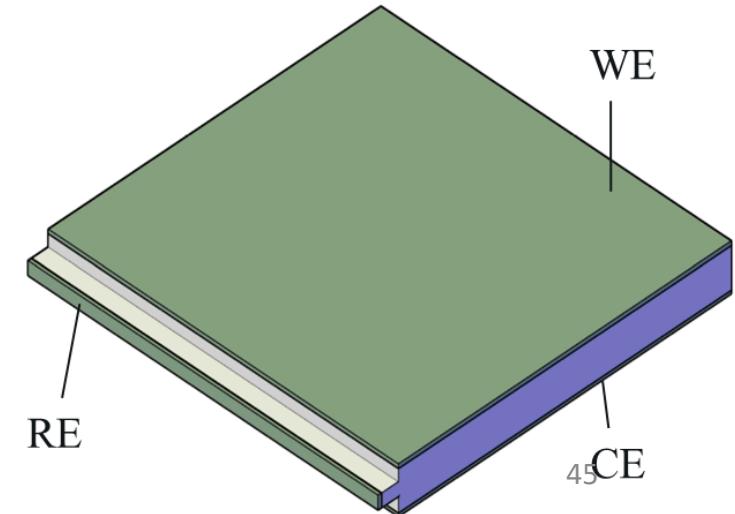
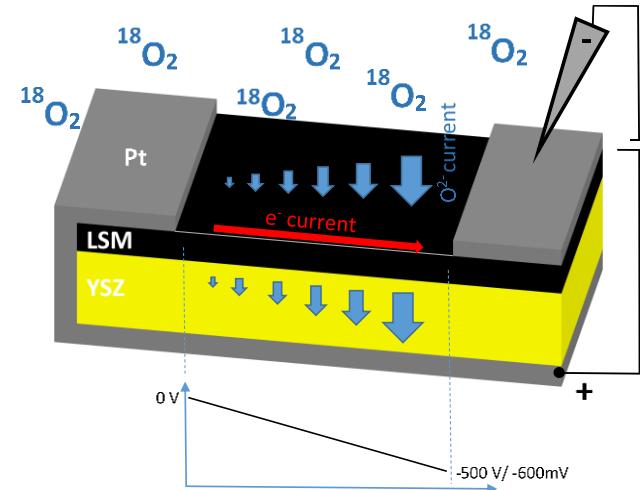
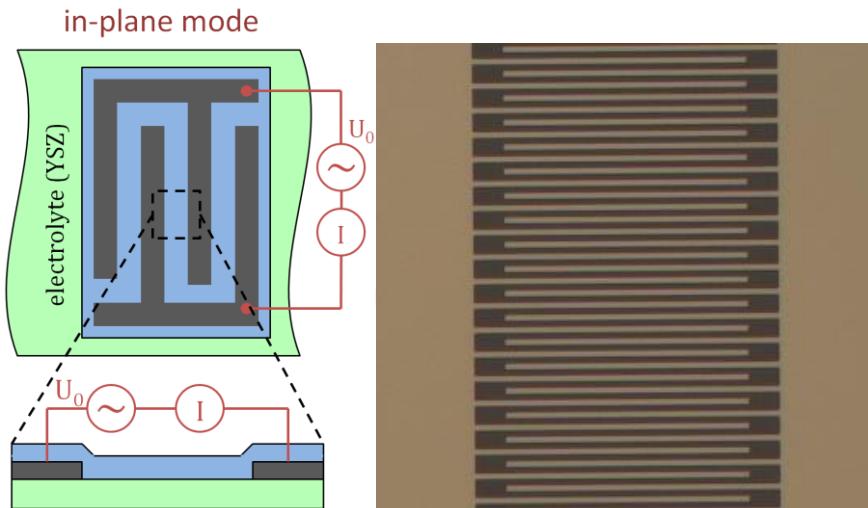


radiation

# Electrode shapes & electrical measurements

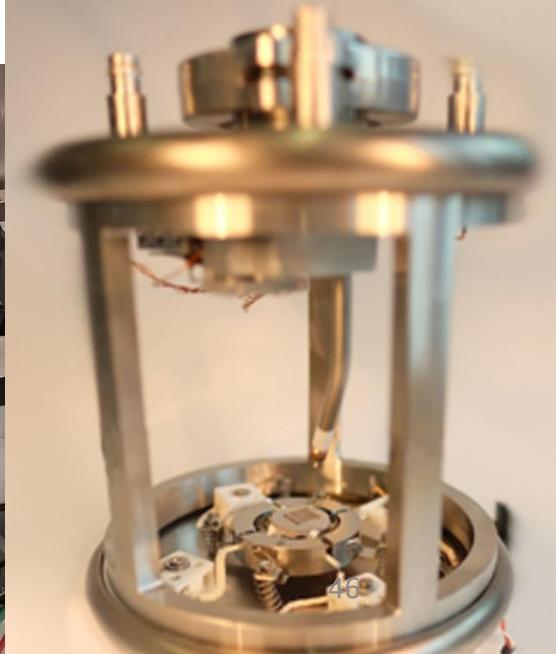
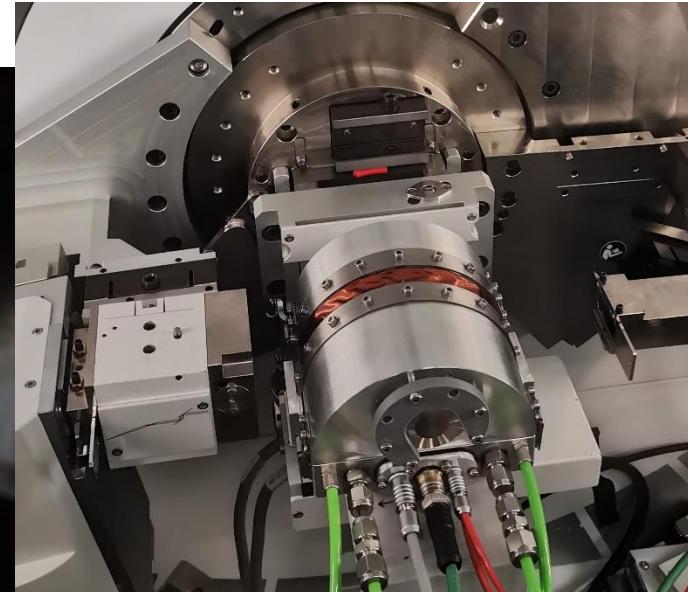
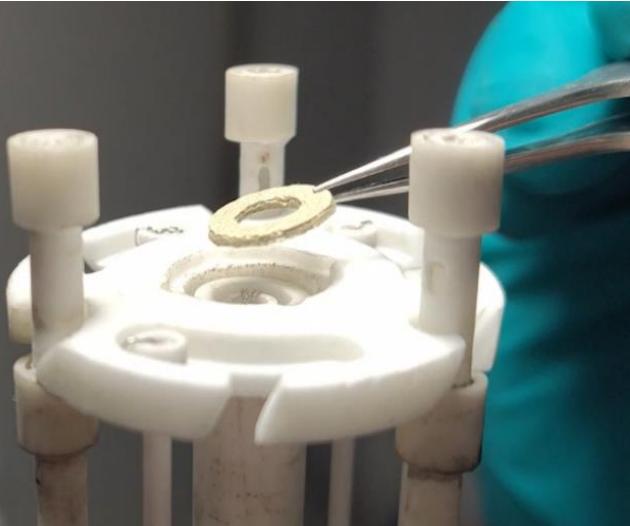
# Electrical measurements

- Symmetric cell
- Asymmetric cell
  - Large difference in R and C of WE & CE
  - Microelectrode
  - Reference electrode
- Special geometries

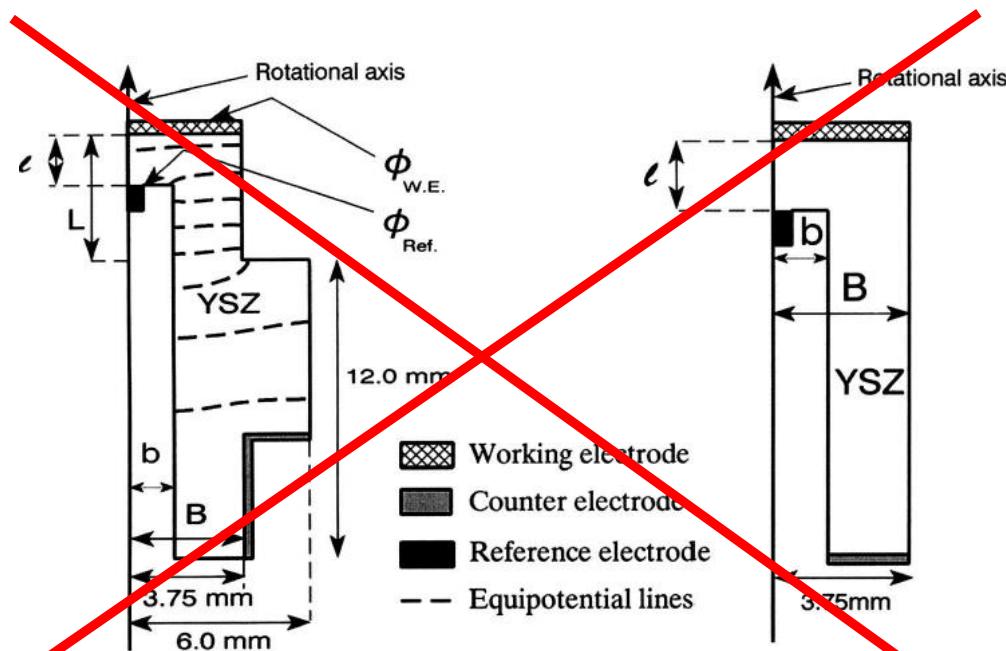


# Advantages of micro patterned thin film electrodes

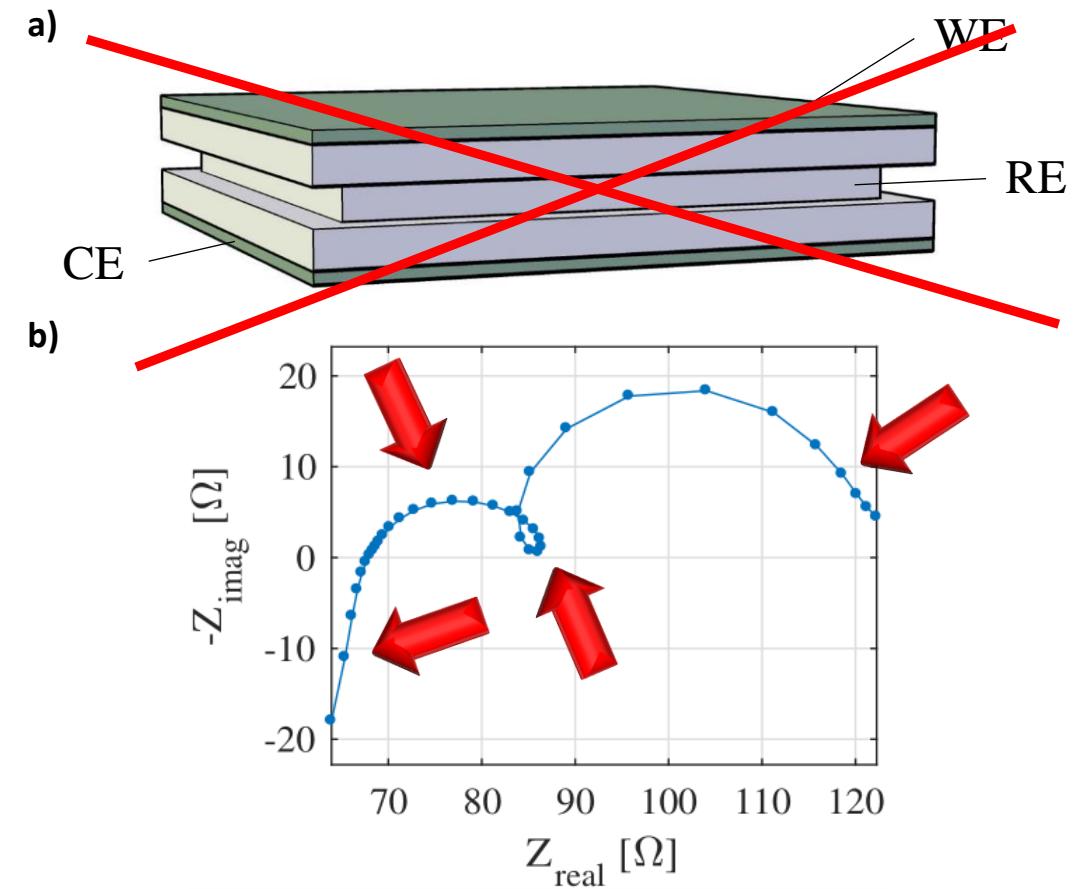
- Well-defined geometry (variable L3PB, ...)
- No reference electrode
- Large number of electrodes
- Direct access to active surfaces
- Current voltage measurements



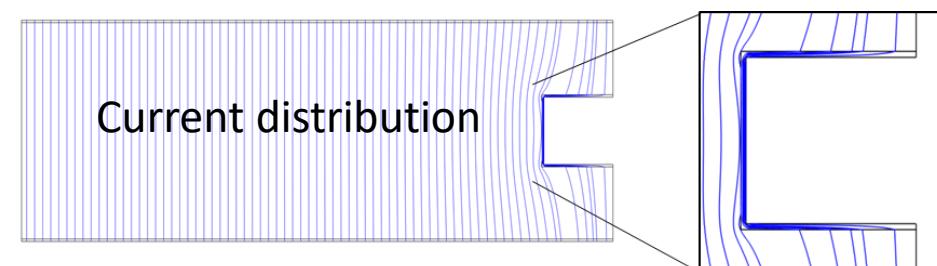
# Reference electrodes



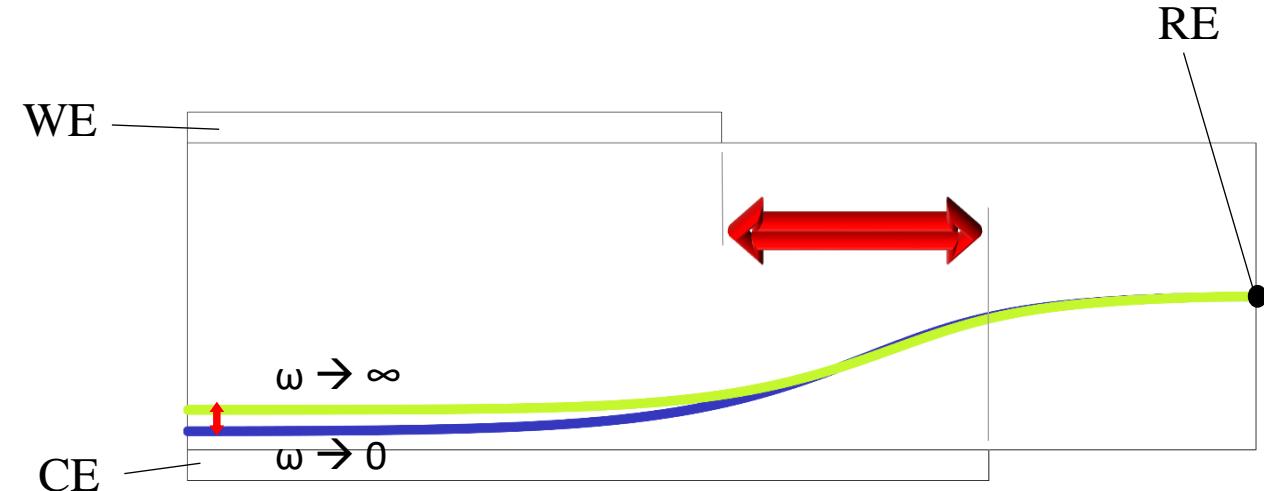
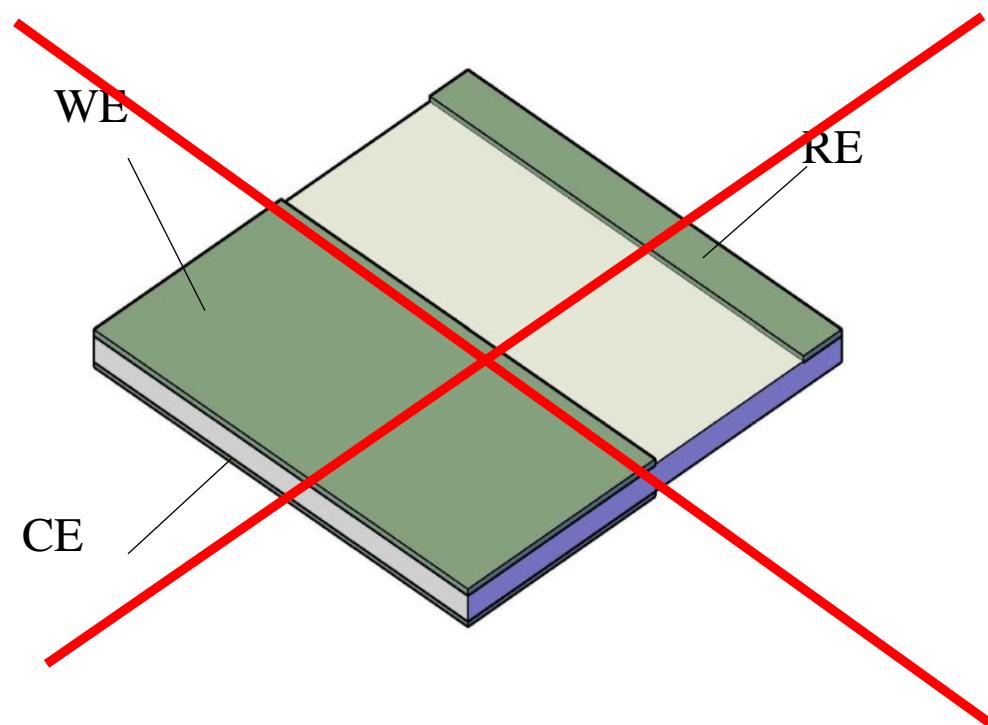
J. Winkler et al., Journal of The Electrochemical Society 145.4 (1998), pp. 1184-1192



- a) **Ring geometry** arrangement with carved reference electrode
- b) Impedance spectra of LSF on YSZ single crystal sample indicating **four measurement errors**



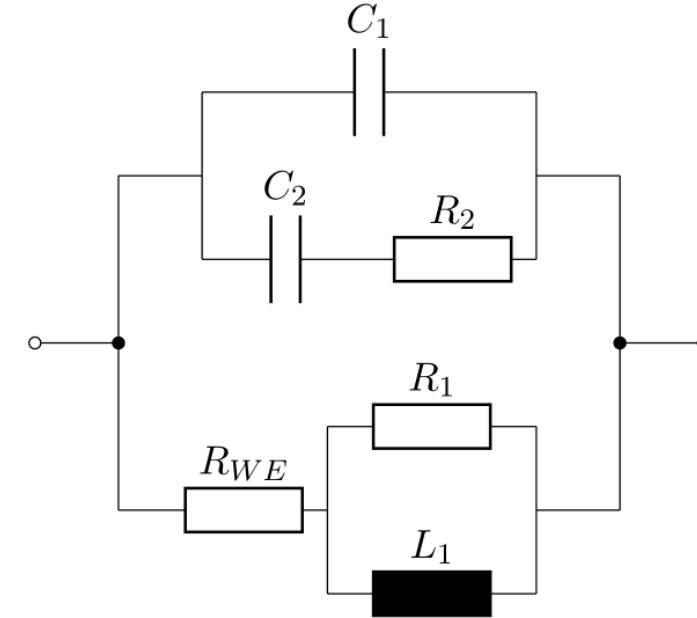
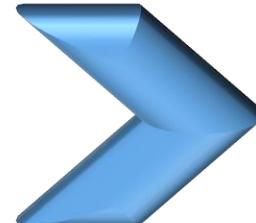
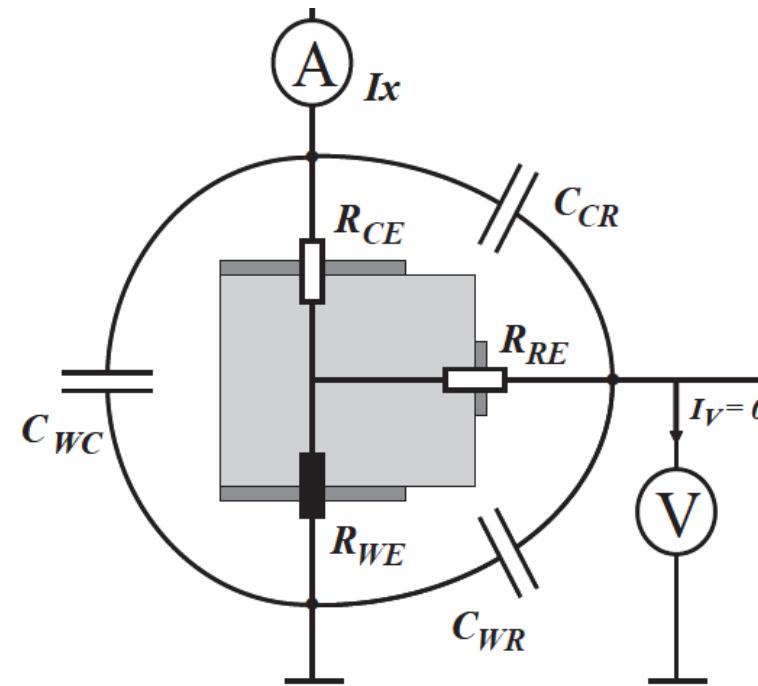
# Widely used 3-terminal measurements



## effect of misaligned electrodes

- asymmetric WE and CE
- potential shift in the reference potential from high to low measurement frequency

# *High resistive samples/ High frequencies*

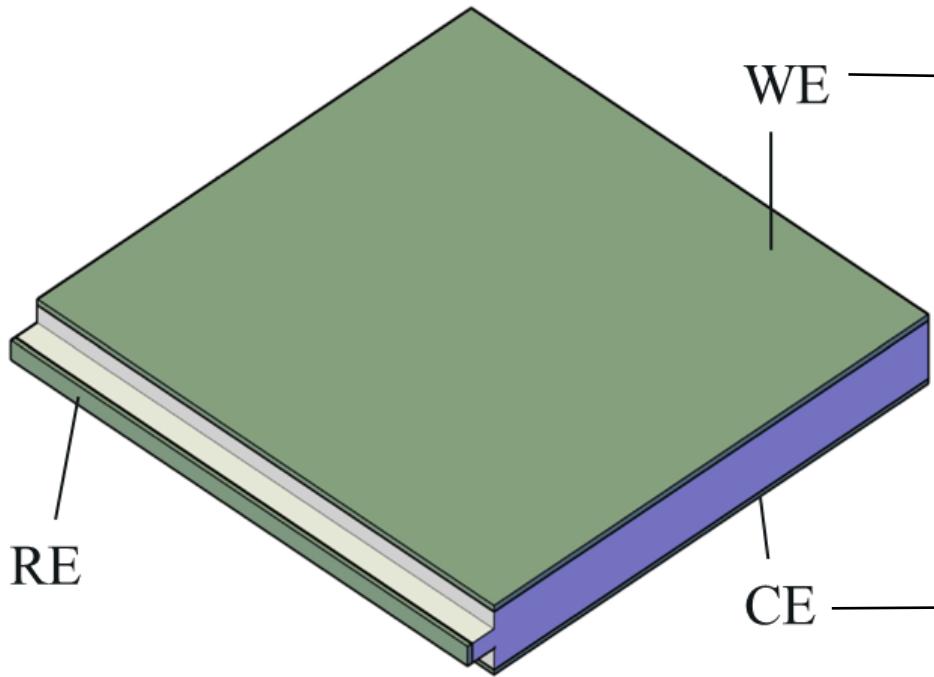


**3-point transfer characteristic**

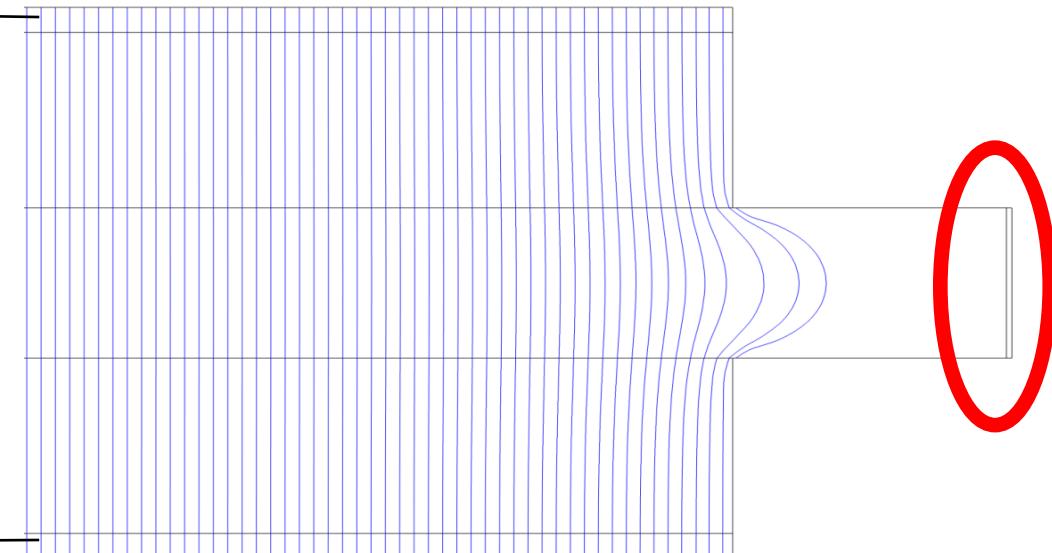
$$\underline{Z}(\omega)_{\text{3-point}} = \frac{\underline{V}}{\underline{I}} = \underline{Z}(\omega)_{\text{2-point, equivalent}}$$

# The novel “WING GEOMETRY”

a)



b)



a) Wing geometry

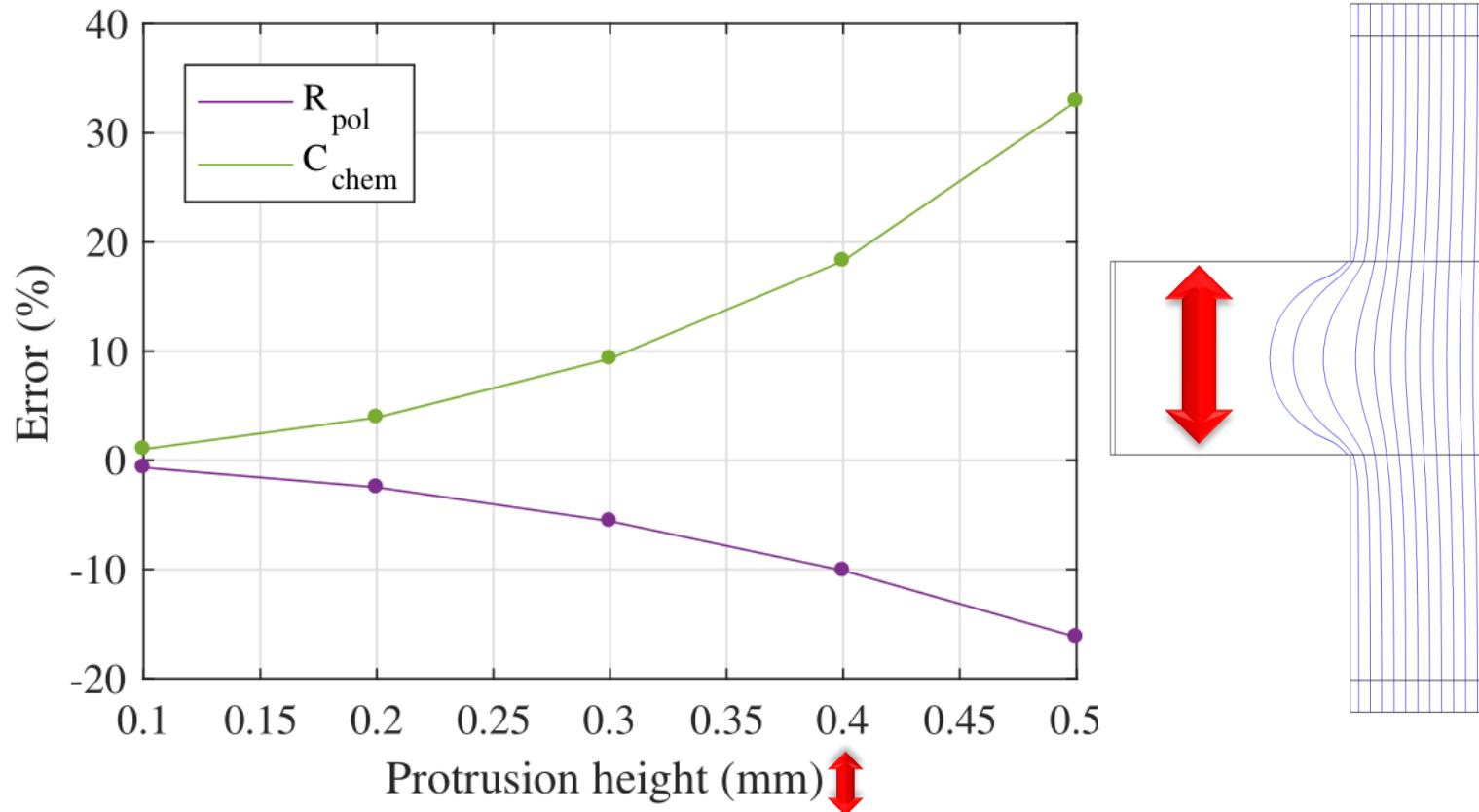
b) Current distribution ( $\omega \rightarrow \infty$ )

- minimal measurement errors
- affordable
- suitable for different applications



Alexander Schmid

# The novel “WING GEOMETRY”

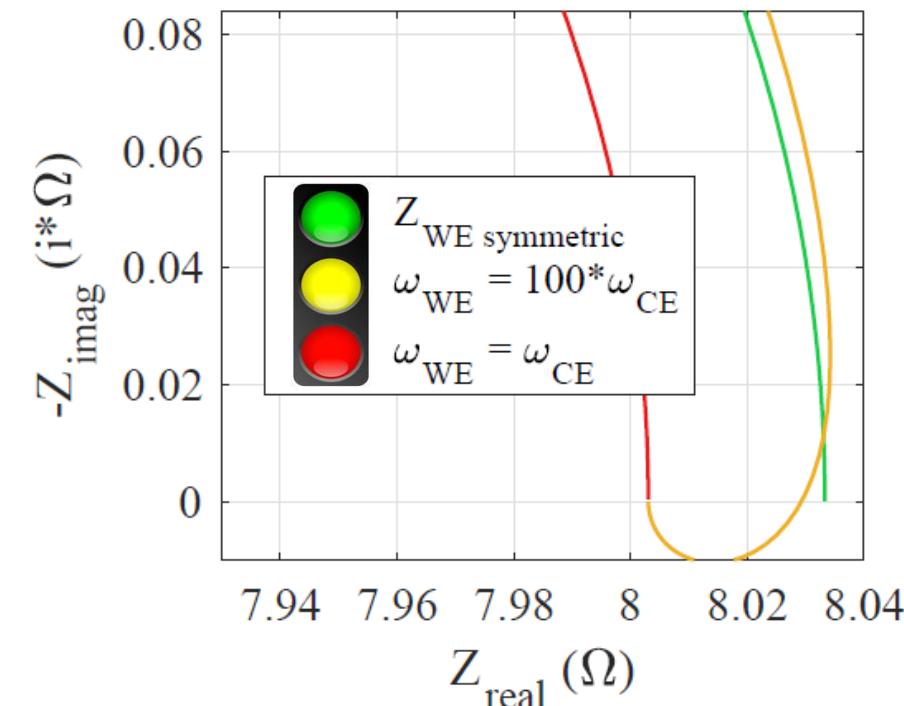
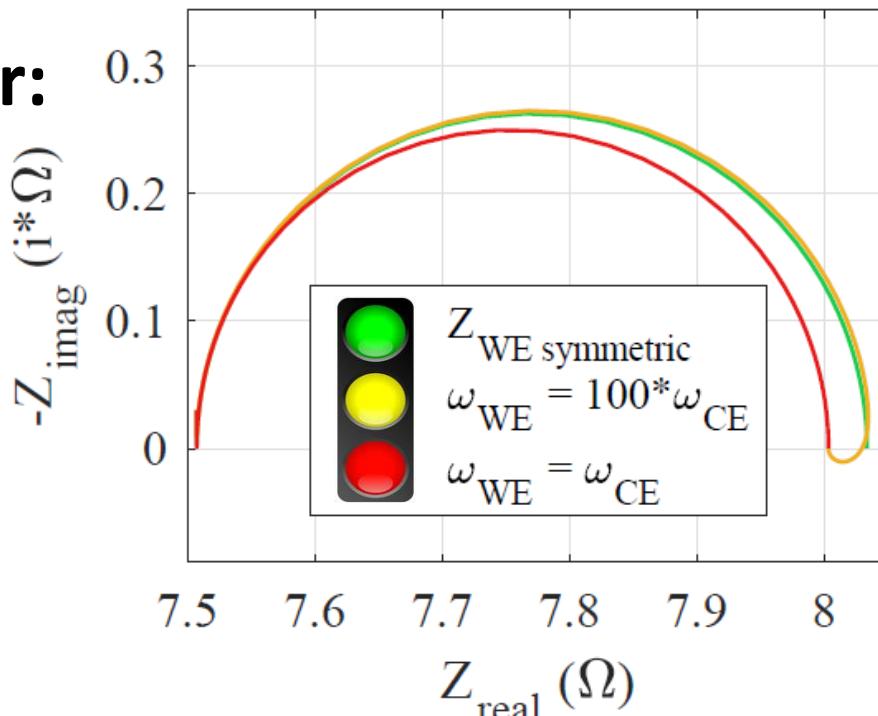


## 3 Error sources:

- 1. 3-point transfer characteristic** (high ohmic electrodes and high frequencies)
- 2. Reference potential shift caused by WE/CE**
  - Geometrical asymmetry
  - Resistive asymmetry
  - Capacitive asymmetry
- 3. Short circuit effect**

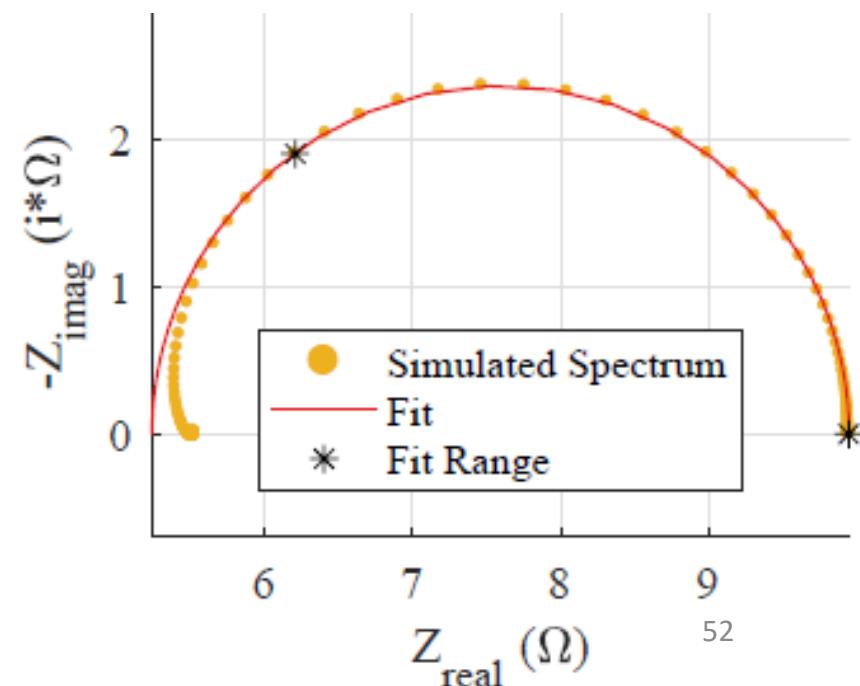
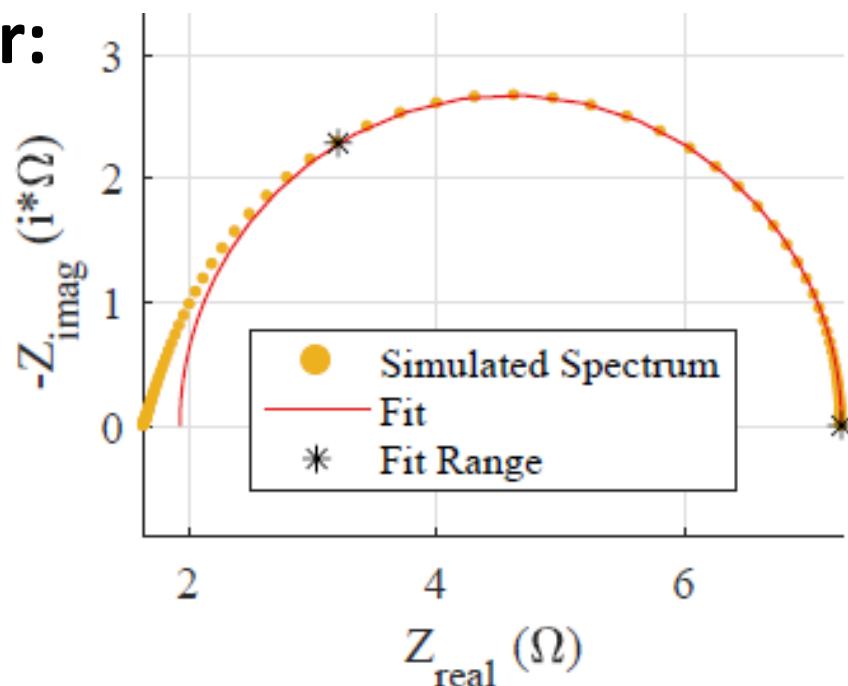
## Low frequency error:

$$\omega = \frac{1}{RC}$$

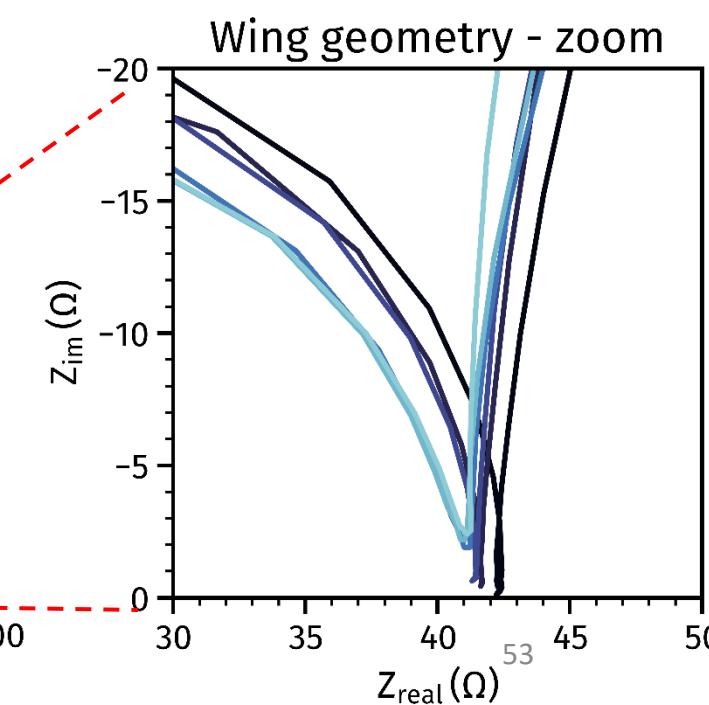
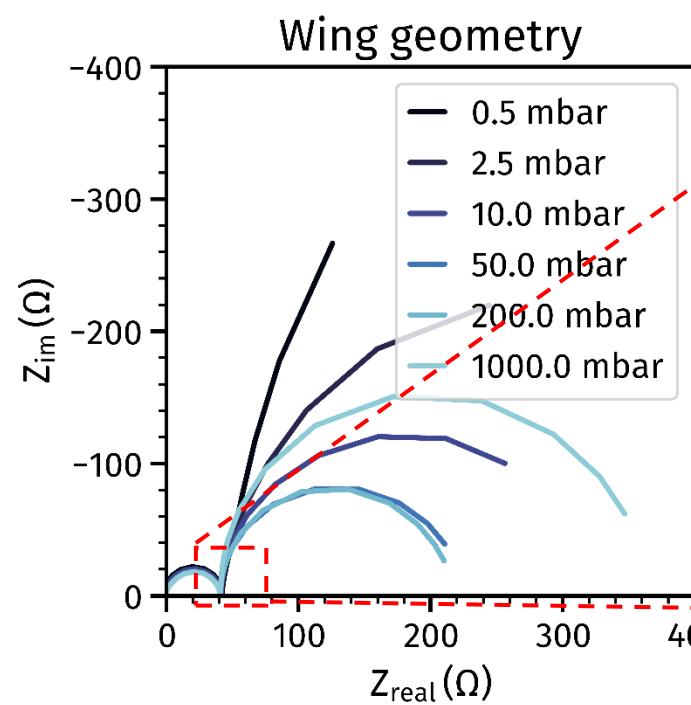
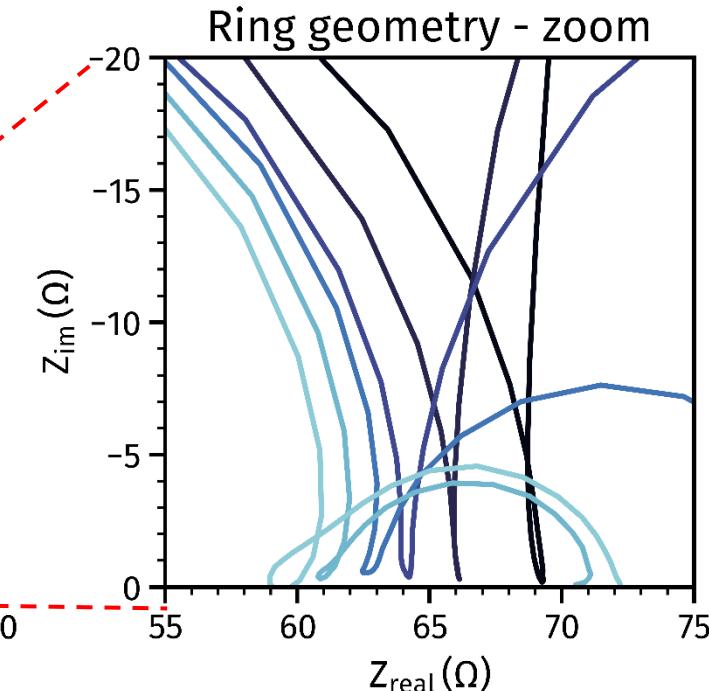
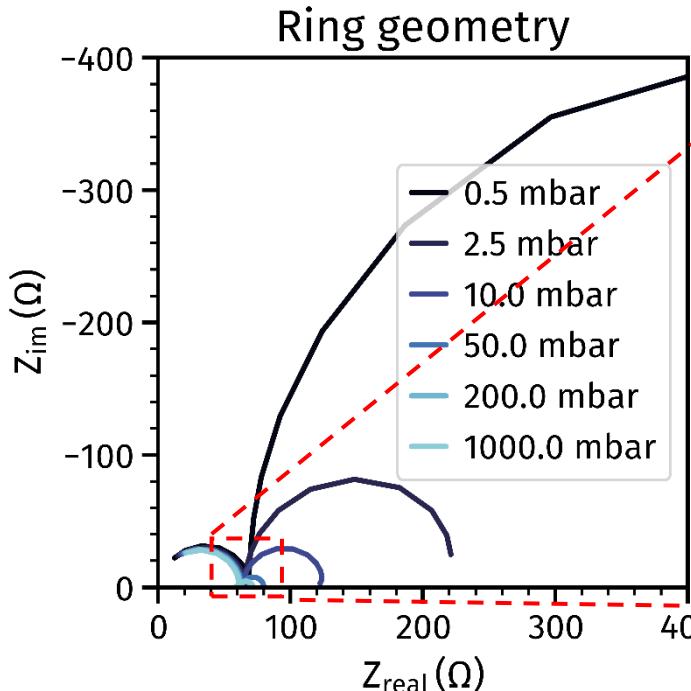
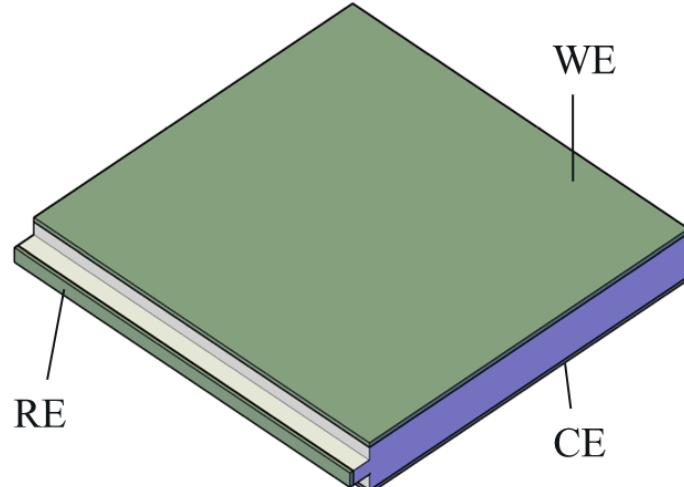


## High frequency error:

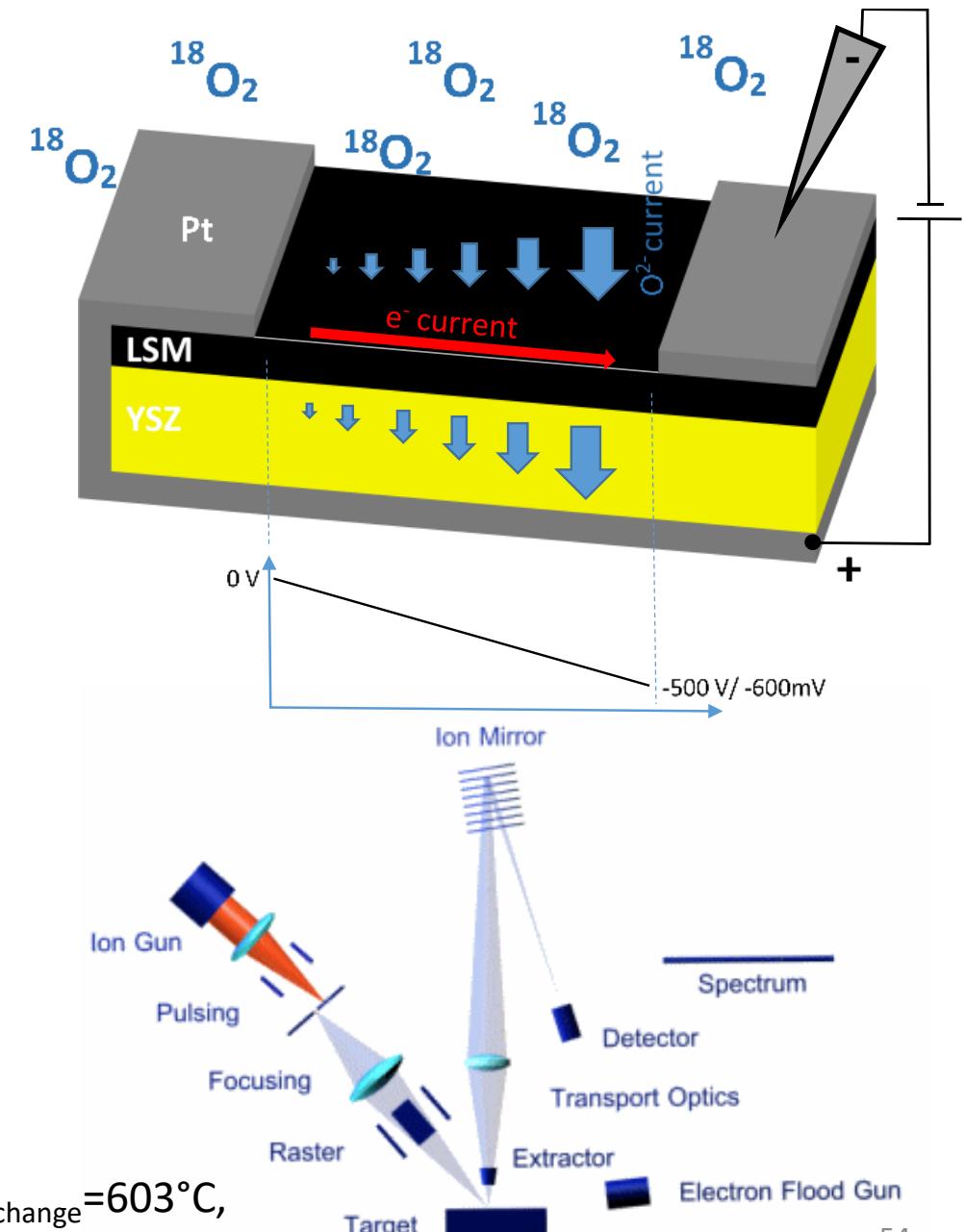
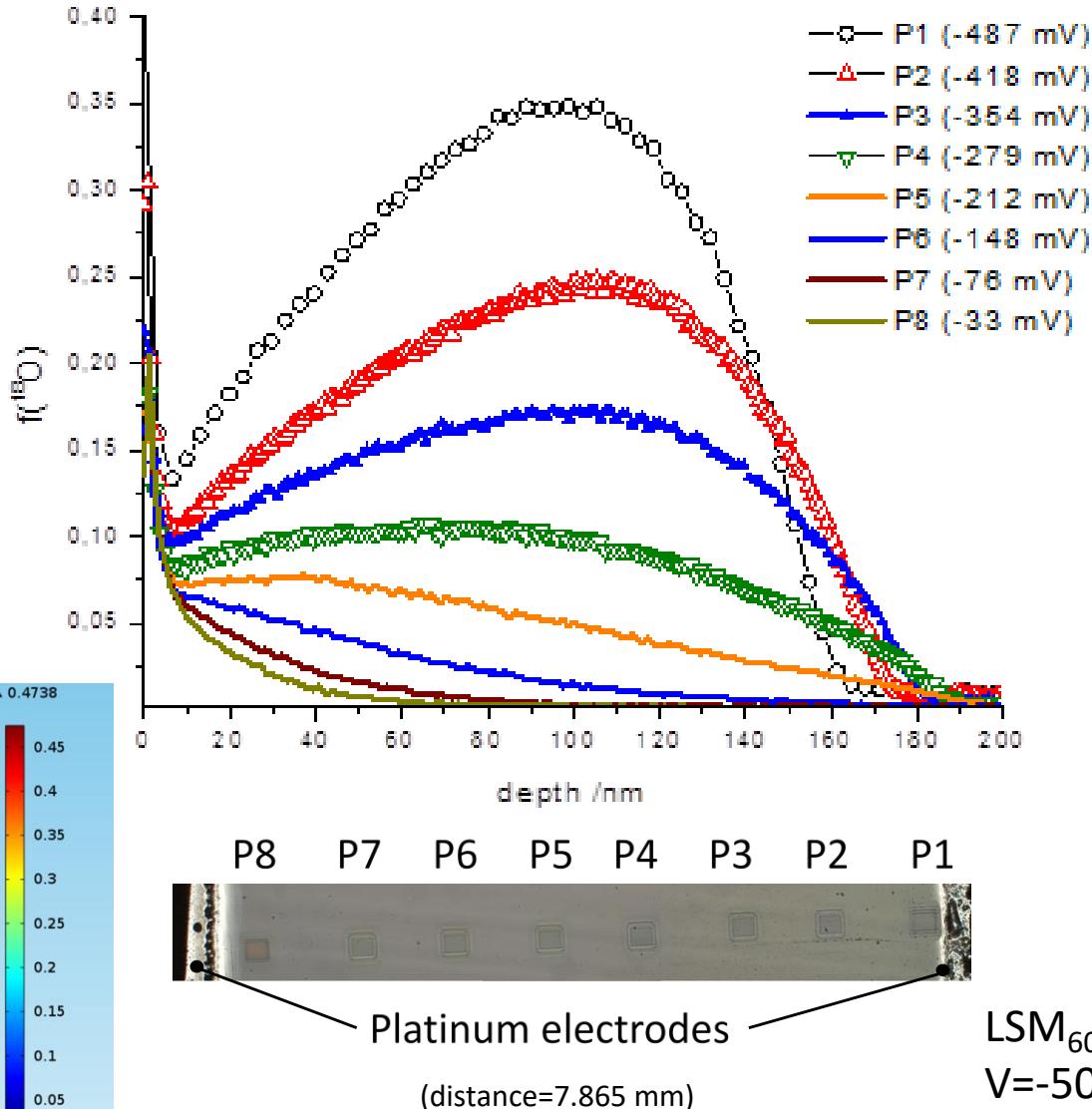
- cross check CE vs RE
- switch WE, CE
- get an idea of WE/CE asymmetry



# The novel “WING” vs. “RING GEOMETRY”

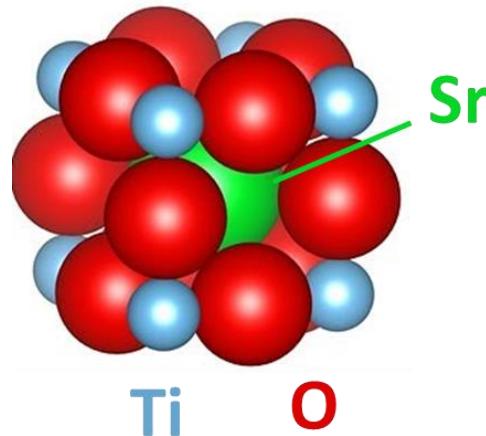


# New experimental design for polarization experiments



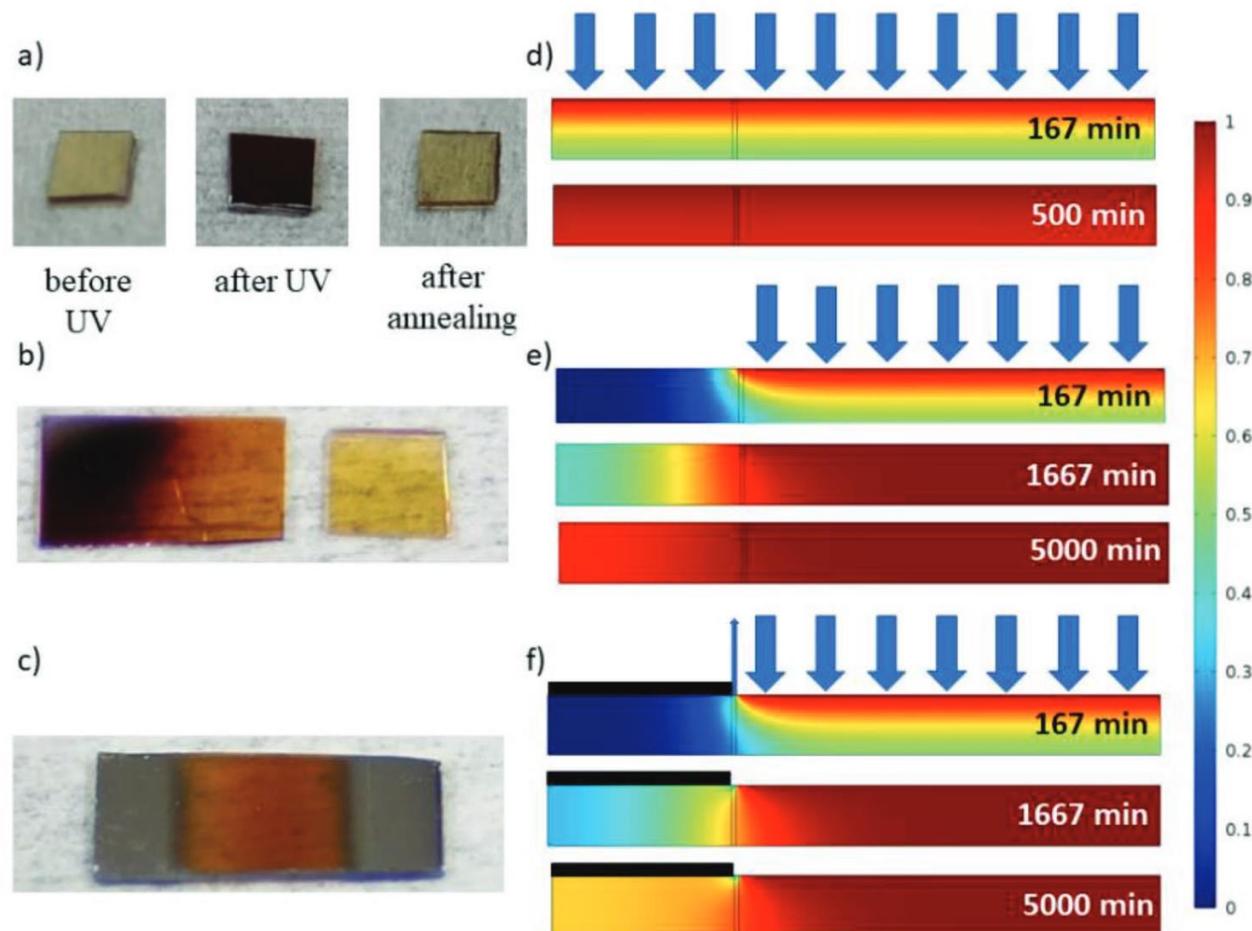
# Temperature & light gradient issues

# Light experiments (shadowing problem)

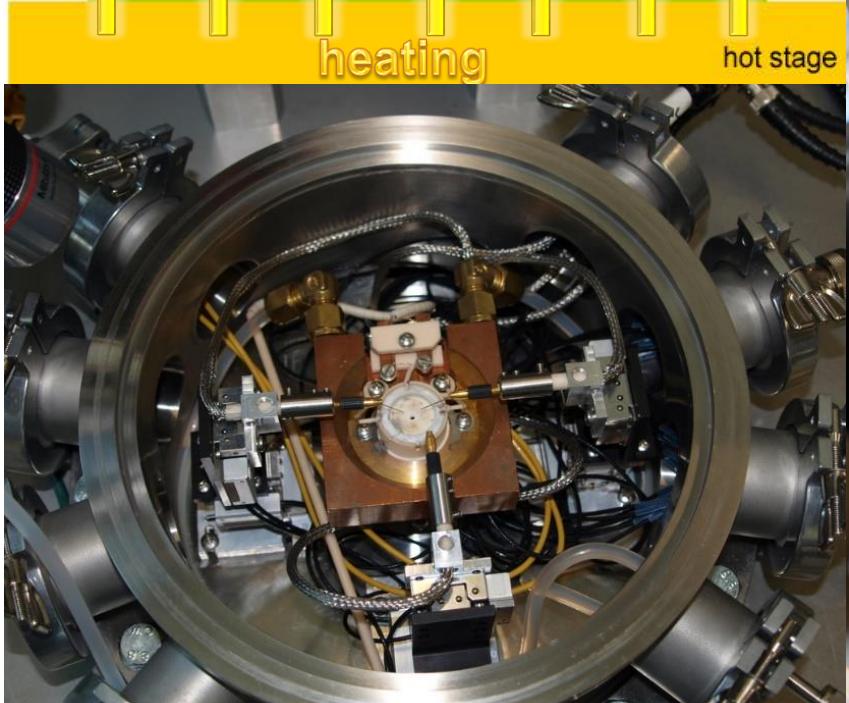
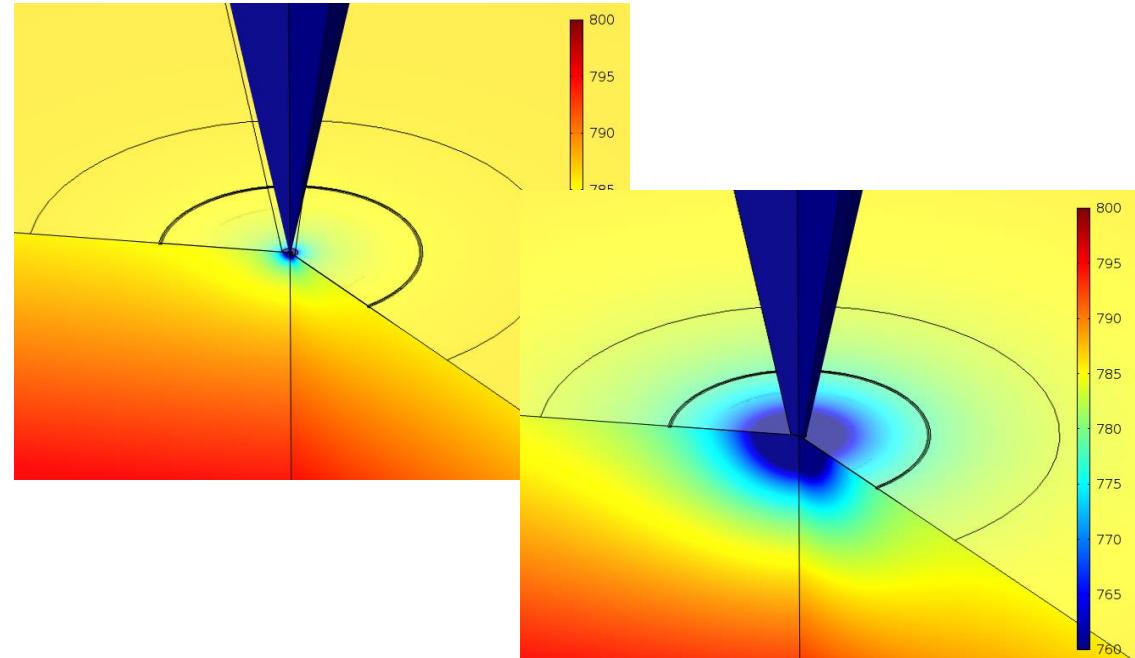
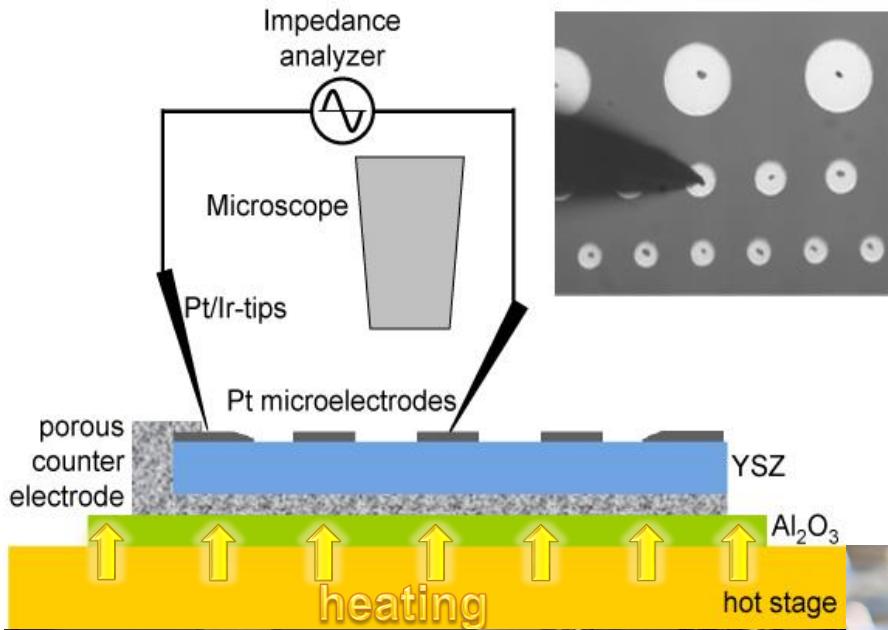


Opto-Ionic effects in  $\text{SrTiO}_3$

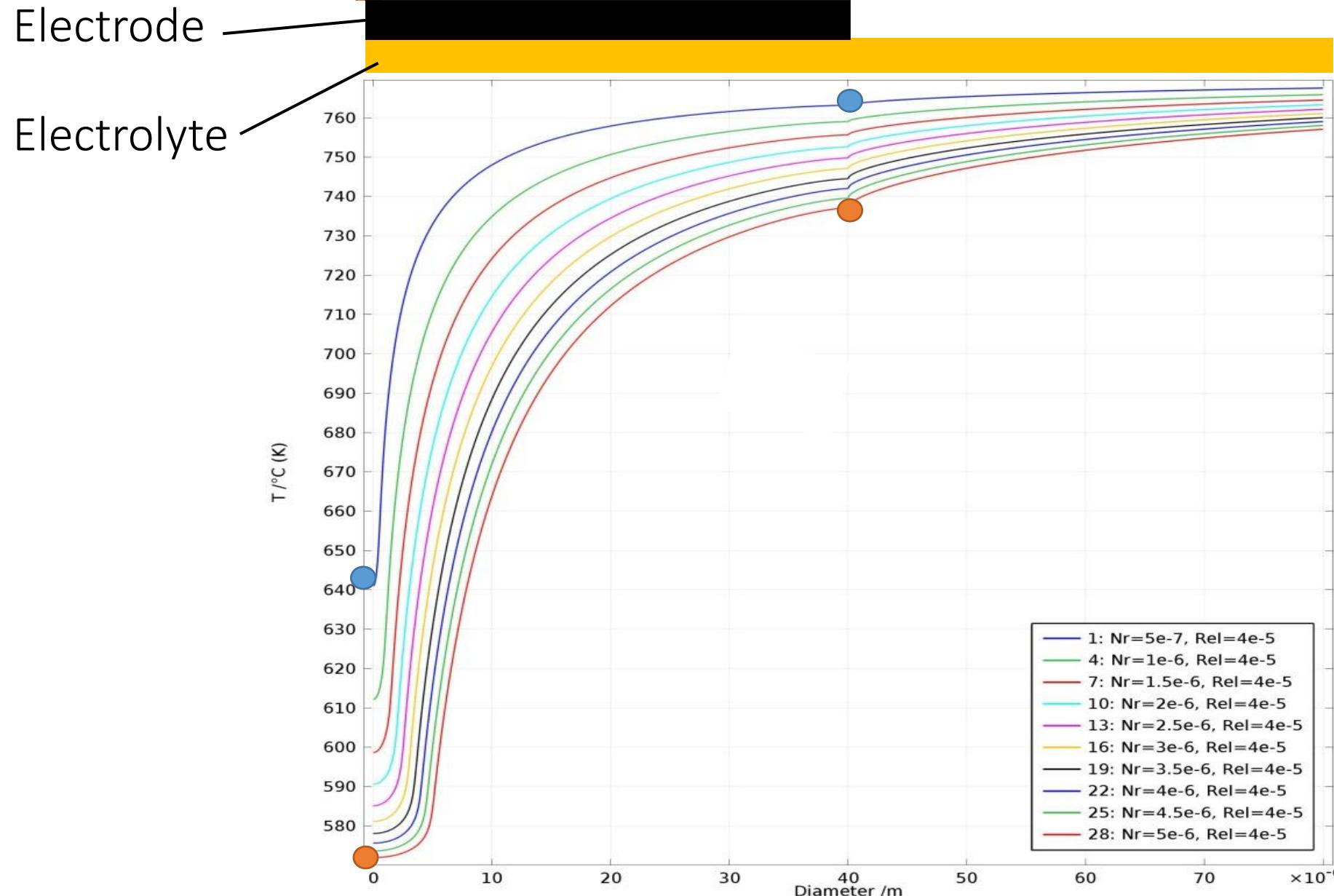
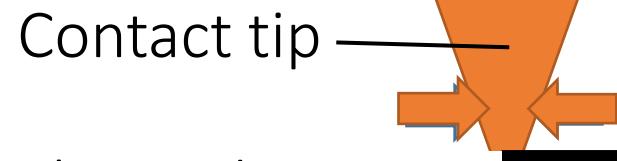
- Perovskite structure
- Model electroceramic
- Indirect bandgap  $\sim 3.2 \text{ eV}$



# Asymmetric heating

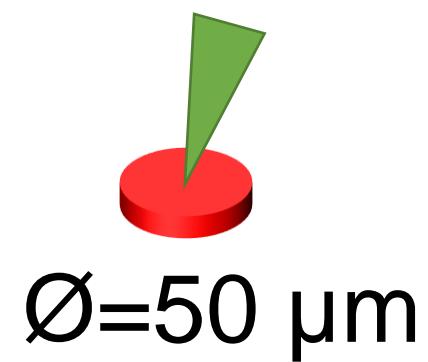
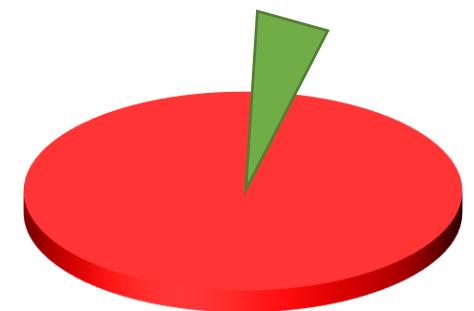


# Finite element calculations



T. M. Huber, et. al. Solid State  
Ionics 268 (2014): 82-93

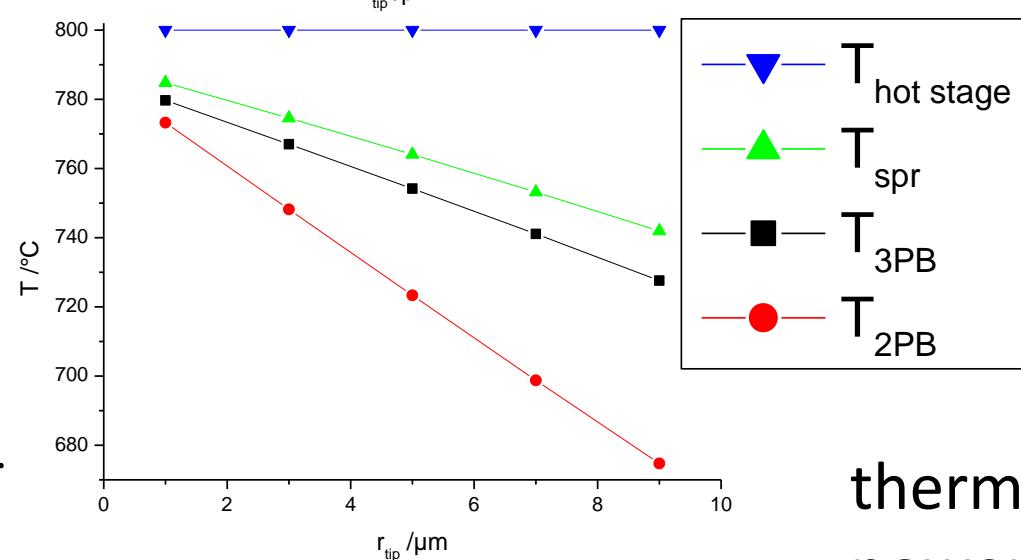
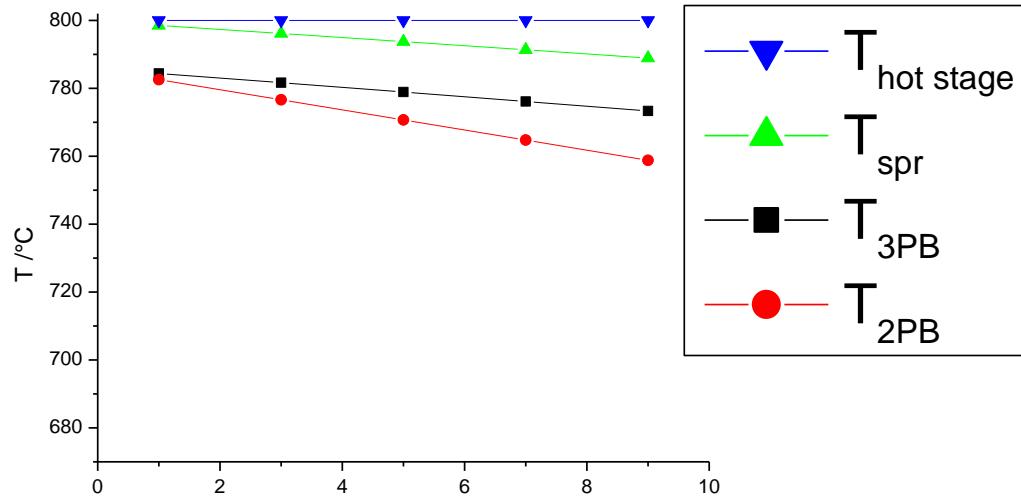
# Temperatures at differently sized electrodes



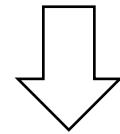
$$T_{2PB} = \frac{4}{d_{ME}^2} \int T(r) \cdot r \cdot 2 \cdot dr$$

**problem:  $\Delta T \rightarrow$  thermo voltage**

E. Ahlgren, F. W. Poulsen; Solid State Ionics 70/71(1994) 528-532



$$\sigma_{ion} = \frac{1}{2d_{ME}R_0} = \sigma^* \cdot e^{-\frac{E_a}{k_B T}}$$

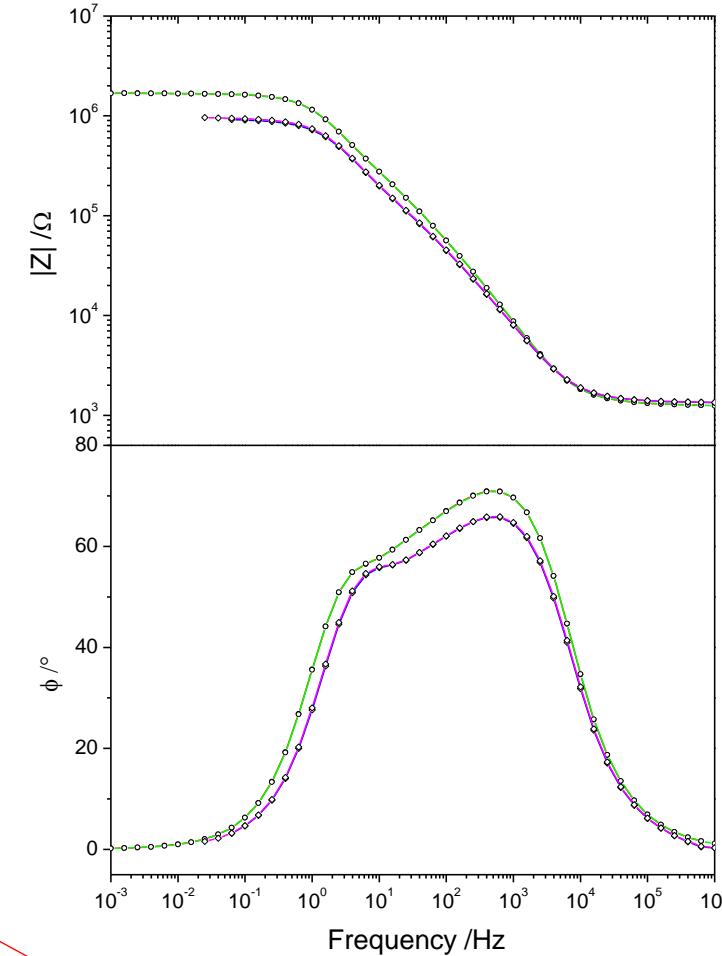
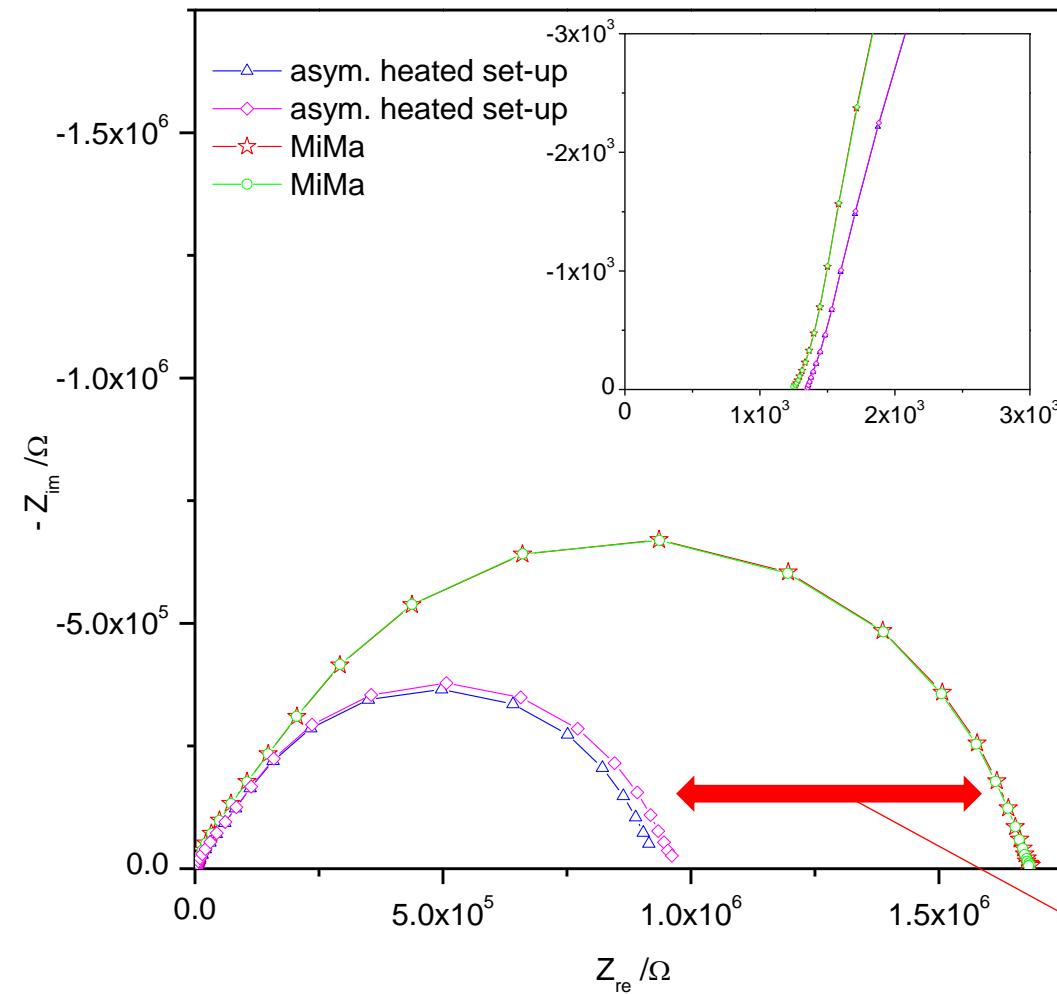


$$T_{spr} = \frac{E_a}{k_B \cdot \ln(2d_{ME}R_0)}$$

thermoelectric  
power (0.486 mV/K  
YSZ in air [1])

# Impedance spectroscopy on microelectrodes

## 145 $\mu\text{m}$ squared LSM microelectrode at 760 °C



error induced by thermovoltage



Institute of Chemical Technologies  
and Analytics



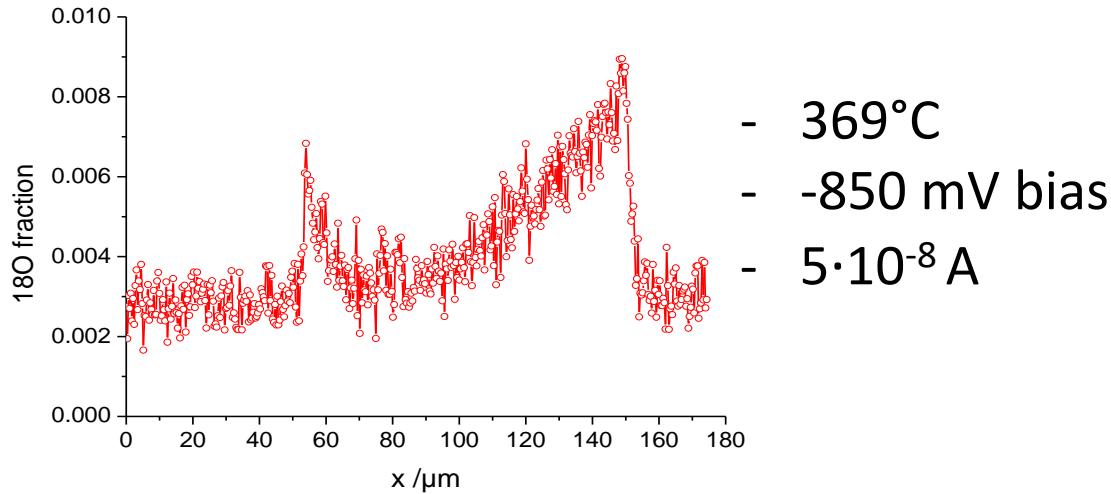
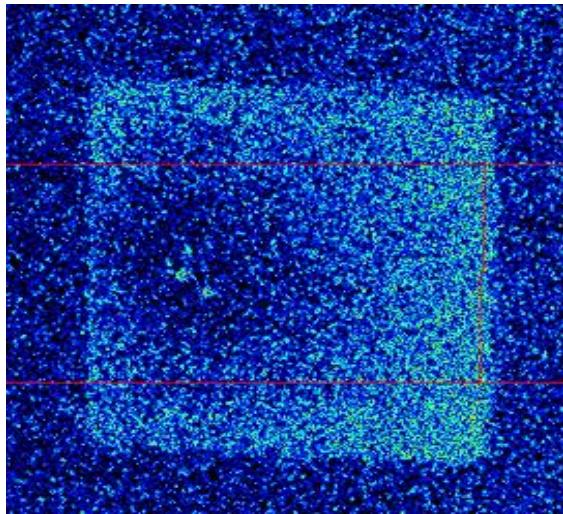
 huber  
scientific  
novel measurement solutions

# PIZZA

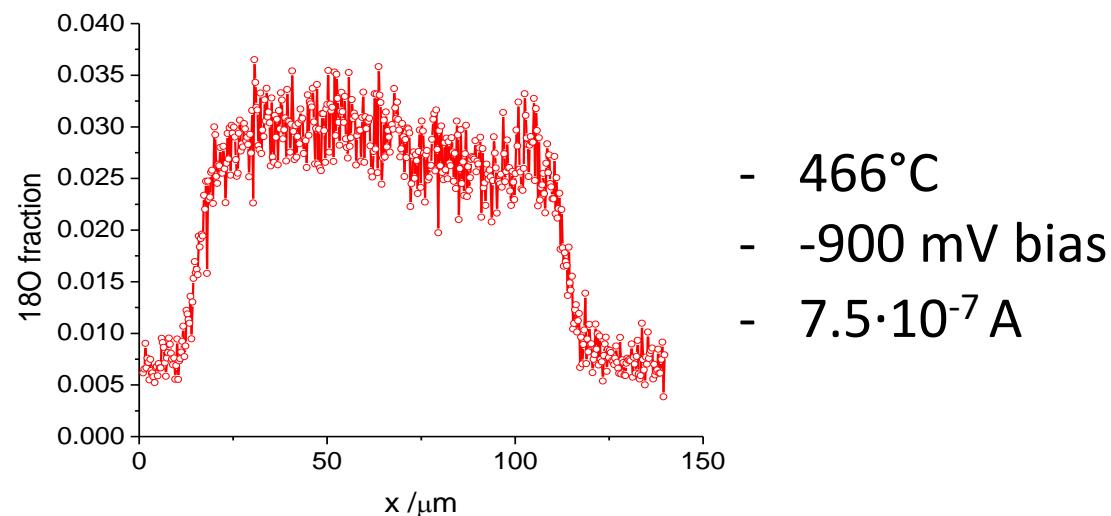
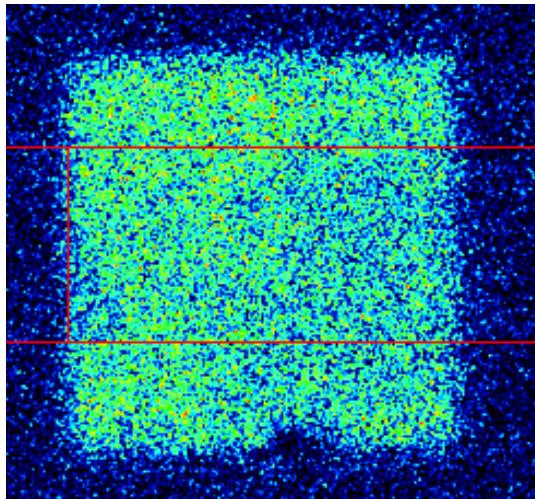
- Surface de wetting → Mozarella

# DC-polarization with $^{18}\text{O}$ tracer

## asymmetrically heated set-up

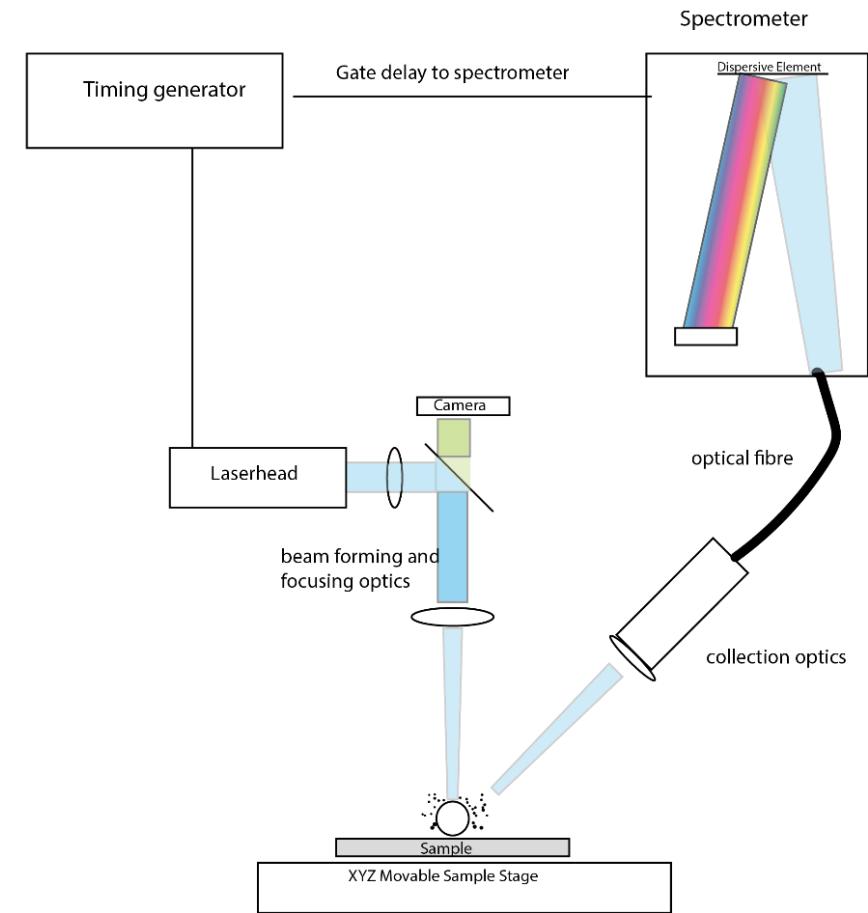
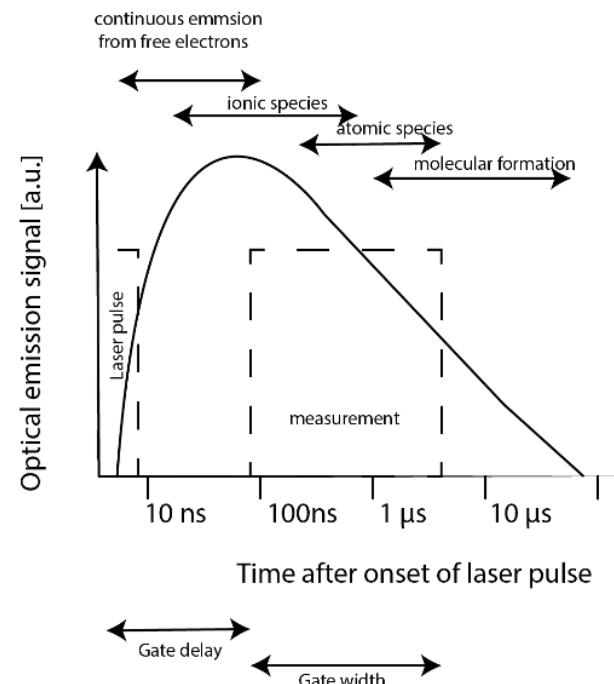
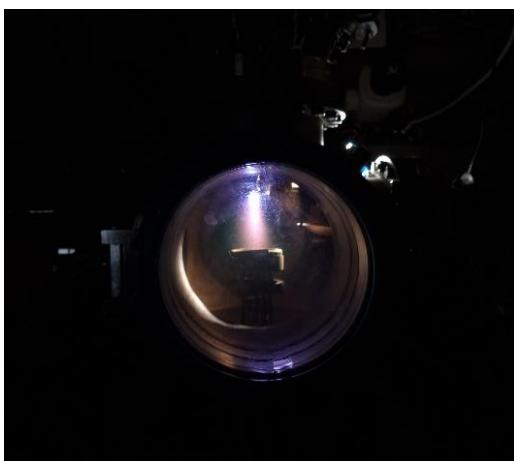


## symmetrically heated set-up

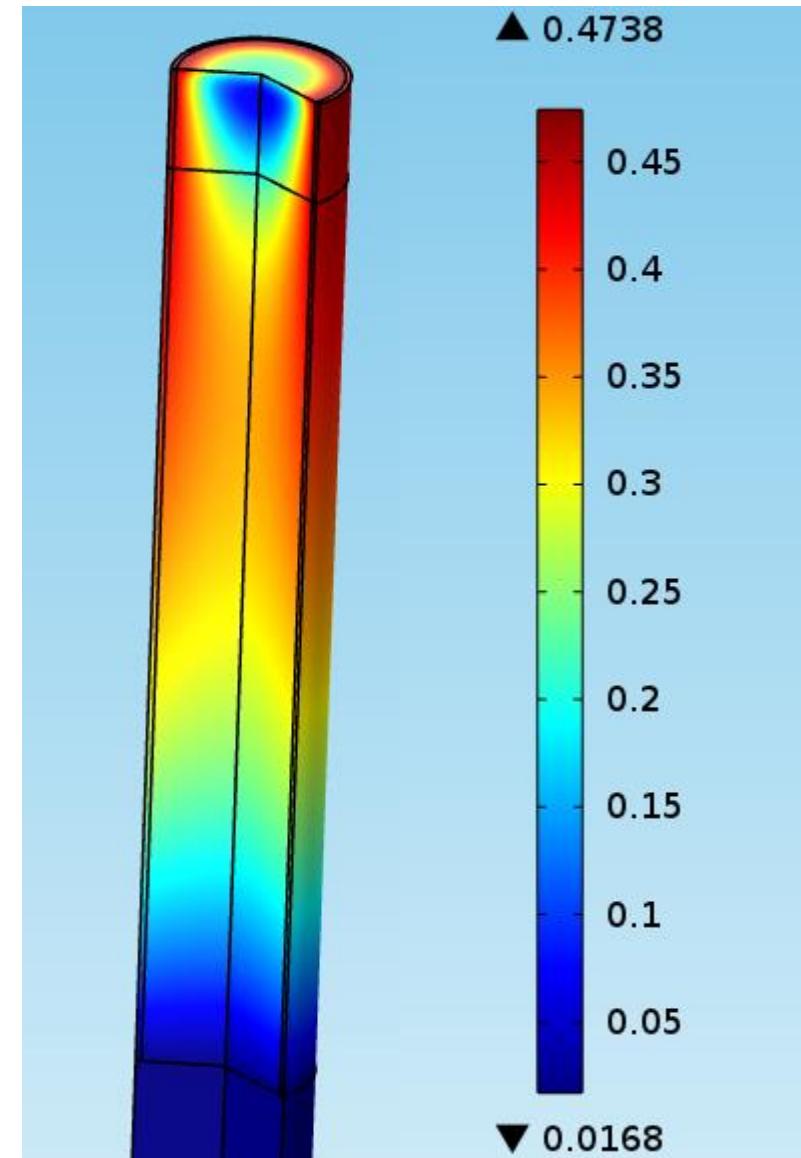
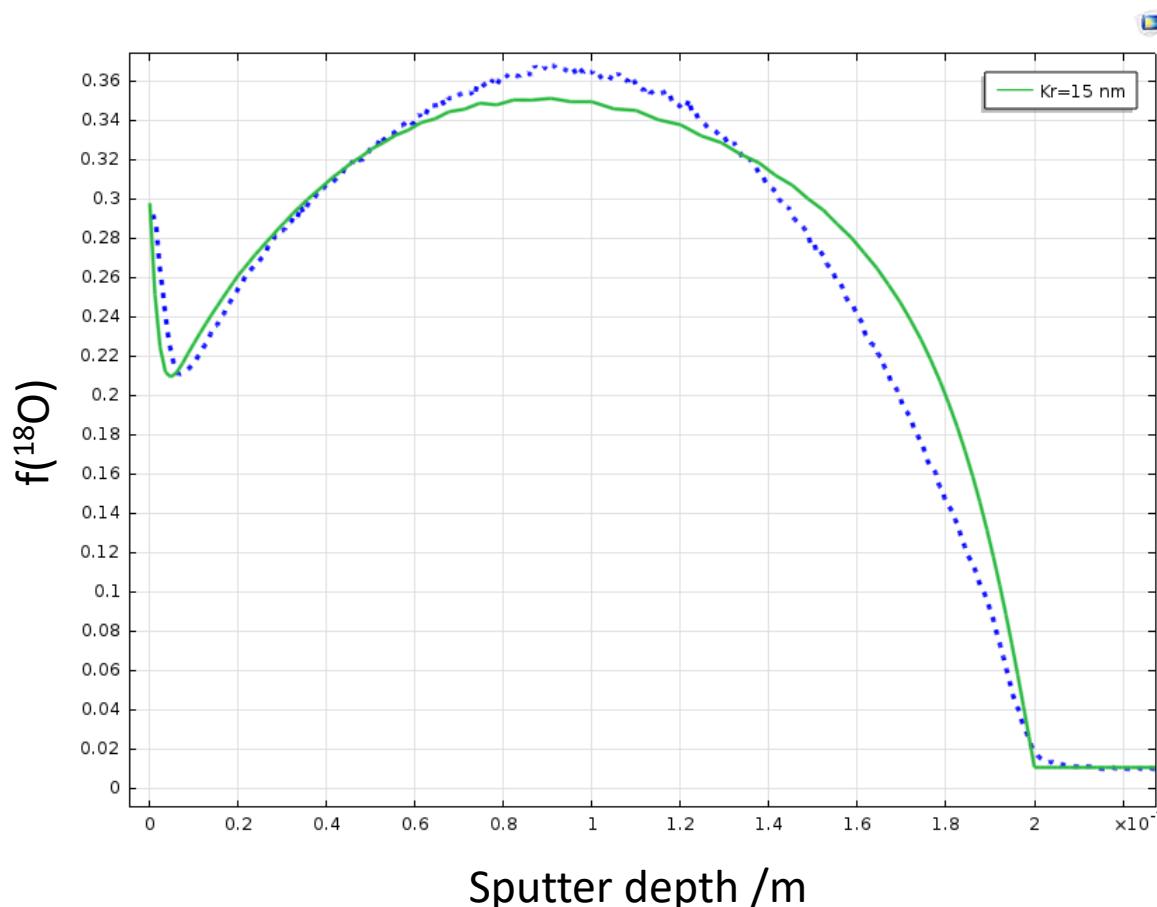


# Laser induced breakdown spectroscopy

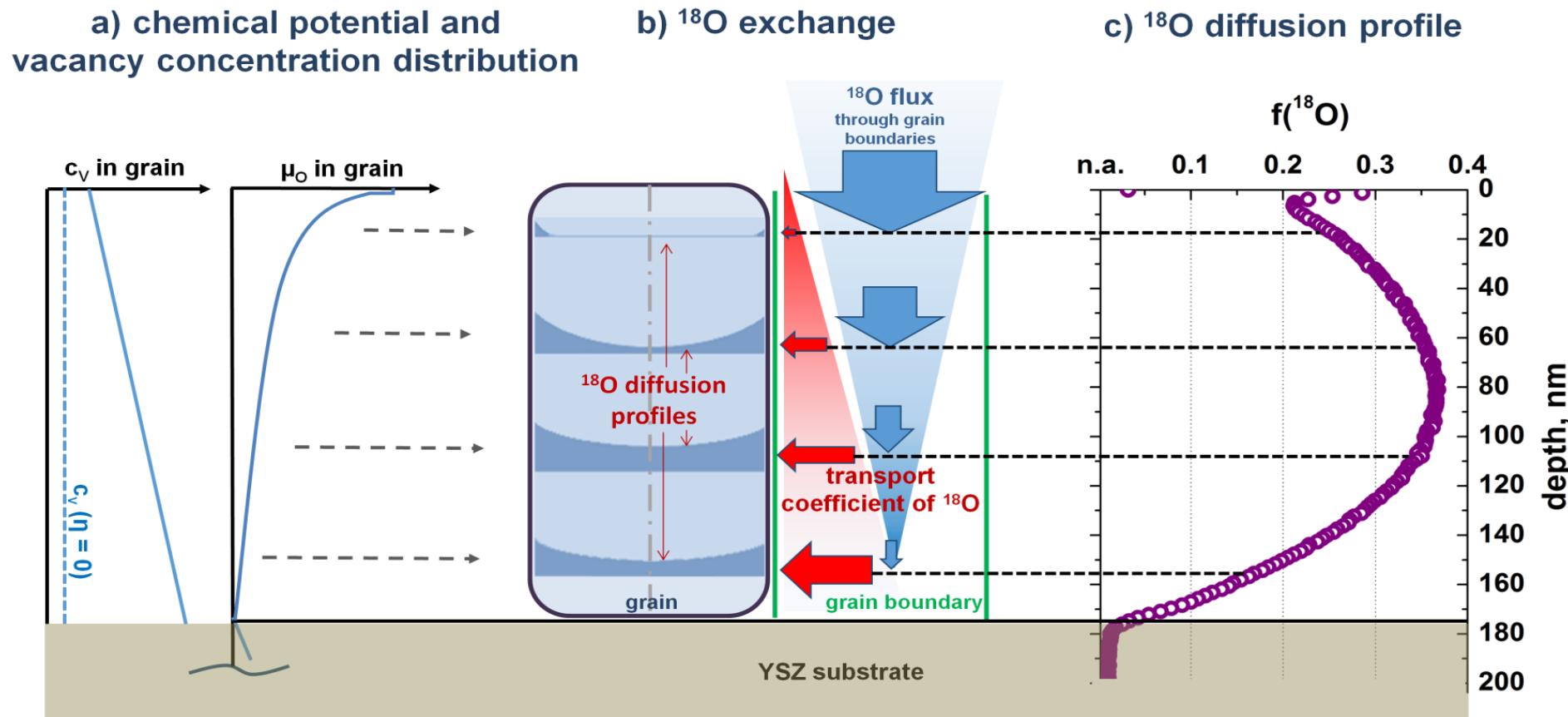
- **Laser pulse evaporates sample**
  - (same mechanism as PLD)
- **Removed material forms plasma**
- **Plasma emits characteristic elemental emission → detected and quantified**



# Apparent uphill diffusion /finite element fitting

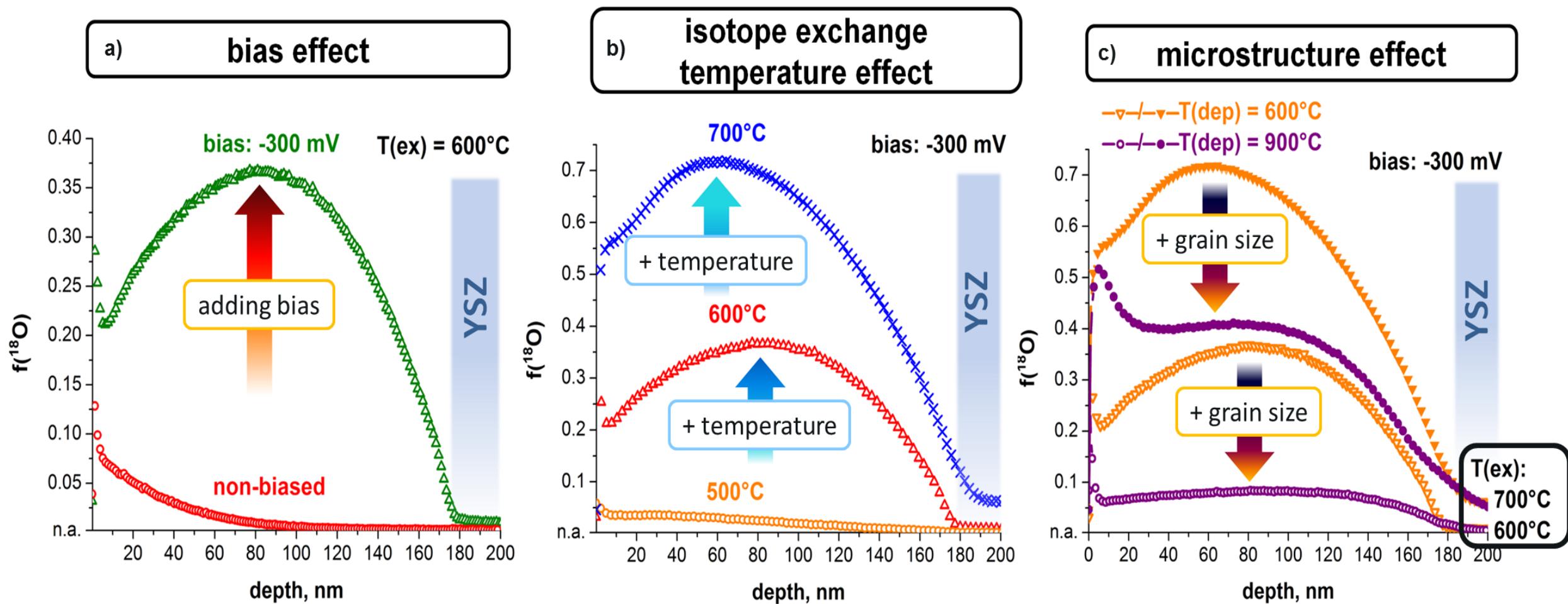


# Evolution of apparent uphill diffusion

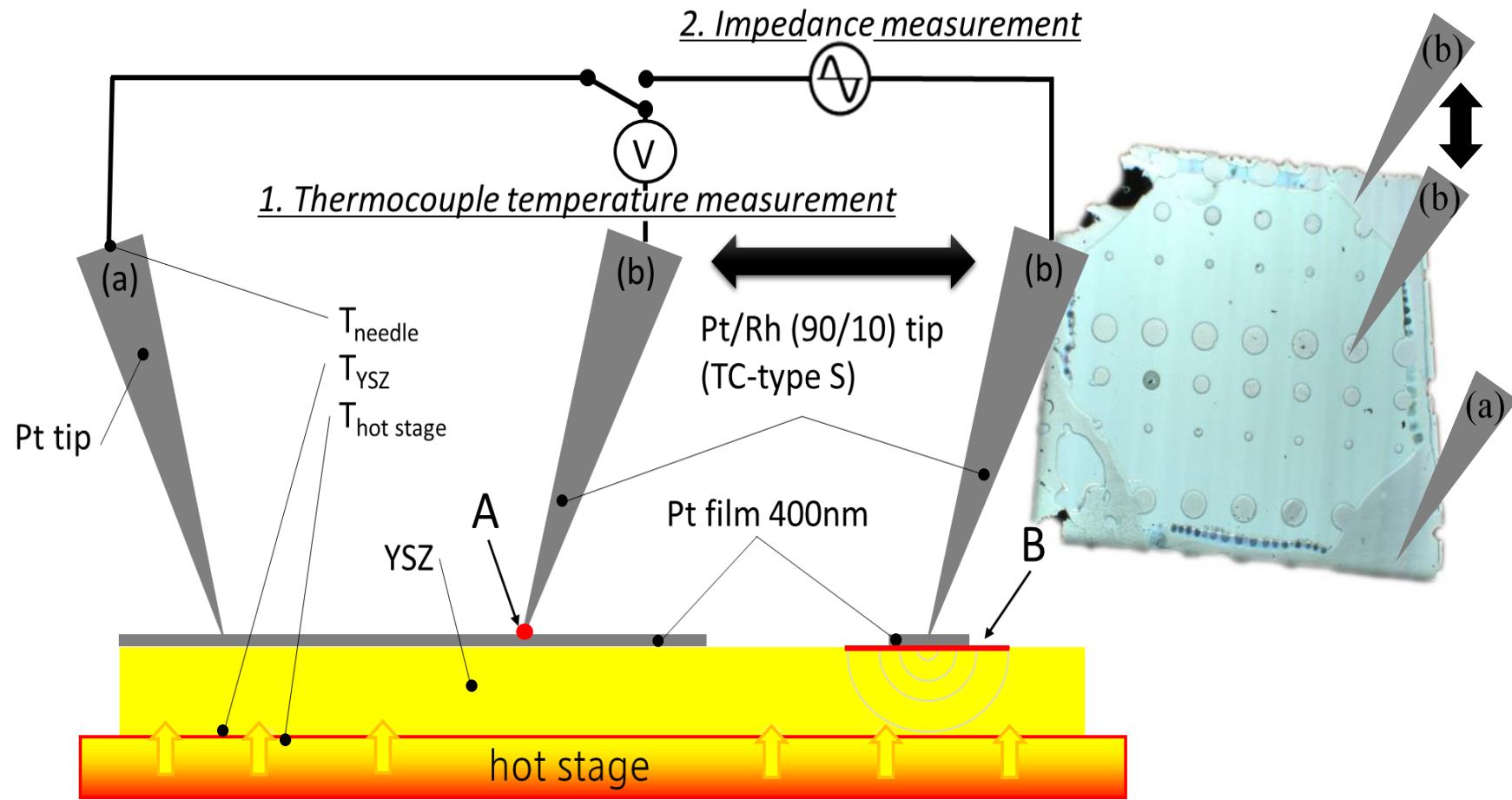


$$D_b(z) = D_b(z=0) \cdot \left( 1 + \Delta \frac{z}{h} \right)$$

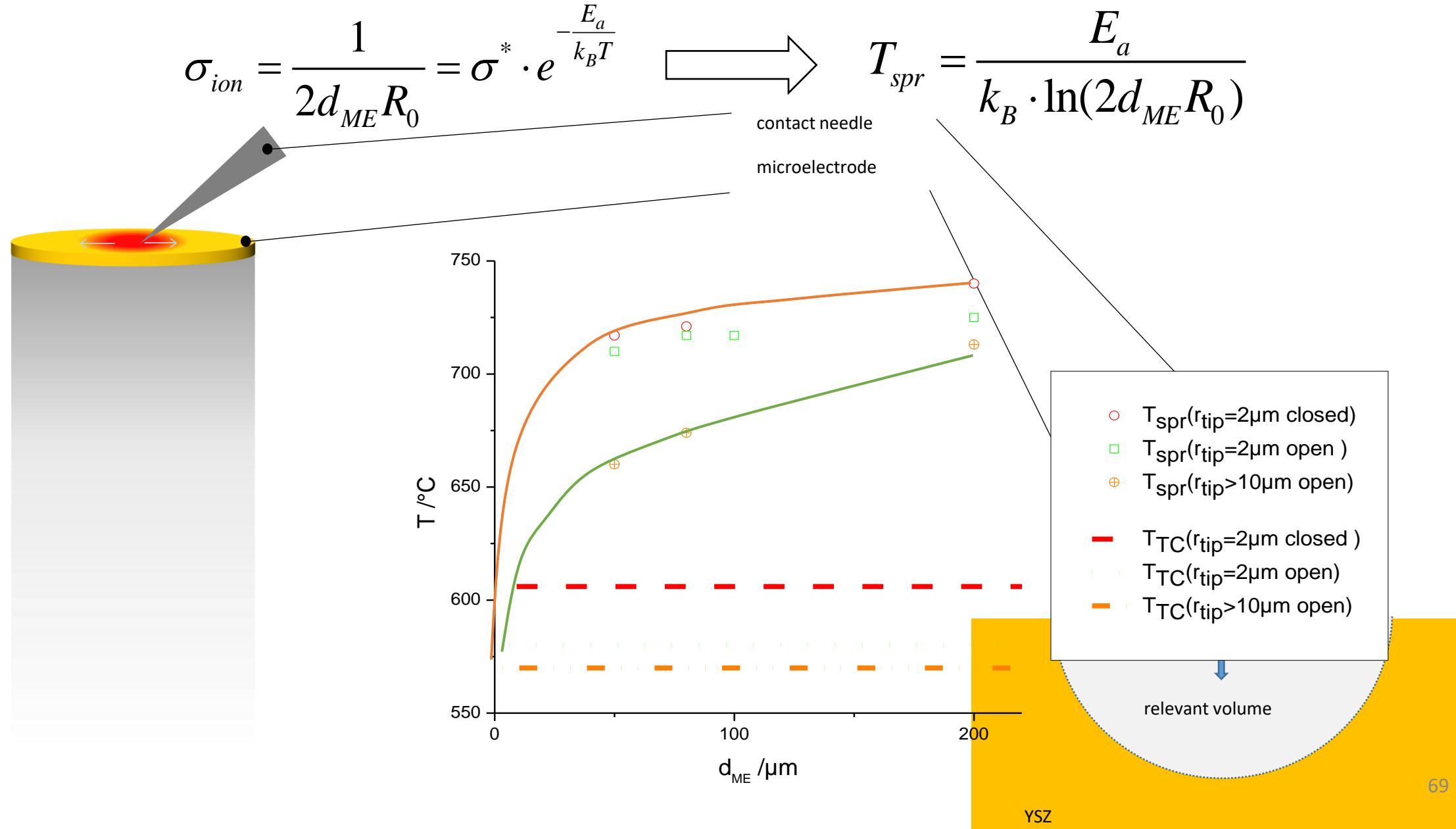
# Voltage effect on oxygen tracer diffusion



# Micro-thermocouple

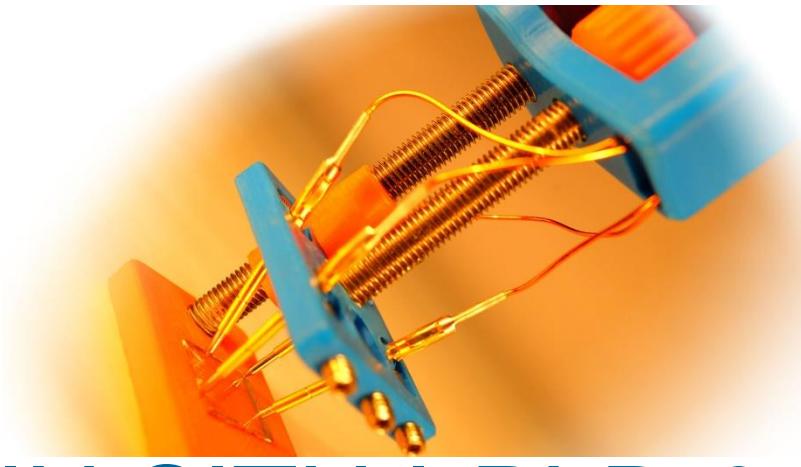


# Visualization of temperature gradients

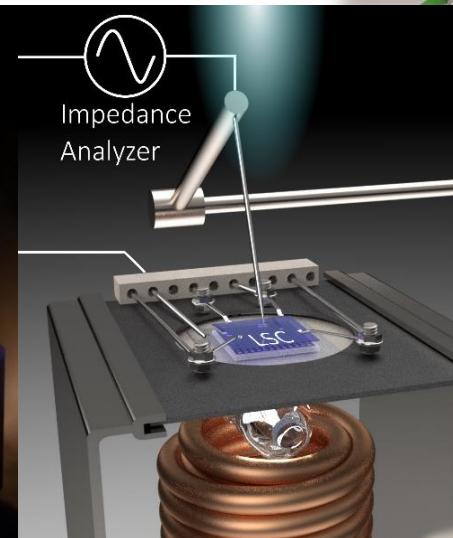
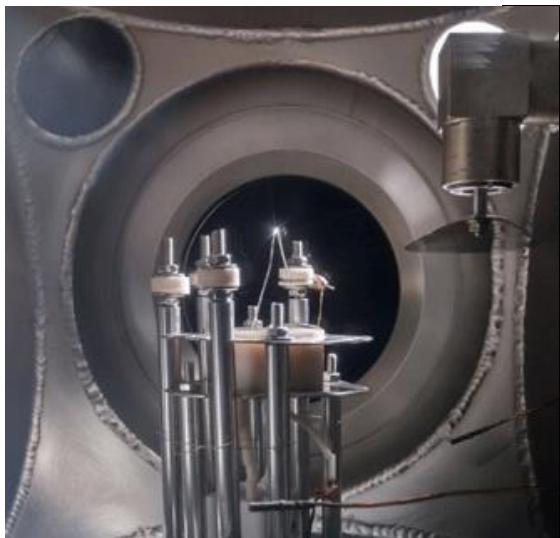


# IN SITU NEUTRON REFLECTIVITY

# MINI CHAMBER FOR THIN FILMS & DEVICES

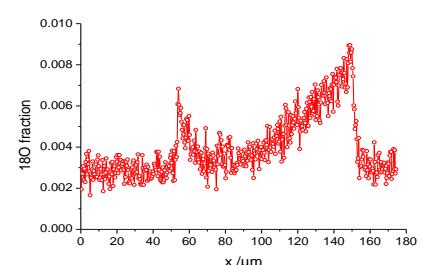
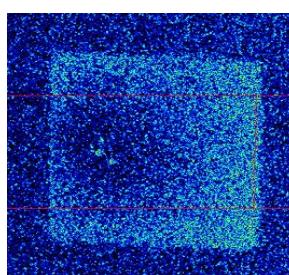
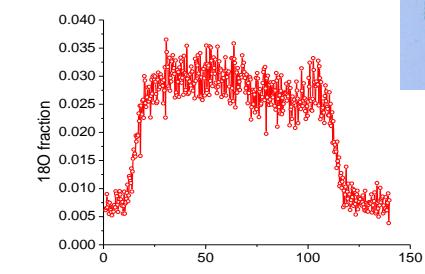
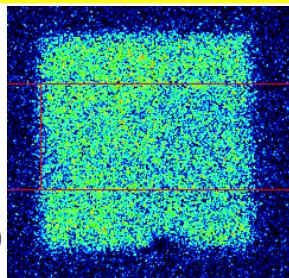
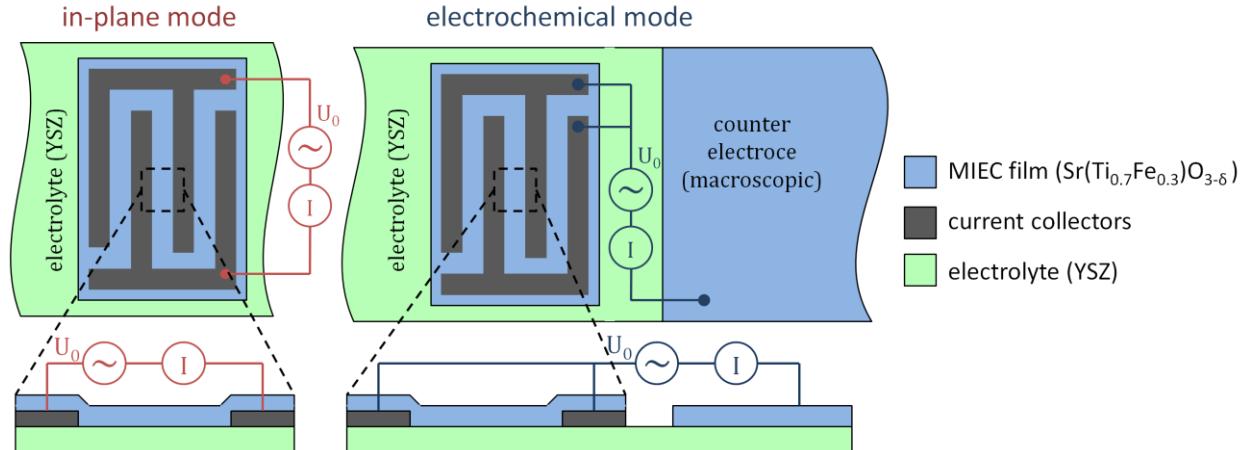
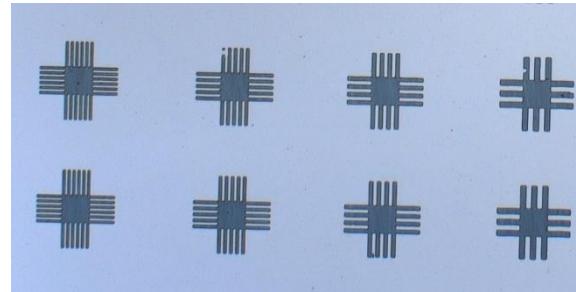
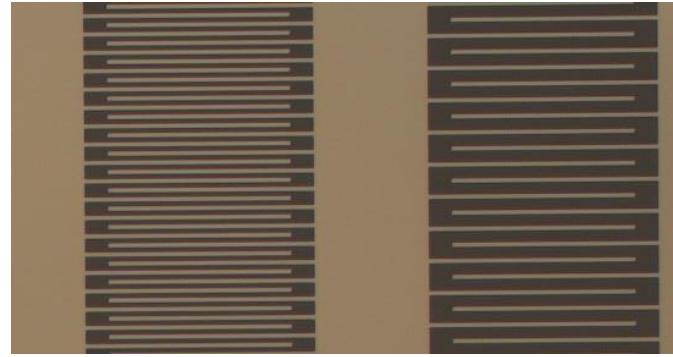


## IN SITU I-PLD & I-PVD HEATER

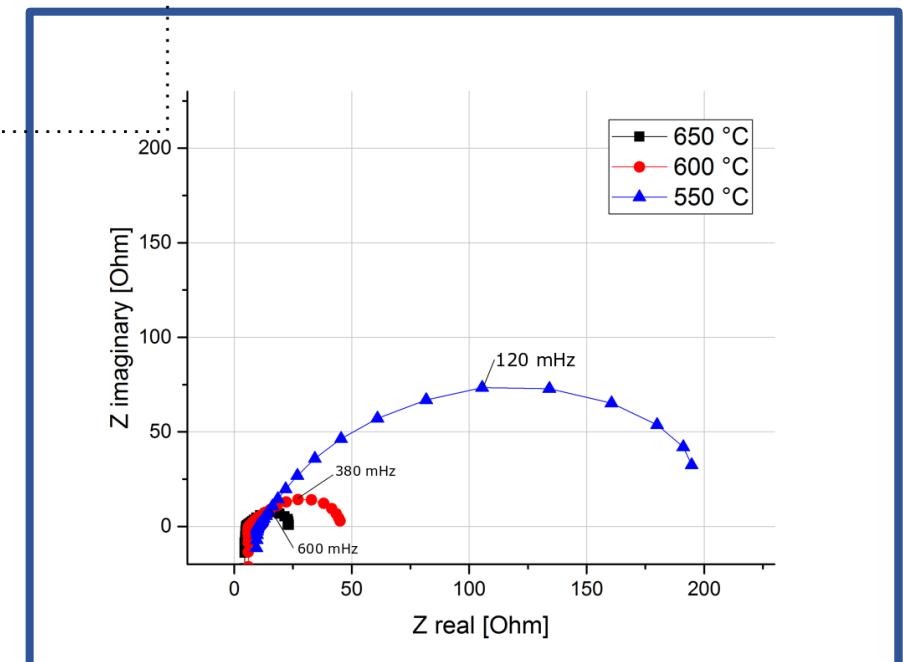
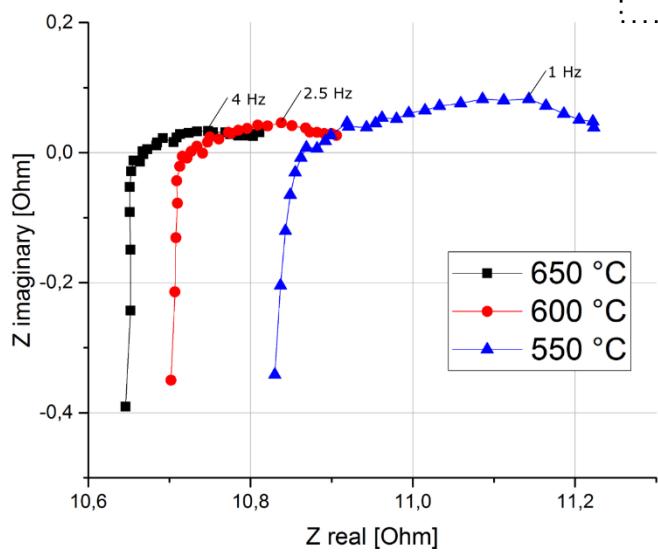
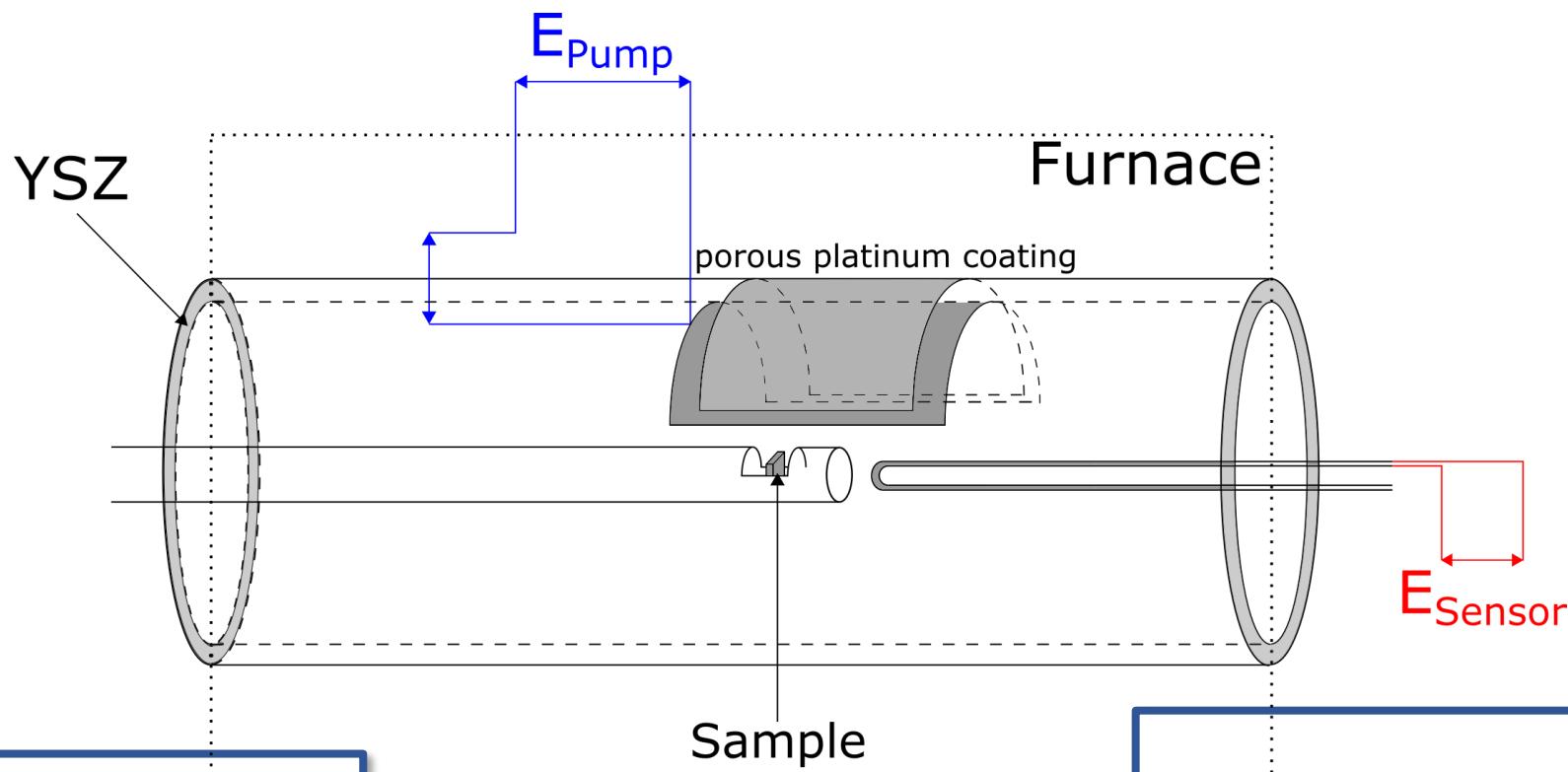


# Advantages of micro patterned thin film electrodes

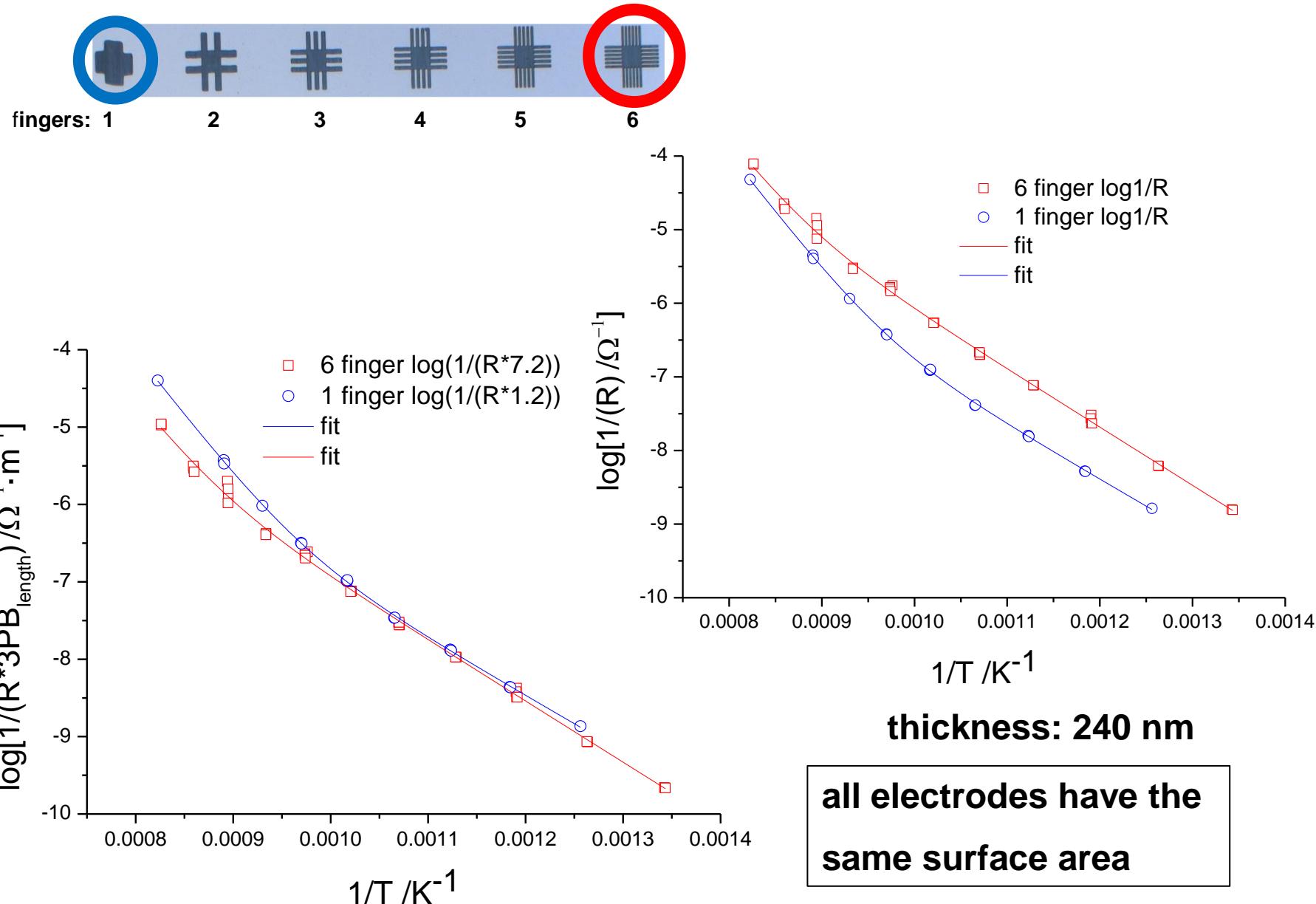
- Well-defined geometry (variable L3PB, ...)
- Reference electrode can be omitted
- Large number of electrodes on each sample
- Direct access to active surfaces in SIMS-studies, ...
- Current voltage measurement measurements



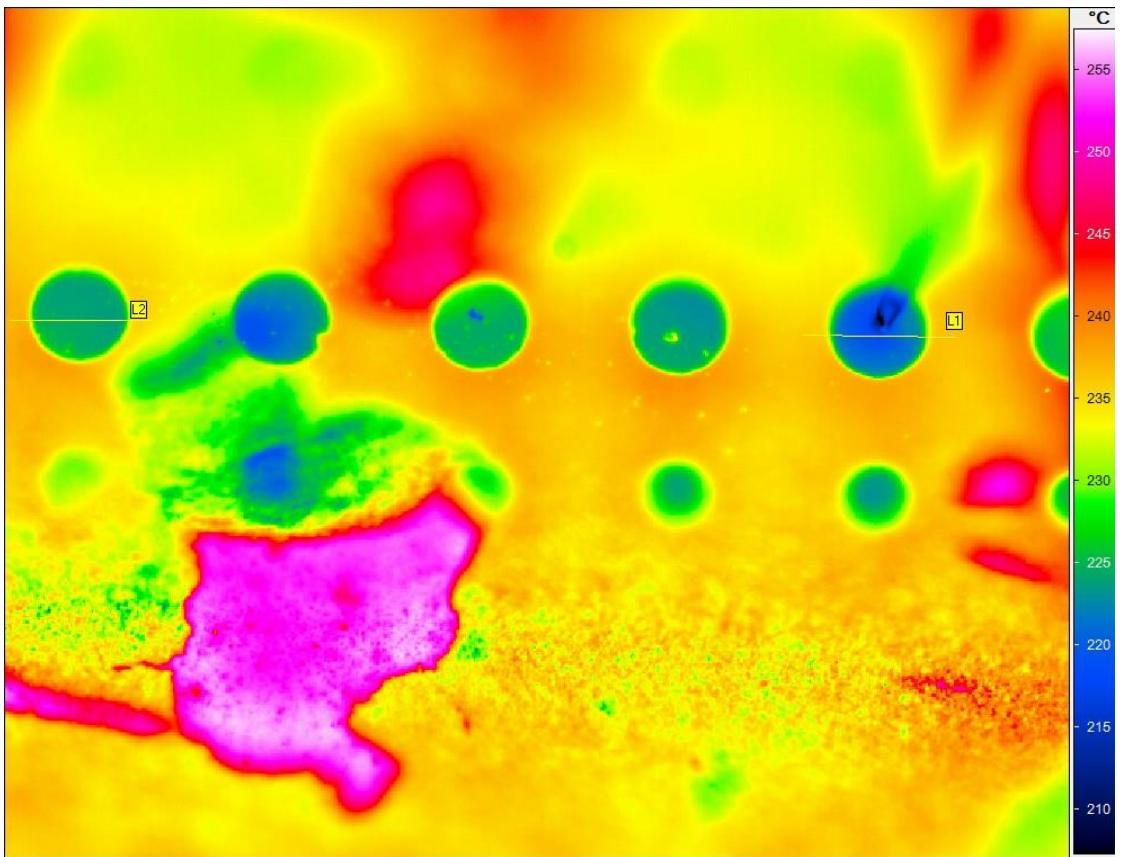
71  
300  $\mu\text{m}$



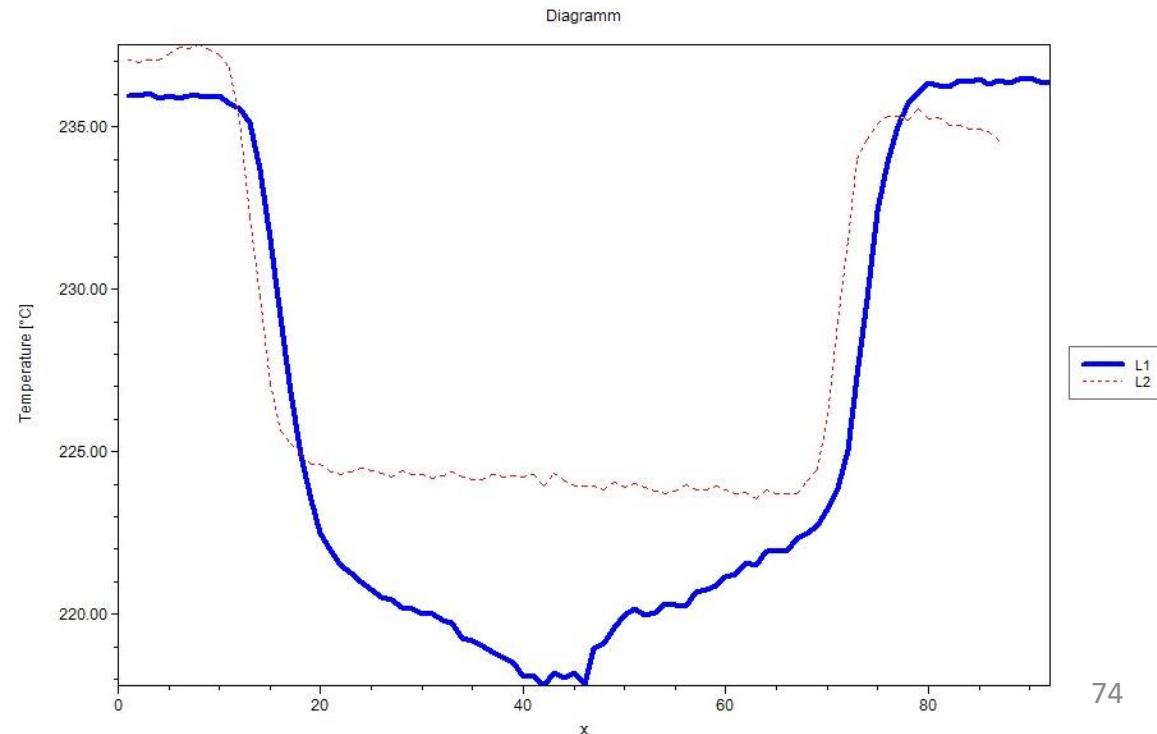
# Ridge electrodes, variation of 3PB



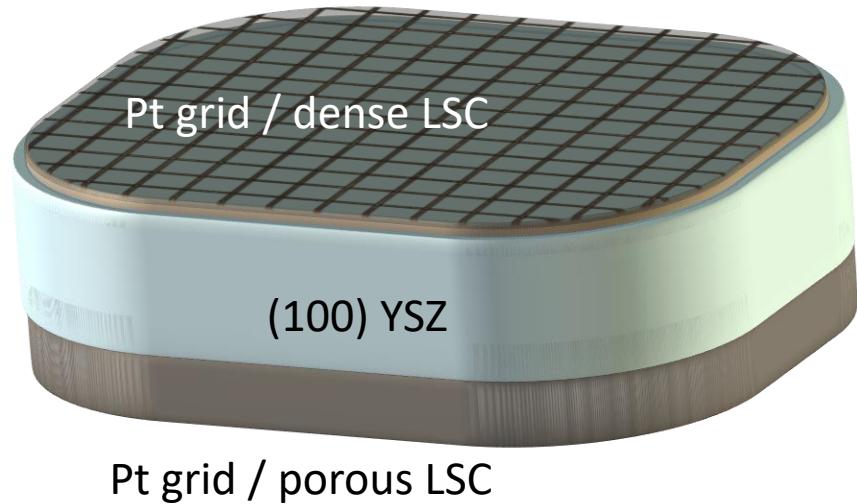
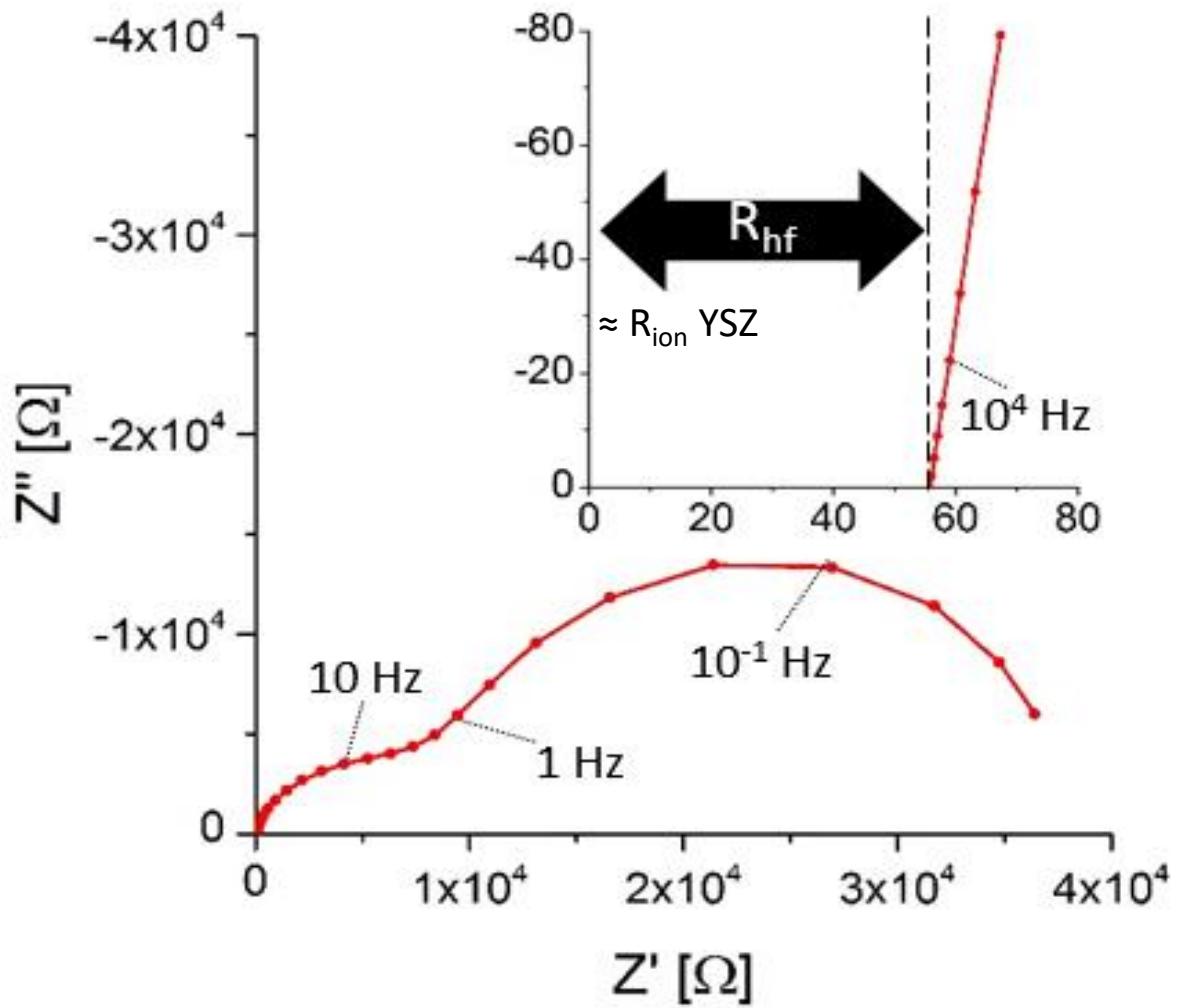
# Infrared camera



- 200 µm LSM electrode
- 300 °C furnace temperature
- visualizing temperature gradient

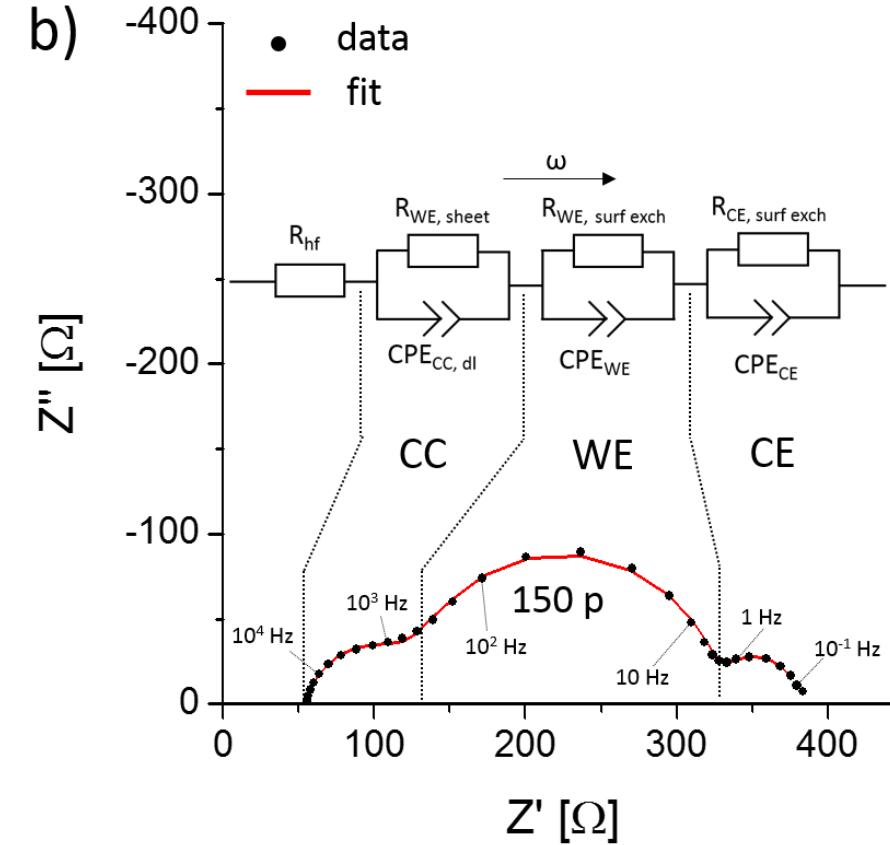
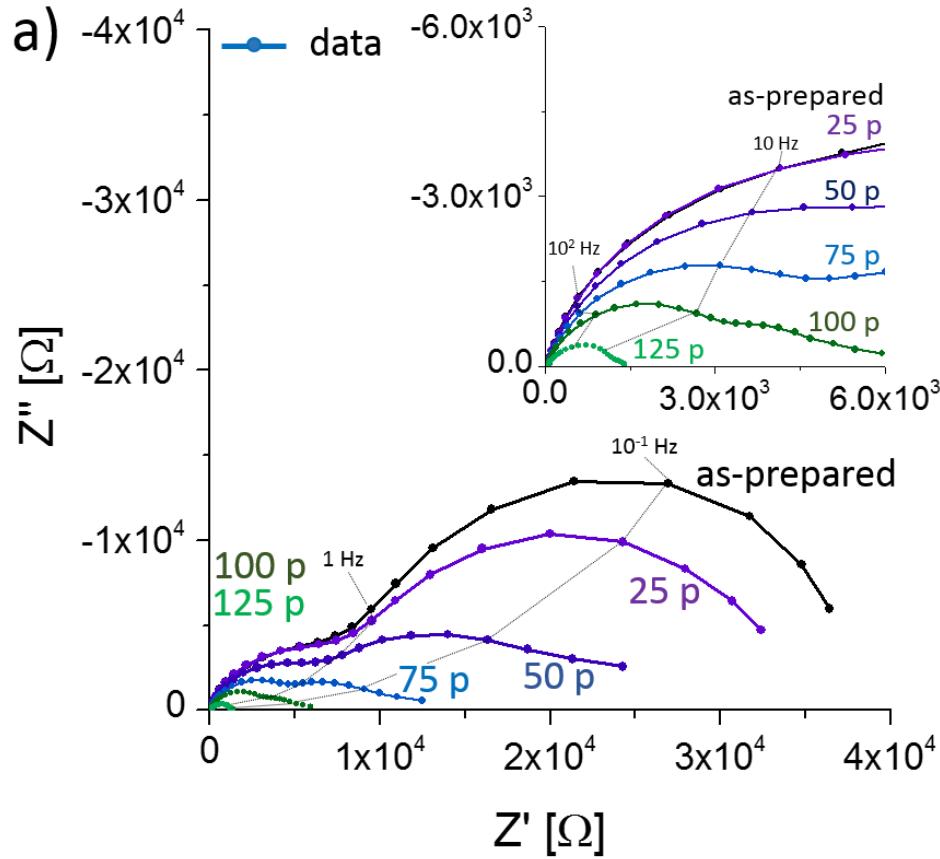


# Temperature control



- High frequency resistance  $R_{hf}$  is dominated by the ionic oxygen transport resistance of (100) YSZ
- Calibration via reference measurements of YSZ

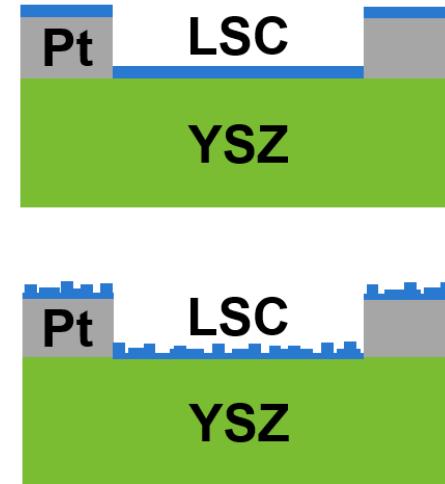
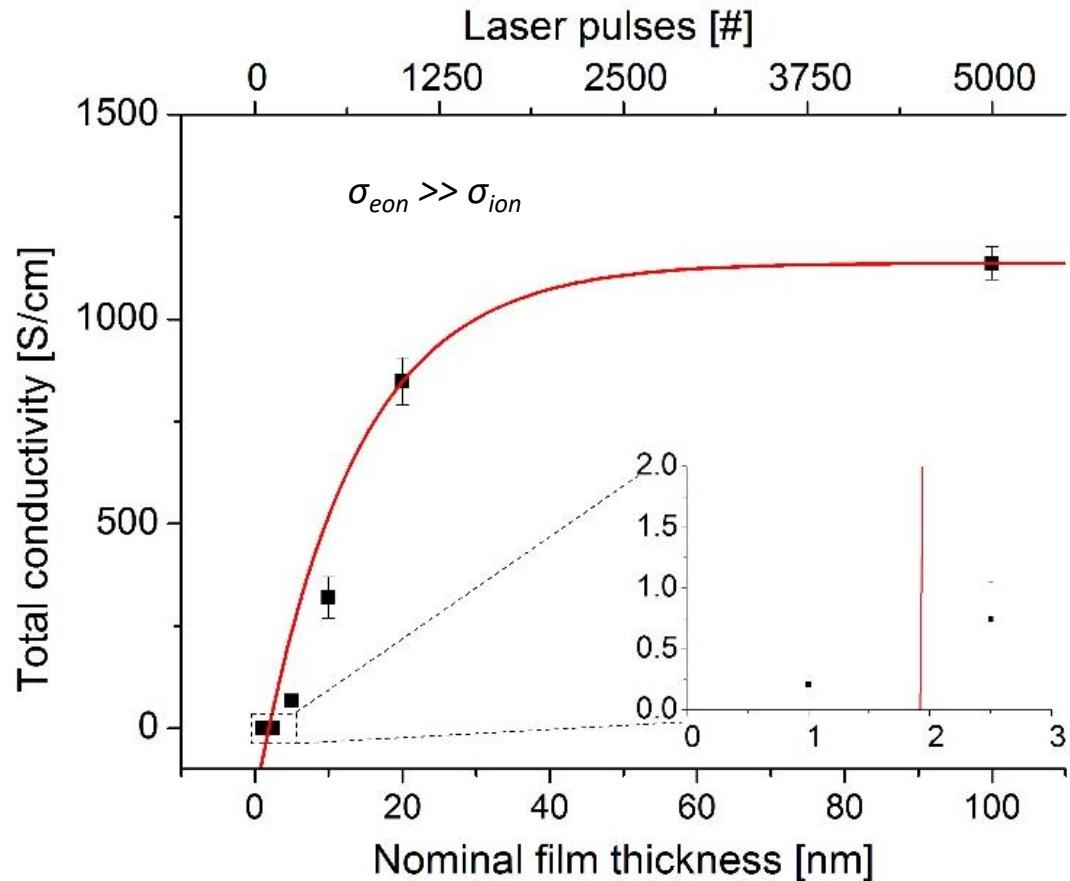
# Impedance in the first 3 nm LSC



- PLD at 600°C and  $4 \cdot 10^{-2}$  mbar p(O<sub>2</sub>), 10 mVAC for impedance
- At the beginning impedance is dominated by Pt grid
- > 125 pulses: 4 resistive contributions can be distinguished

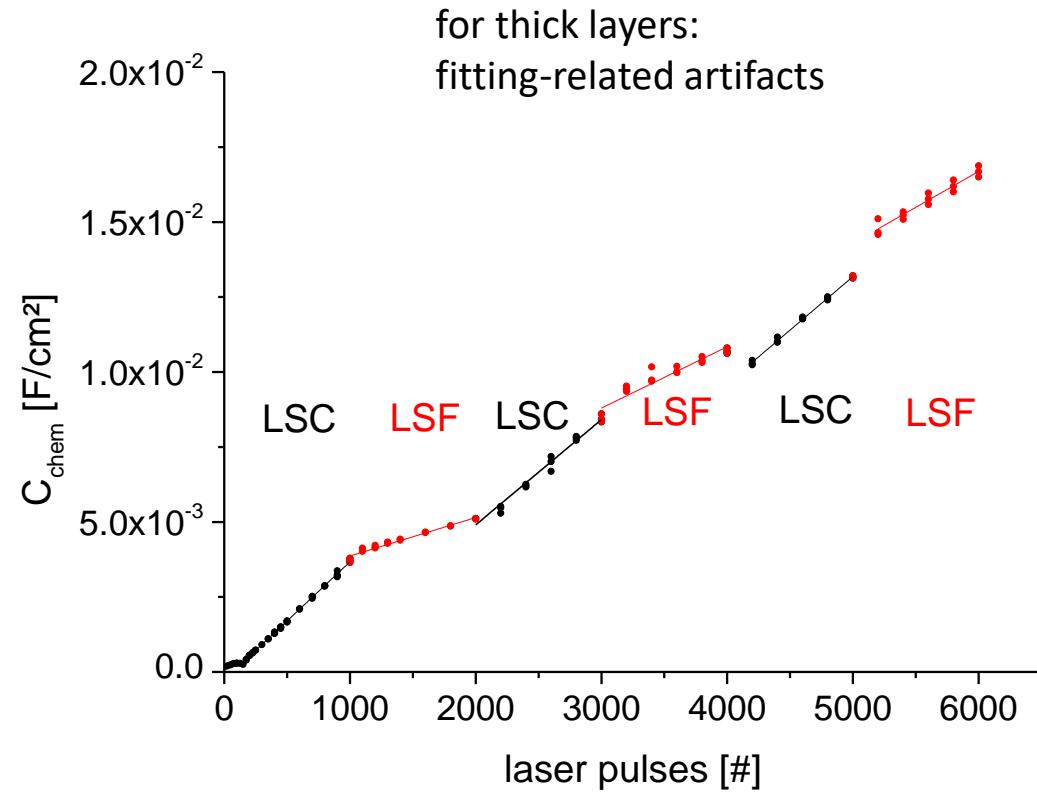
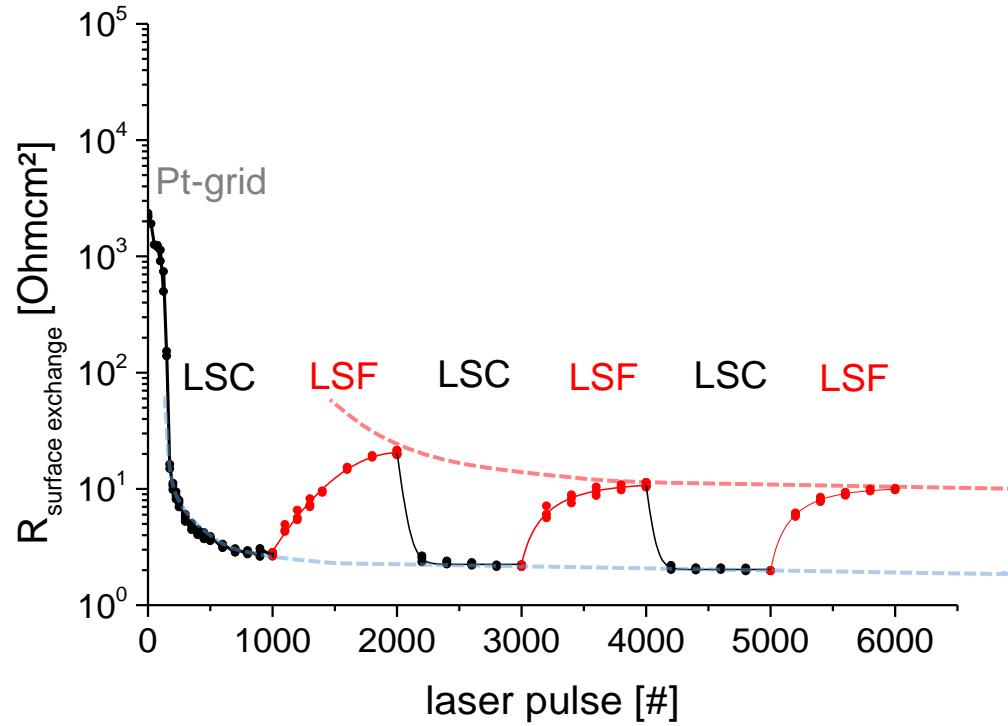
150 pulses = 3 nm

# Sheet resistance of the growing film



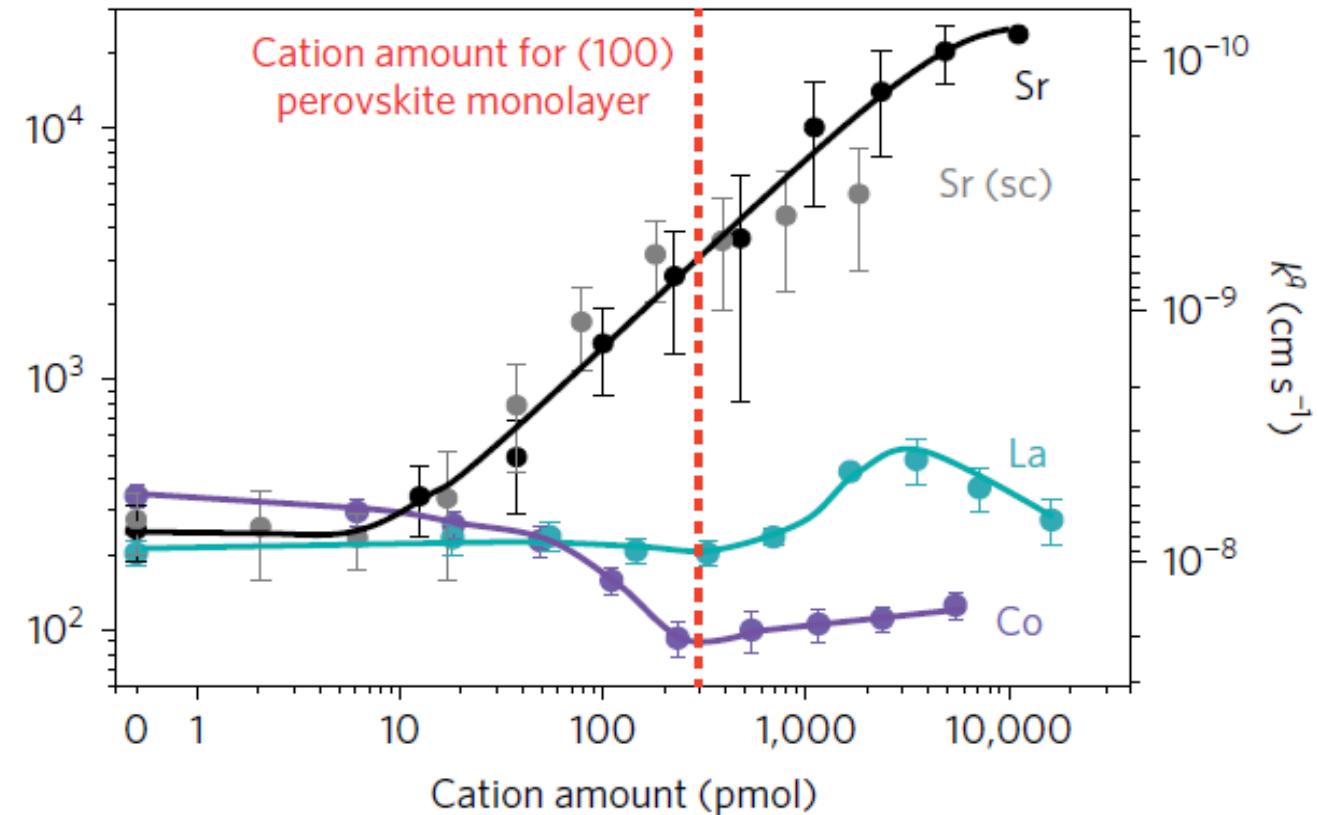
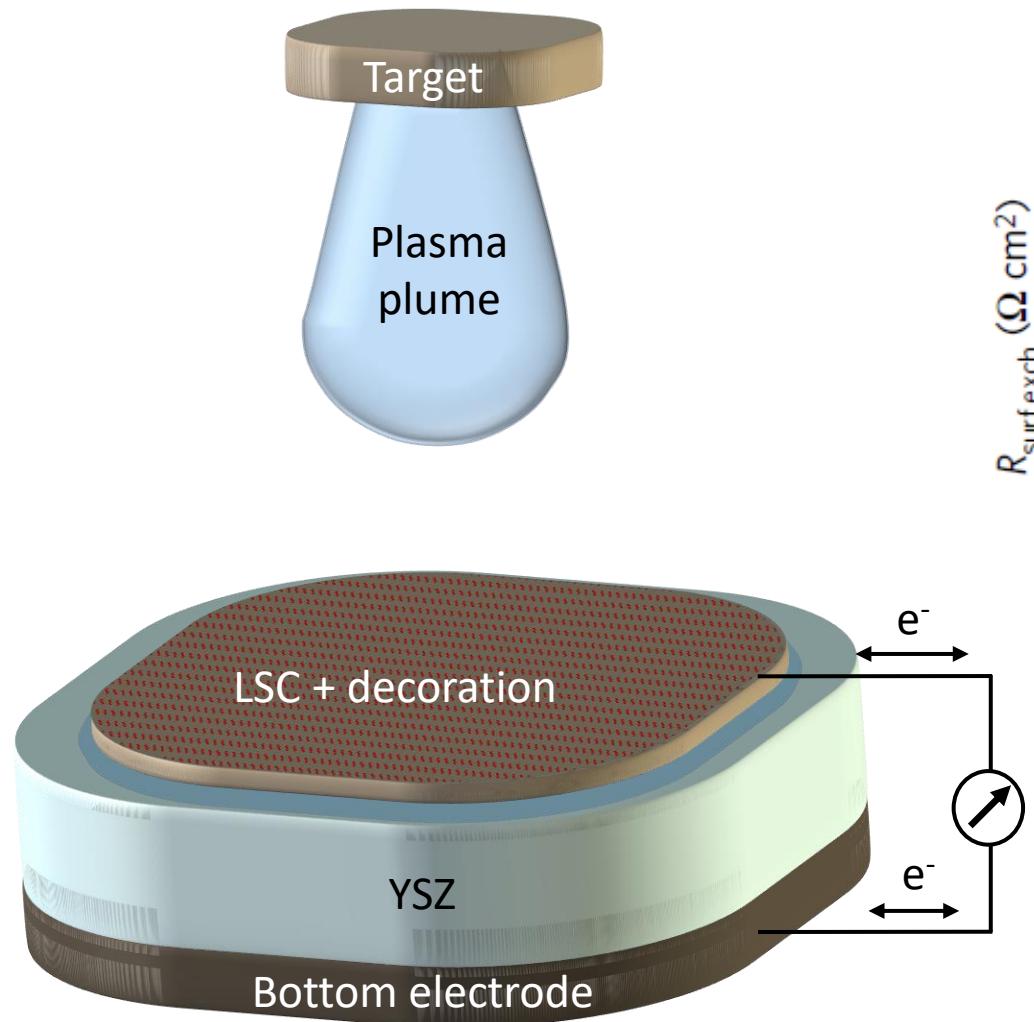
- Ex situ 4-point Van-der-Pauw measurements
- Expected LSC conductivity
- Slight deviation from ideal behavior → non-ideal growth

# Multilayers of $\text{La}_{0.6}\text{Sr}_{0.4}\text{CoO}_{3-\delta}$ and $\text{La}_{0.6}\text{Sr}_{0.4}\text{FeO}_{3-\delta}$



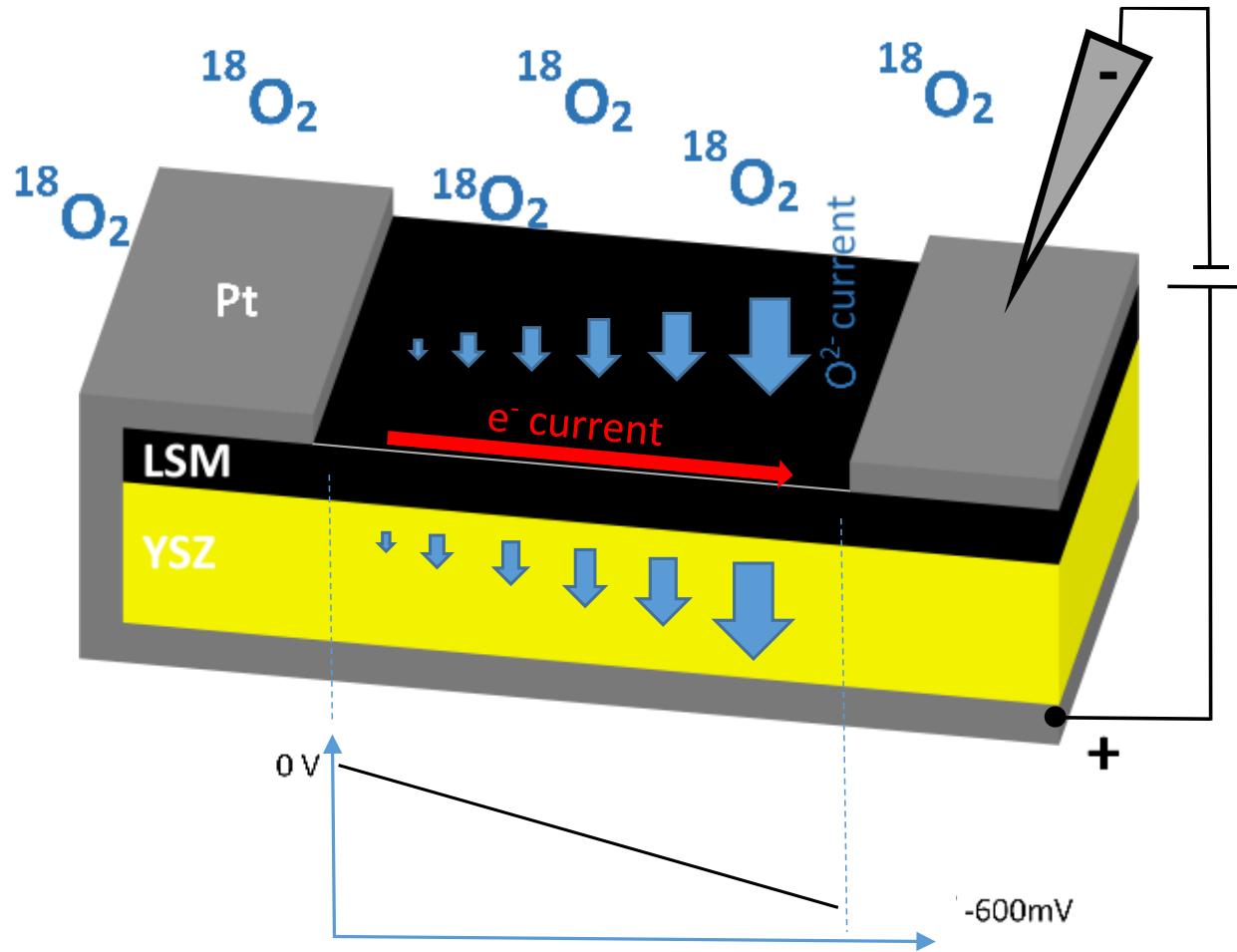
- Multilayers show transition between different surfaces ( $R_s$ )
- Charge carrier concentration from  $C_{\text{chem}}$

# Sub-monolayer decoration layers



- **Huge impact:**  
add 13% of a ML → +100% resistance
- Few active centers on the surface
- Co enhances, Sr reduces activity

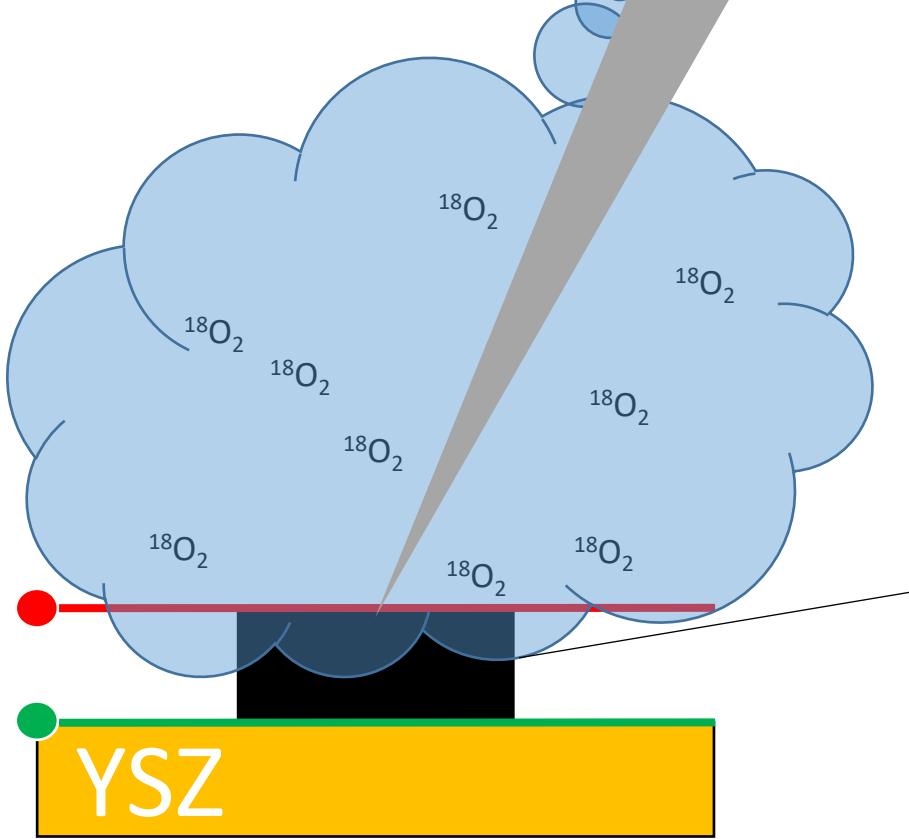
# New experimental design for polarization experiments



## **motivation:**

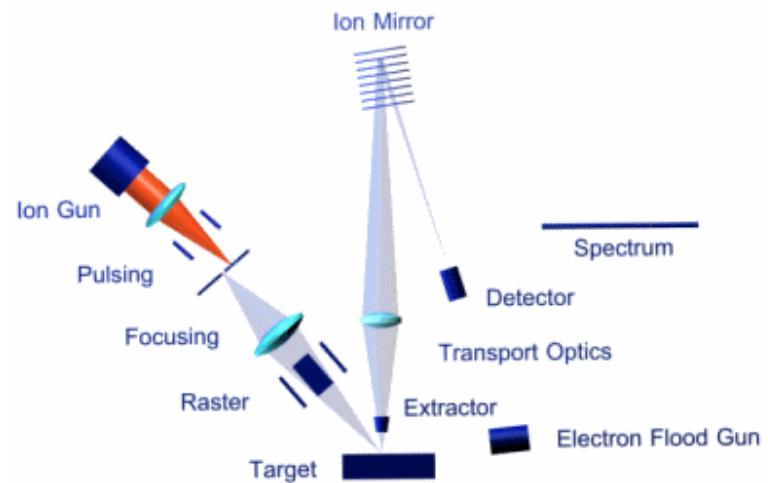
- Develop a simple method to study voltage assisted tracer exchange
- Easy to contact
- Highly accurate applied voltage
- Different **polarized thin film** on one and the same sample

SIMS



and  $^{18}\text{O}$  exchange  
with polarization

Electrode



© ION-TOF GmbH

in situ



ex situ

cooling down changes experiment

sufficient resources? (time & money)

in situ ex situ same surface process?

surface with analytic tools accessible

process only visible under experimental conditions

data possible to interpret?

impurities cause problems

oxidation → reductions make it visible

switch the catalyst on and off

observe the process. e.g. from the interface

expert in two fields ... e.g. deposition and measuring at the same time